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(54) HETEROLEPTIC IRIDIUM COMPLEXES AS DOPANTS

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- (63) Continuation of application No. 13/193,221, filed on Jul. 28, 2011, now Pat. No. 8,709,615, and a continuation-in-part of application No. 12/727,615, filed on Mar. 19, 2010, now Pat. No. 8,722,205.
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(58) Field of Classification Search

None

See application file for complete search history.

(56) References Cited

U.S. PATENT DOCUMENTS

4,769,292 A 9/1988 Tang et al. 5,061,569 A 10/1991 VanSlyke et al. (Continued)

FOREIGN PATENT DOCUMENTS

CN 1680366 10/2005 EP 0650955 5/1995 (Continued)

OTHER PUBLICATIONS

Adachi, Chihaya et al., "Organic Electroluminescent Device Having a Hole Conductor as an Emitting Layer," Appl. Phys. Lett., 55(15): 1489-1491 (1989).

(Continued)

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(57) ABSTRACT

Novel phosphorescent heteroleptic iridium complexes with phenylpyridine and dibenzo-containing ligands are provided. Alkyl substitution at specific positions on the ligands gives rise to compounds with improved OLED properties, including saturated green emission.

22 Claims, 3 Drawing Sheets

$$\begin{bmatrix} R_1 & R_2 & R_3 & R_4 & R_5 \\ R_3 & R_6 & R_6 & R_6 \end{bmatrix}_{n}$$

Formula I

(51)	T 4 Cl			2009/03	007022 A1 1	2/2000	V
(51)	Int. Cl.		(200 < 01)		297033 A1 1 008605 A1		Knowles et al. Kawamura et al.
	H01L 51/00		(2006.01)		008003 A1 009065 A1		Nishimura et al.
	H05B 33/14		(2006.01)		017330 A1		Iwakuma et al.
	C07F 15/00		(2006.01)		030202 A1		Iwakuma et al.
	H01L 51/50		(2006.01)	2009/00)39776 A1		Yamada et al.
(5.0)		D 6			045730 A1	2/2009	Nishimura et al.
(56)		Referen	ces Cited		045731 A1		Nishimura et al.
	IIS	PATENT	DOCUMENTS		101870 A1 108737 A1		Prakash et al. Kwong et al.
	0.5.	171111111	DOCCIMENTS		115316 A1		Zheng et al.
	5,247,190 A	9/1993	Friend et al.		165846 A1		Johannes et al.
	5,703,436 A		Forrest et al.	2009/01	167162 A1	7/2009	Lin et al.
	5,707,745 A 5,834,893 A		Forrest et al. Bulovic et al.		179554 A1		Kuma et al.
	5,844,363 A		Gu et al.	2010/02	244004 A1	9/2010	Xia et al.
	6,013,982 A		Thompson et al.		FOREICN	LDATE	NE DOCUMENTO
	6,087,196 A		Sturm et al.		FOREIGN	N PALE.	NT DOCUMENTS
	6,091,195 A 6,097,147 A		Forrest et al. Baldo et al.	EP	012389	81	9/2002
	6,294,398 B1		Kim et al.	EP	13494		10/2003
	6,303,238 B1		Thompson et al.	EP	17250		11/2006
	6,337,102 B1		Forrest et al.	EP EP	18208 20345		8/2007 3/2009
	6,468,819 B1	3/2003	Kim et al.	JP	2005116		1/2005
	6,528,187 B1 6,687,266 B1		Ma et al.	JР	20050297		2/2005
	6,835,469 B2		Kwong et al.	JP	20061798		7/2006
	6,893,743 B2		Sato et al.	JP JP	20071233		5/2007 10/2007
	6,921,915 B2		Takiguchi et al.	JР	20072542 20080749		10/2007 4/2008
	6,953,628 B2 7,087,321 B2		Kamatani et al. Kwong et al.	WO	01392		5/2001
	7,090,928 B2		Thompson et al.	WO	02027		1/2002
	7,154,114 B2		Brooks et al.	WO WO	02156 030402		2/2002 5/2003
	7,250,226 B2		Tokito et al.	WO	030402		7/2003
	7,279,704 B2 7,332,232 B2		Walters et al. Ma et al.	WO	20040932		10/2004
	7,338,722 B2		Thompson et al.	WO	20041078		12/2004
	7,393,599 B2		Thompson et al.	WO WO	20041110		12/2004 2/2005
	7,396,598 B2		Takeuchi et al. Shtein et al.	WO	20050145 20050193		3/2005
	7,431,968 B1 7,445,855 B2		Mackenzie et al.	WO	20050309		4/2005
	7,534,505 B2		Lin et al.	WO	20050890		9/2005
	7,635,526 B2		Stossel et al.	WO WO	20051238 20060090		12/2005 1/2006
	7,955,716 B2 8,709,615 B2*		Nomura et al. Kottas et al 428/690	WO	20060564		6/2006
	8,722,205 B2 *		Xia et al	WO	20060720		7/2006
2002	2/0034656 A1		Thompson et al.	WO	20060827		8/2006
	2/0134984 A1		Igarashi	WO WO	20060981 20061002		9/2006 9/2006
	2/0158242 A1 3/0138657 A1		Son et al. Li et al.	WO	20061038		10/2006
	3/0152802 A1		Tsuboyama et al.	WO	20061149		11/2006
	3/0162053 A1		Marks et al.	WO WO	20061321		12/2006
	3/0175553 A1 3/0230980 A1		Thompson et al. Forrest et al.	WO	20070026 20070043		1/2007 1/2007
	1/0013905 A1		Tsuboyama et al.	WO	20070637		6/2007
	1/0036077 A1	2/2004	Ise	WO	20070637		6/2007
	1/0137267 A1		Igarashi et al.	WO WO	20080567 20081018		5/2008 8/2008
	1/0137268 A1 1/0174116 A1		Igarashi et al. Lu et al.	wo	20081310		11/2008
	5/0025993 A1		Thompson et al.	WO	20090006		12/2008
	5/0112407 A1		Ogasawara et al.	WO	20090038		1/2009
	5/0238919 A1		Ogasawara	WO WO	20090083 20090180		1/2009 2/2009
	5/0244673 A1 5/0260441 A1		Satoh et al. Thompson et al.	wo	20090211		2/2009
	5/0260449 A1		Walters et al.	WO	20090309		3/2009
	5/0008670 A1	1/2006	Lin et al.	WO	20090502		4/2009
	5/0202194 A1		Jeong et al.	WO WO	20090625 20090638		5/2009 5/2009
	5/0240279 A1 5/0251923 A1		Adamovich et al. Lin et al.	WO	20090667		5/2009
	5/0263635 A1	11/2006		WO	20090667	79	5/2009
2006	5/0280965 A1	12/2006	Kwong et al.	WO	20090860		7/2009
	5/0287498 A1		Morishita et al.	WO	20091009	91	8/2009
	7/0190359 A1 7/0278938 A1		Knowles et al. Yabunouchi et al.		OT: 1	DD DIT	DI ICATIONIC
	3/0015355 A1		Schafer et al.		OTH	EK PUI	BLICATIONS
2008	3/0018221 A1	1/2008	Egen et al.	Adachi	Chihava et al	"Nearly	100% Internal Phosphorescence
	8/0106190 A1		Yabunouchi et al.		•		Emitting Device," J. Appl. Phys.,
	B/0124572 A1 B/0220265 A1		Mizuki et al. Xia et al.		y in an Oigain 048-5051 (200	_	Emitting Device, J. Appl. Fllys.,
2000	00220203 A1	212000	ma et al.	30(10 <i>)</i> , 3	U-10-3U31 (2UU	ı <i>j</i> .	

(56) References Cited

OTHER PUBLICATIONS

Adachi, Chihaya et al., "High-Efficiency Red Electrophosphorescence Devices," Appl. Phys. Lett., 78(11)1622-1624 (2001).

Aonuma, Masaki et al., "Material Design of Hole Transport Materials Capable of Thick-Film Formation in Organic Light Emitting Diodes," Appl. Phys. Lett., 90:183503-1-183503-3, (2007).

Baldo et al. "Highly Efficient Phosphorescent Emission from Organic Electroluminescent Devices" Nature, vol. 395, 151-154, (1998).

Baldo et al. "Very high-efficiency green organic light-emitting devices based on electrophosphorescence" Appl. Phys. Lett., vol. 75, No. 1, 4-6 (1999).

Gao, Zhiqiang et al., "Bright-Blue Electroluminescence From a Silyl-Substituted ter-(phenylene-vinylene) derivative," Appl. Phys. Lett., 74(6): 865-867 (1999).

Guo, Tzung-Fang et al., "Highly Efficient Electrophosphorescent Polymer Light-Emitting Devices," Organic Electronics, 1:15-20 (2000).

Hamada, Yuji et al., "High Luminance in Organic Electroluminescent Devices with Bis(10-hydroxybenzo[h]quinolinato) beryllium as an Emitter," Chem. Lett., 905-906 (1993).

Holmes, R.J. et al., "Blue Organic Electrophosphorescence Using Exothermic Host-Guest Energy Transfer," Appl. Phys. Lett., 82(15):2422-2424 (2003).

Hu, Nan-Xing et al., "Novel High Tg Hole-Transport Molecules Based on Indolo[3,2-b]carbazoles for Organic Light-Emitting Devices," Synthetic Metals, 111-112:421-424 (2000).

Huang, Jinsong et al., "Highly Efficient Red-Emission Polymer Phosphorescent Light-Emitting Diodes Based on Two Novel Tris(1-phenylisoquinolinato-C2,N)iridium(III)Derivatives," Adv. Mater., 19:739-743 (2007).

Huang, Wei-Sheng et al., "Highly Phosphorescent Bis-Cyclometalated Iridium Complexes Containing Benzoimidazole-Based Ligands," Chem. Mater., 16(12):2480-2488 (2004).

Hung, L.S. et al., "Anode Modification in Organic Light-Emitting Diodes by Low-Frequency Plasma Polymerization of CHF3," Appl. Phys. Lett., 78(5):673-675 (2001).

Ikai, Masamichi et al., "Highly Efficient Phosphorescence From Organic Light-Emitting Devices with an Exciton-Block Layer," Appl. Phys. Lett., 79(2):156-158 (2001).

Ikeda, Hisao et al., "P-185 Low-Drive-Voltage OLEDs with a Buffer Layer Having Molybdenum Oxide," SID Symposium Digest, 37:923-926 (2006).

Inada, Hiroshi and Shirota, Yasuhiko, "1,3,5-Tris[4-(diphenylamino)phenyl]benzene and its Methylsubstituted Derivatives as a Novel Class of Amorphous Molecular Materials," J. Mater. Chem., 3(3):319-320 (1993).

Kanno, Hiroshi et al., "Highly Efficient and Stable Red Phosphorescent Organic Light-Emitting Device Using bis[2-(2-benzothiazoyl)phenolato]zinc(II) as host material," Appl. Phys. Lett., 90:123509-1-123509-3 (2007).

Kido, Junji et al., "1,2,4-Triazole Derivative as an Electron Transport Layer in Organic Electroluminescent Devices," Jpn. J. Appl. Phys., 32:L917-L920 (1993).

Kuwabara, Yoshiyuki et al., "Thermally Stable Multilayered Organic Electroluminescent Devices Using Novel Starburst Molecules, 4,4',4"-Tri(N-carbazolyl)triphenylamine (TCTA) and 4,4',4"-Tris(3-methylphenylphenyl-amino) triphenylamine (m-MTDATA), as Hole-Transport Materials," Adv. Mater., 6(9):677-679 (1994).

Kwong, Raymond C. et al., "High Operational Stability of Electrophosphorescent Devices," Appl. Phys. Lett., 81(1) 162-164 (2002).

Lamansky, Sergey et al., "Synthesis and Characterization of Phosphorescent Cyclometalated Iridium Complexes," Inorg. Chem., 40(7)1 704-1711 (2001).

Lee, Chang-Lyoul et al., "Polymer Phosphorescent Light-Emitting Devices Doped with Tris(2-phenylpyridine) Iridium as a Triplet Emitter," Appl. Phys. Lett., 77(15):2280-2282 (2000).

Lo, Shih-Chun et al., "Blue Phosphorescence from Iridium(III) Complexes at Room Temperature," Chem. Mater., 18 (21)5119-5129 (2006).

Ma, Yuguang et al., "Triplet Luminescent Dinuclear-Gold(I) Complex-Based Light-Emitting Diodes with Low Turn-On voltage," Appl. Phys. Lett., 74(10):1361-1363 (1999).

Mi, Bao-Xiu et al., "Thermally Stable Hole-Transporting Material for Organic Light-Emitting Diode an Isoindole Derivative," Chem. Mater.. 15(16):3148-3151 (2003).

Nishida, Jun-ichi et al., "Preparation, Characterization, and Electroluminescence Characteristics of α -Diimine-type Platinum(II) Complexes with Perfluorinated Phenyl Groups as Ligands," Chem. Lett., 34(4): 592-593 (2005).

Niu, Yu-Hua et al., "Highly Efficient Electrophosphorescent Devices with Saturated Red Emission from a Neutral Osmium Complex," Chem. Mater., 17(13):3532-3536 (2005).

Noda, Tetsuya and Shirota, Yasuhiko, "5,5'-Bis(dimesitylboryl)-2,2'-bithiophene and 5,5"-Bis (dimesitylboryl)-2,2'5',2"-terthiophene as a Novel Family of Electron-Transporting Amorphous Molecular Materials," J. Am. Chem. Soc., 120 (37):9714-9715 (1998).

Okumoto, Kenji et al., "Green Fluorescent Organic Light-Emitting Device with External Quantum Efficiency of Nearly 10%," Appl. Phys. Lett., 89:063504-1-063504-3 (2006).

Palilis, Leonidas C., "High Efficiency Molecular Organic Light-Emitting Diodes Based on Silole Derivatives and Their Exciplexes," Organic Electronics, 4:113-121 (2003).

Paulose, Betty Marie Jennifer S. et al., "First Examples of Alkenyl Pyridines as Organic Ligands for Phosphorescent Iridium Complexes," Adv. Mater., 16(22):2003-2007 (2004).

Ranjan, Sudhir et al., "Realizing Green Phosphorescent Light-Emitting Materials from Rhenium(I) Pyrazolato Diimine Complexes," Inorg. Chem., 42(4):1248-1255 (2003).

Sakamoto, Youichi et al., "Synthesis, Characterization, and Electron-Transport Property of Perfluorinated Phenylene Dendrimers," J. Am. Chem. Soc., 122(8):1832-1833 (2000).

Salbeck, J. et al., "Low Molecular Organic Glasses for Blue Electroluminescence," Synthetic Metals, 91:209-215 (1997).

Shirota, Yasuhiko et al., "Starburst Molecules Based on p-Electron Systems as Materials for Organic Electroluminescent Devices," Journal of Luminescence, 72-74:985-991 (1997).

Sotoyama, Wataru et al., "Efficient Organic Llght-Emitting Diodes with Phosphorescent Platinum Complexes Containing NACAN-Coordinating Tridentate Ligand," Appl. Phys. Lett., 86:153505-1-153505-3 (2005).

Sun, Yiru and Forrest, Stephen R., "High-Efficiency White Organic Light Emitting Devices with Three Separate Phosphorescent Emission Layers," Appl. Phys. Lett., 91:263503-1-263503-3 (2007).

T. Östergård et al., "Langmuir-Blodgett Light-Emitting Diodes of Poly(3-Hexylthiophene) Electro-Optical Characteristics Related to Structure," Synthetic Metals, 88:171-177, (1997).

Takizawa, Shin-ya et al., "Phosphorescent Iridium Complexes Based on 2-Phenylimidazo[1,2- α]pyridine Ligands Tuning of Emission Color toward the Blue Region and Application to Polymer Light-Emitting Devices," Inorg. Chem., 46(10):4308-4319 (2007).

Tang, C.W. and VanSlyke, S.A., "Organic Electroluminescent Diodes," Appl, Phys. Lett., 51(12):913-915 (1987).

Tung, Yung-Liang et al., "Organic Light-Emitting Diodes Based on Charge-Neutral Ru II PHosphorescent Emitters" Adv. Mater., 17(8)1059-1064 (2005).

Van Slyke, S. A. et al., "Organic Electroluminescent Devices with Improved Stability," Appl. Phys. Lett., 69 (15):2160-2162 (1996).

Wang, Y. et al., "Highly Efficient Electroluminescent Materials Based on Fluorinated Organometallic Iridium Compounds," Appl. Phys. Lett., 79(4):449-451 (2001).

Wong, Keith Man-Chung et al., "A Novel Class of Phosphorescent Gold(III) Alkynyl-Based Organic Light-Emitting Devices with Tunable Colour," Chem. Commun., 2906-2908 (2005).

Wong, Wai-Yeung, "Multifunctional Iridium Complexes Based on Carbazole Modules as Highly Efficient Electrophosphors," Angew. Chem. Int. Ed., 45:7800-7803 (2006).

^{*} cited by examiner

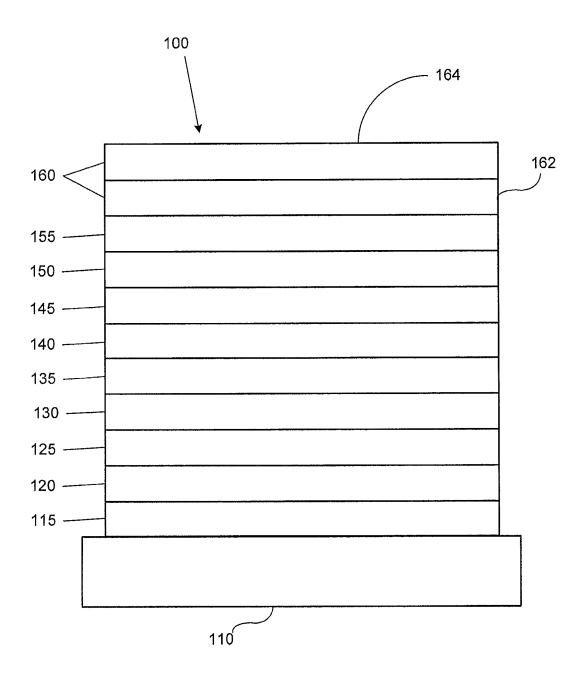


FIGURE 1

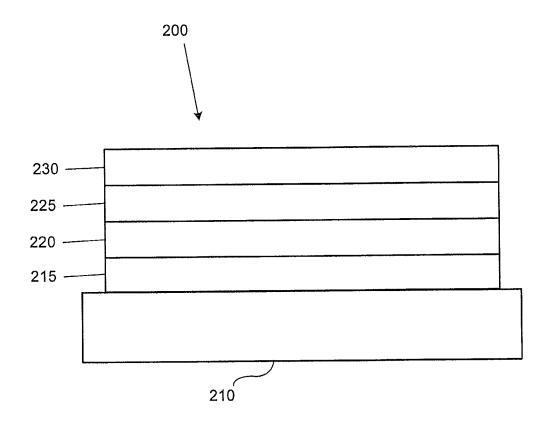


FIGURE 2

$$\begin{bmatrix} R_1 & R_2 & R_3 & R_4 & R_5 \\ R_1 & R_5 & R_6 & R_6 \end{bmatrix}$$

Formula I

FIGURE 3

HETEROLEPTIC IRIDIUM COMPLEXES AS DOPANTS

CROSS-REFERENCE TO RELATED APPLICATIONS

This application is a continuation of U.S. patent application Ser. No. 13/193,221 filed Jul. 28, 2011, now U.S. Pat. No. 8,709,615, and a continuation-in-part of U.S. patent application Ser. No. 12/727,615, filed Mar. 19, 2010, now U.S. Pat. No. 8,722,205, which claims priority to U.S. Provisional Application No. 61/162,476, filed Mar. 23, 2009, the entire contents of which are incorporated herein by reference.

PARTIES TO A JOINT RESEARCH AGREEMENT

The claimed invention was made by, on behalf of, and/or in connection with one or more of the following parties to a joint university corporation research agreement: Regents of the ²⁰ University of Michigan, Princeton University, The University of Southern California, and the Universal Display Corporation. The agreement was in effect on and before the date the claimed invention was made, and the claimed invention was made as a result of activities undertaken within the scope of ²⁵ the agreement.

FIELD OF THE INVENTION

The present invention relates to heteroleptic iridium complexes suitable for inclusion in OLED devices.

BACKGROUND

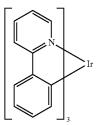
Opto-electronic devices that make use of organic materials are becoming increasingly desirable for a number of reasons. Many of the materials used to make such devices are relatively inexpensive, so organic opto-electronic devices have the potential for cost advantages over inorganic devices. In addition, the inherent properties of organic materials, such as their flexibility, may make them well suited for particular applications such as fabrication on a flexible substrate. Examples of organic opto-electronic devices include organic light emitting devices (OLEDs), organic phototransistors, organic photovoltaic cells, and organic photodetectors. For OLEDs, the organic materials may have performance advantages over conventional materials. For example, the wavelength at which an organic emissive layer emits light may generally be readily tuned with appropriate dopants.

OLEDs make use of thin organic films that emit light when voltage is applied across the device. OLEDs are becoming an increasingly interesting technology for use in applications such as flat panel displays, illumination, and backlighting. Several OLED materials and configurations are described in U.S. Pat. Nos. 5,844,363, 6,303,238, and 5,707,745, which are incorporated herein by reference in their entirety.

One application for phosphorescent emissive molecules is a full color display. Industry standards for such a display call for pixels adapted to emit particular colors, referred to as "saturated" colors. In particular, these standards call for saturated red, green, and blue pixels. Color may be measured using CIE coordinates, which are well known to the art.

One example of a green emissive molecule is tris(2-phe-65 nylpyridine) iridium, denoted Ir(ppy)₃, which has the following structure:

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In this, and later figures herein, we depict the dative bond from nitrogen to metal (here, Ir) as a straight line.

As used herein, the term "organic" includes polymeric materials as well as small molecule organic materials that may be used to fabricate organic opto-electronic devices. "Small molecule" refers to any organic material that is not a polymer, and "small molecules" may actually be quite large. Small molecules may include repeat units in some circumstances. For example, using a long chain alkyl group as a substituent does not remove a molecule from the "small molecule" class. Small molecules may also be incorporated into polymers, for example as a pendent group on a polymer backbone or as a part of the backbone. Small molecules may also serve as the core moiety of a dendrimer, which consists of a series of chemical shells built on the core moiety. The core moiety of a dendrimer may be a fluorescent or phosphorescent small molecule emitter. A dendrimer may be a "small molecule," and it is believed that all dendrimers currently used in the field of OLEDs are small molecules.

As used herein, "top" means furthest away from the substrate, while "bottom" means closest to the substrate. Where a first layer is described as "disposed over" a second layer, the first layer is disposed further away from substrate. There may be other layers between the first and second layer, unless it is specified that the first layer is "in contact with" the second layer. For example, a cathode may be described as "disposed over" an anode, even though there are various organic layers to the tween.

As used herein, "solution processible" means capable of being dissolved, dispersed, or transported in and/or deposited from a liquid medium, either in solution or suspension form.

A ligand may be referred to as "photoactive" when it is believed that the ligand directly contributes to the photoactive properties of an emissive material. A ligand may be referred to as "ancillary" when it is believed that the ligand does not contribute to the photoactive properties of an emissive material, although an ancillary ligand may alter the properties of a photoactive ligand.

As used herein, and as would be generally understood by one skilled in the art, a first "Highest Occupied Molecular Orbital" (HOMO) or "Lowest Unoccupied Molecular Orbital" (LUMO) energy level is "greater than" or "higher than" a second HOMO or LUMO energy level if the first energy level is closer to the vacuum energy level. Since ionization potentials (IP) are measured as a negative energy relative to a vacuum level, a higher HOMO energy level corresponds to an IP having a smaller absolute value (an IP that is less negative). Similarly, a higher LUMO energy level corresponds to an electron affinity (EA) having a smaller absolute value (an EA that is less negative). On a conventional energy level diagram, with the vacuum level at the top, the LUMO energy level of a material is higher than the HOMO energy level of the same material. A "higher" HOMO or LUMO energy level appears closer to the top of such a diagram than a "lower" HOMO or LUMO energy level.

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As used herein, and as would be generally understood by one skilled in the art, a first work function is "greater than" or "higher than" a second work function if the first work function has a higher absolute value. Because work functions are generally measured as negative numbers relative to vacuum level, this means that a "higher" work function is more negative. On a conventional energy level diagram, with the vacuum level at the top, a "higher" work function is illustrated as further away from the vacuum level in the downward direction. Thus, the definitions of HOMO and LUMO energy levels follow a different convention than work functions.

More details on OLEDs, and the definitions described above, can be found in U.S. Pat. No. 7,279,704, which is incorporated herein by reference in its entirety.

SUMMARY OF THE INVENTION

In one aspect, a compound having the formula:

is provided. R_1 and R_2 are optionally linked and the sum of the number of carbon atoms in R_1 and R_2 is at least 2. R_3 , R_4 , R_5 , R_6 are optionally linked, and R_a and R_b represent mono-, di-, 40 tri- or tetra-substitution. X is selected from the group consisting of BR, NR, PR, O, S, Se, C=O, S=O, SO2, CRR', SiRR', and GeRR', and R_a , R_b , R, R', R_1 , R_2 , R_3 , R_4 , R_5 , and R_6 are independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfanyl, sulfonyl, phosphino, and combinations thereof; and wherein n is 1 or 2.

In one aspect, n is 2. In one aspect, X is O. In one aspect, R_1 is hydrogen and R_2 is alkyl. In another aspect, R_1 is alkyl and R_2 is hydrogen. In one aspect, R_1 and R_2 are alkyl. In one aspect, R_1 and R_2 contain one or more deuterium atoms. In another aspect, R_1 or R_2 are independently selected from the $\,^{55}$ group consisting of branched alkyl, cyclic alkyl, bicyclic alkyl, and multicyclic alkyl. In one aspect, R_1 or R_2 is isopropyl.

In one aspect, R_1 or R_2 contain one or more deuterium atoms. In one aspect, R_3 , R_4 , R_5 and R_6 are independently 60 selected from the group consisting of hydrogen, deuterium, alkyl, aryl, and combinations thereof. In another aspect, at least one of R_3 , R_4 , R_5 and R_6 comprises a branched alkyl, cyclic alkyl, bicyclic alkyl, or a multicyclic alkyl. In one aspect, R_3 , R_4 , R_5 or R_6 contain one or more deuterium atoms. 65

In one aspect, the compound is selected from the group consisting of Compound 53, Compounds 157-159, Com4

pound 165, Compound 174, Compound 175, Compounds 184-185, Compound 314, Compound 321, Compounds 625-628, Compound 633, Compound 643, Compounds 652-653, and Compounds 1145-1146.

In one aspect, a first device is provided. The first device comprises a first organic light-emitting device, further comprising an anode, a cathode, and an organic layer, disposed between the anode and the cathode, comprising a compound having the formula:

Formula I

$$\begin{bmatrix} R_1 & R_2 & R_3 & R_4 \\ R_3 & R_5 & R_6 \end{bmatrix}_{R_b}$$

 R_1 and R_2 are optionally linked and the sum of the number of carbon atoms in R_1 and R_2 is at least 2. R_3 , R_4 , R_5 , R_6 are optionally linked, and R_a and R_b represent mono-, di-, tri- or tetra-substitution. X is selected from the group consisting of BR, NR, PR, O, S, Se, C=O, S=O, SO₂, CRR', SiRR', and GeRR', and R_a , R_b , R, R, R, R_1 , R_2 , R_3 , R_4 , R_5 , and R_6 are independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof; and wherein n is 1 or 2.

In one aspect, the first device is a consumer product. In another aspect, the first device is an organic light-emitting device. In another aspect, the first device comprises a lighting panel. In one aspect, the organic layer is an emissive layer and the compound is an emissive dopant. In another aspect, the organic layer is an emissive layer and the compound is a non-emissive dopant.

In one aspect, the organic layer further comprises a host. In another aspect, the host comprises a triphenylene containing benzo-fused thiophene or benzo-fused furan, wherein any substituent in the host is an unfused substituent independently selected from the group consisting of C_nH_{2n+1} , OC_nH_{2n+1} , OC_n

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In one aspect, the host has the formula

In another aspect, the host is selected from the group consisting of:

6

and combinations thereof.

In one aspect, the host is a metal complex.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 shows an organic light emitting device.

FIG. 2 shows an inverted organic light-emitting device that does not have a separate electron transport layer.

FIG. 3 shows a compound of Formula I.

DETAILED DESCRIPTION

Generally, an OLED comprises at least one organic layer disposed between and electrically connected to an anode and a cathode. When a current is applied, the anode injects holes and the cathode injects electrons into the organic layer(s). The injected holes and electrons each migrate toward the oppositely charged electrode. When an electron and hole localize on the same molecule, an "exciton," which is a localized electron-hole pair having an excited energy state, is formed. Light is emitted when the exciton relaxes via a photoemissive mechanism. In some cases, the exciton may be localized on an excimer or an exciplex. Non-radiative mechanisms, such as thermal relaxation, may also occur, but are generally considered undesirable.

The initial OLEDs used emissive molecules that emitted light from their singlet states ("fluorescence") as disclosed, for example, in U.S. Pat. No. 4,769,292, which is incorporated by reference in its entirety. Fluorescent emission generally occurs in a time frame of less than 10 nanoseconds.

More recently, OLEDs having emissive materials that emit light from triplet states ("phosphorescence") have been demonstrated. Baldo et al., "Highly Efficient Phosphorescent Emission from Organic Electroluminescent Devices," Nature, vol. 395, 151-154, 1998; ("Baldo-I") and Baldo et al.,

"Very high-efficiency green organic light-emitting devices based on electrophosphorescence," Appl. Phys. Lett., vol. 75, No. 3, 4-6 (1999) ("Baldo-II"), which are incorporated by reference in their entireties. Phosphorescence is described in more detail in U.S. Pat. No. 7,279,704 at cols. 5-6, which are 5 incorporated by reference.

FIG. 1 shows an organic light emitting device 100. The figures are not necessarily drawn to scale. Device 100 may include a substrate 110, an anode 115, a hole injection layer 120, a hole transport layer 125, an electron blocking layer 10 130, an emissive layer 135, a hole blocking layer 140, an electron transport layer 145, an electron injection layer 150, a protective layer 155, and a cathode 160. Cathode 160 is a compound cathode having a first conductive layer 162 and a second conductive layer 164. Device 100 may be fabricated 15 by depositing the layers described, in order. The properties and functions of these various layers, as well as example materials, are described in more detail in U.S. Pat. No. 7,279, 704 at cols. 6-10, which are incorporated by reference.

More examples for each of these layers are available. For 20 example, a flexible and transparent substrate-anode combination is disclosed in U.S. Pat. No. 5,844,363, which is incorporated by reference in its entirety. An example of a p-doped hole transport layer is m-MTDATA doped with F.sub.4-TCNQ at a molar ratio of 50:1, as disclosed in U.S. Patent 25 Application Publication No. 2003/0230980, which is incorporated by reference in its entirety. Examples of emissive and host materials are disclosed in U.S. Pat. No. 6,303,238 to Thompson et al., which is incorporated by reference in its entirety. An example of an n-doped electron transport layer is 30 BPhen doped with Li at a molar ratio of 1:1, as disclosed in U.S. Patent Application Publication No. 2003/0230980, which is incorporated by reference in its entirety. U.S. Pat. Nos. 5,703,436 and 5,707,745, which are incorporated by reference in their entireties, disclose examples of cathodes 35 including compound cathodes having a thin layer of metal such as Mg:Ag with an overlying transparent, electricallyconductive, sputter-deposited ITO layer. The theory and use of blocking layers is described in more detail in U.S. Pat. No. 6,097,147 and U.S. Patent Application Publication No. 2003/ 40 0230980, which are incorporated by reference in their entireties. Examples of injection layers are provided in U.S. Patent Application Publication No. 2004/0174116, which is incorporated by reference in its entirety. A description of protective layers may be found in U.S. Patent Application Publication 45 No. 2004/0174116, which is incorporated by reference in its entirety.

FIG. 2 shows an inverted OLED 200. The device includes a substrate 210, a cathode 215, an emissive layer 220, a hole transport layer 225, and an anode 230. Device 200 may be 50 fabricated by depositing the layers described, in order. Because the most common OLED configuration has a cathode disposed over the anode, and device 200 has cathode 215 disposed under anode 230, device 200 may be referred to as an "inverted" OLED. Materials similar to those described 55 with respect to device 100 may be used in the corresponding layers of device 200. FIG. 2 provides one example of how some layers may be omitted from the structure of device 100.

The simple layered structure illustrated in FIGS. 1 and 2 is provided by way of non-limiting example, and it is understood that embodiments of the invention may be used in connection with a wide variety of other structures. The specific materials and structures described are exemplary in nature, and other materials and structures may be used. Functional OLEDs may be achieved by combining the various 65 layers described in different ways, or layers may be omitted entirely, based on design, performance, and cost factors.

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Other layers not specifically described may also be included. Materials other than those specifically described may be used. Although many of the examples provided herein describe various layers as comprising a single material, it is understood that combinations of materials, such as a mixture of host and dopant, or more generally a mixture, may be used. Also, the layers may have various sublayers. The names given to the various layers herein are not intended to be strictly limiting. For example, in device 200, hole transport layer 225 transports holes and injects holes into emissive layer 220, and may be described as a hole transport layer or a hole injection layer. In one embodiment, an OLED may be described as having an "organic layer" disposed between a cathode and an anode. This organic layer may comprise a single layer, or may further comprise multiple layers of different organic materials as described, for example, with respect to FIGS. 1 and 2.

Structures and materials not specifically described may also be used, such as OLEDs comprised of polymeric materials (PLEDs) such as disclosed in U.S. Pat. No. 5,247,190 to Friend et al., which is incorporated by reference in its entirety. By way of further example, OLEDs having a single organic layer may be used. OLEDs may be stacked, for example as described in U.S. Pat. No. 5,707,745 to Forrest et al, which is incorporated by reference in its entirety. The OLED structure may deviate from the simple layered structure illustrated in FIGS. 1 and 2. For example, the substrate may include an angled reflective surface to improve out-coupling, such as a mesa structure as described in U.S. Pat. No. 6,091,195 to Forrest et al., and/or a pit structure as described in U.S. Pat. No. 5,834,893 to Bulovic et al., which are incorporated by reference in their entireties.

Unless otherwise specified, any of the layers of the various embodiments may be deposited by any suitable method. For the organic layers, preferred methods include thermal evaporation, ink-jet, such as described in U.S. Pat. Nos. 6,013,982 and 6,087,196, which are incorporated by reference in their entireties, organic vapor phase deposition (OVPD), such as described in U.S. Pat. No. 6,337,102 to Forrest et al., which is incorporated by reference in its entirety, and deposition by organic vapor jet printing (OVJP), such as described in U.S. patent application Ser. No. 10/233,470, now U.S. Pat. No. 7,431,968, which is incorporated by reference in its entirety. Other suitable deposition methods include spin coating and other solution based processes. Solution based processes are preferably carried out in nitrogen or an inert atmosphere. For the other layers, preferred methods include thermal evaporation. Preferred patterning methods include deposition through a mask, cold welding such as described in U.S. Pat. Nos. 6,294,398 and 6,468,819, which are incorporated by reference in their entireties, and patterning associated with some of the deposition methods such as ink jet and OVJD. Other methods may also be used. The materials to be deposited may be modified to make them compatible with a particular deposition method. For example, substituents such as alkyl and aryl groups, branched or unbranched, and preferably containing at least 3 carbons, may be used in small molecules to enhance their ability to undergo solution processing. Substituents having 20 carbons or more may be used, and 3-20 carbons is a preferred range. Materials with asymmetric structures may have better solution processibility than those having symmetric structures, because asymmetric materials may have a lower tendency to recrystallize. Dendrimer substituents may be used to enhance the ability of small molecules to undergo solution processing.

Devices fabricated in accordance with embodiments of the invention may be incorporated into a wide variety of consumer products, including flat panel displays, computer

monitors, televisions, billboards, lights for interior or exterior illumination and/or signaling, heads up displays, fully transparent displays, flexible displays, laser printers, telephones, cell phones, personal digital assistants (PDAs), laptop computers, digital cameras, camcorders, viewfinders, micro-displays, vehicles, a large area wall, theater or stadium screen, or a sign. Various control mechanisms may be used to control devices fabricated in accordance with the present invention, including passive matrix and active matrix. Many of the devices are intended for use in a temperature range comfortable to humans, such as 18 degrees C. to 30 degrees C., and more preferably at room temperature (20-25 degrees C.).

The materials and structures described herein may have applications in devices other than OLEDs. For example, other optoelectronic devices such as organic solar cells and organic photodetectors may employ the materials and structures. More generally, organic devices, such as organic transistors, may employ the materials and structures.

The terms halo, halogen, alkyl, cycloalkyl, alkenyl, alkynyl, arylkyl, heterocyclic group, aryl, aromatic group, and heteroaryl are known to the art, and are defined in U.S. Pat. No. 7,279,704 at cols. 31-32, which are incorporated herein by reference.

In one embodiment, a compound having the formula:

is provided. R₁ and R₂ are optionally linked and the sum of the number of carbon atoms in R₁ and R₂ is at least 2. Thus, both 45 R₁ and R₂ both represent a substituent with at least one carbon. If R₁ does not represent substituent containing carbon, then R₂ must represent a substituent containing at least two carbons and vice versa. R₃, R₄, R₅, R₆ are optionally linked, and R_a and R_b represent mono-, di-, tri- or tetra-substitution. 50 X is selected from the group consisting of BR, NR, PR, O, S, Se, C \equiv O, S \equiv O, SO₂, CRR', SiRR', and GeRR', and R_a, R_b, $R, R', R_1, R_2, R_3, R_4, R_5$, and R_6 are independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, 55 amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfanyl, sulfonyl, phosphino, and combinations thereof; and wherein n is 1 or 2.

In one embodiment, n is 2. In one embodiment, X is O. In one embodiment, R_1 is hydrogen and R_2 is alkyl. In another embodiment, R_1 is alkyl and R_2 is hydrogen. In one embodiment, R_1 and R_2 are alkyl. In another embodiment, R_1 or R_2 are independently selected from the group consisting of branched alkyl, cyclic alkyl, bicyclic alkyl, and multicyclic 65 alkyl. In one embodiment, R_1 or R_2 is iso-propyl. Substitution at the 4- and 5-positions of either pyridine ring in the com-

pounds of Formula I can give rise to compounds with desirable properties such as saturated green emission, high efficiencies, and long device lifetimes when incorporated in OLED devices. The photophysical and device properties of devices incorporating these compounds may be tuned by varying the nature of the substituent at the 4- or 5-position on the pyridine. The 4-position on a pyridine ring in the compound of Formula I is the position occupied by the $R_{\rm 5}$ or $R_{\rm 1}$ substituent, whereas the 5-position is the position occupied by the $R_{\rm 4}$ or $R_{\rm 2}$ substituent.

As used herein, fragments containing the following structure:

$$A_3$$
 A_4
 A_5
 A_6

are called DBX groups, i.e. dibenzo X, where X is any of the atoms or groups described herein. Atoms A1-A8 can comprise nitrogen or carbon.

In one embodiment, R₁ or R₂ contain one or more deuterium atoms. In one embodiment, R1 and R2 contain one or more deuterium atoms. In one embodiment, R₃, R₄, R₅ and R₆ are independently selected from the group consisting of hydrogen, deuterium, alkyl, aryl, and combinations thereof. In another embodiment, at least one of R₃, R₄, R₅ and R₆ comprises a branched alkyl, cyclic alkyl, bicyclic alkyl, or a multicyclic alkyl. In one embodiment, R₃, R₄, R₅ or R₆ contain one or more deuterium atoms. Without being bound by theory, incorporation of deuterium is thought to improve stability of compounds due the greater bond strength of the carbon-deuterium (C-D) bond versus the carbon-hydrogen (C—H) bond. Therefore, compounds wherein labile C—H bonds are replaced by C-D bonds, higher stability can be expected. Without being bound by theory, it is believed that incorporation of deuterium atoms on the alkyl groups of ligands for iridium complexes, the resulting complexes can have longer device lifetimes.

In one embodiment, the compound is selected from the group consisting of:

-continued

Compound 157

Compound 158

15

Compound 159 35

Compound 165

50

-continued

Compound 175

Compound 184

Compound 185

15

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25

30

35

-continued

Compound 314

-continued

Compound 628

Compound 627

Compound 633

Compound 643

15

$$D_3C$$
 N
 N
 N
 N
 N

Compound 1146

In one embodiment, suitable $R_1\text{-}R_6$ groups in the compounds of Formula I include the configurations of substituents in Table 1.

TABLE 1

Compound	# R ₁	R_2	R ₃	R_4	R_5	R ₆
1.	Н	Ethyl	Н	Н	Н	Н
2.	Η	Ethyl	Methyl	H	H	Н
3.	Η	Ethyl	H	Methyl	H	Н
4.	Η	Ethyl	H	H	Methyl	H
5.	Η	Ethyl	H	H	H	Methyl
6.	Η	Ethyl	Methyl	Methyl	H	Н
7.	Η	Ethyl	Methyl	H	Methyl	H
8.	Η	Ethyl	Methyl	H	H	Methyl
9.	Η	Ethyl	H	Methyl	Methyl	Н
10.	Η	Ethyl	H	Methyl	H	Methyl
11.	Η	Ethyl	H	H	Methyl	Methyl
12.	Η	Ethyl	Methyl	Methyl	Methyl	Н
13.	Η	Ethyl	Methyl	Methyl	H	Methyl
14.	Η	Ethyl	Methyl	H	Methyl	Methyl
15.	Η	Ethyl	H	Methyl	Methyl	Methyl
16.	Η	Ethyl	Methyl	Methyl	Methyl	Methyl
17.	Η	Ethyl	Ethyl	H	H	Н
18.	Η	Ethyl	H	Ethyl	H	H
19.	Η	Ethyl	H	H	Ethyl	Н
20.	Η	Ethyl	H	H	H	Ethyl
21.	Η	Ethyl	Methyl	Ethyl	H	Н
22.	Η	Ethyl	Methyl	H	Ethyl	H
23.	Η	Ethyl	Methyl	H	H	Ethyl
24.	Η	Ethyl	H	Ethyl	Methyl	Н
25.	Η	Ethyl	H	Ethyl	Ethyl	H
26.	Η	Ethyl	H	Methyl	Ethyl	H
27.	Η	Ethyl	Isopropyl	H	H	Н
28.	Η	Ethyl	H	Isopropyl	H	H
29.	Η	Ethyl	H	H	Isopropyl	H
30.	Η	Ethyl	H	H	H	Isopropyl
31.	Η	Ethyl	Methyl	Isopropyl	H	H
32.	Η	Ethyl	Methyl	Н	Isopropyl	H
33.	Н	Ethyl	Methyl	H	Н	Isopropyl
34.	Н	Ethyl	Н	Isopropyl	Methyl	Н
35.	Н	Ethyl	H	Isopropyl	Isopropyl	Н
				1 17-	1 17-	

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TABLE 1-continued

		TAB	LE 1-coi	ntinued		
Compound	# R ₁	R_2	R ₃	R ₄	R_5	R ₆
36.	Н	Ethyl	Н	Methyl	Isopropyl	H
37.	H	Ethyl	H	Isopropyl	Ethyl	H
38. 39.	H H	Ethyl Ethyl	H Isobutyl	Ethyl H	Isopropyl H	H H
40.	Н	Ethyl	H	Isobutyl	Н	Н
41.	Н	Ethyl	Н	Н	Isobutyl	Н
42.	Н	Ethyl	H	Н	Н	Isobutyl
43.	Η	Ethyl	Methyl	Isobutyl	H	H
44.	Н	Ethyl	Methyl	H	Isobutyl	H
45. 46.	H H	Ethyl Ethyl	Methyl H	H Isobutyl	H Methyl	Isobutyl H
47.	Н	Ethyl	Н	Isobutyl	Isobutyl	H
48.	Н	Ethyl	Н	Methyl	Isobutyl	Н
49.	Η	Ethyl	H	Isobutyl	Ethyl	H
50.	H	Ethyl	H	Ethyl	Isobutyl	H
51. 52.	H H	Ethyl Ethyl	H H	Isobutyl Isopropyl	Isopropyl Isobutyl	H H
53.	Н	Isopropyl	H	Н	H	H
54.	Η	Isopropyl	Methyl	Н	Н	H
55.	Η	Isopropyl	Н	Methyl	H	Н
56.	H	Isopropyl	H	H	Methyl	Н
57.	H	Isopropyl	H	H	H	Methyl
58. 59.	H H	Isopropyl Isopropyl	Methyl Methyl	Methyl H	H Methyl	H H
60.	H	Isopropyl	Methyl	H	Н	Methyl
61.	H	Isopropyl	Н	Methyl	Methyl	Н
62.	Η	Isopropyl	H	Methyl	H	Methyl
63.	H	Isopropyl	H	H	Methyl	Methyl
64. 65.	H H	Isopropyl	Methyl Methyl	Methyl Methyl	Methyl H	H Methyl
66.	H	Isopropyl Isopropyl	Methyl	Н	Methyl	Methyl
67.	Н	Isopropyl	Н	Methyl	Methyl	Methyl
68.	H	Isopropyl	Methyl	Methyl	Methyl	Methyl
69.	Н	Isopropyl	Ethyl	Н	H	H
70. 71.	H H	Isopropyl	H H	Ethyl H	H	H
71.	Н	Isopropyl Isopropyl	Н	Н	Ethyl H	H Ethyl
73.	Н	Isopropyl	Methyl	Ethyl	H	Н
74.	H	Isopropyl	Methyl	Н	Ethyl	Н
75.	Η	Isopropyl	Methyl	Н	Н	Ethyl
76.	H	Isopropyl	H	Ethyl	Methyl	H
77. 78.	H H	Isopropyl Isopropyl	H H	Ethyl Methyl	Ethyl Ethyl	H H
79.	Н	Isopropyl	Isopropyl	Н	Н	Н
80.	Η	Isopropyl	Н	Isopropyl	H	Н
81.	Н	Isopropyl	H	H	Isopropyl	H
82. 83.	H H	Isopropyl	H Methyl	H Isopropyl	H H	Isopropyl H
84.	Н	Isopropyl Isopropyl	Methyl	Н	Isopropyl	H
85.	H	Isopropyl	Methyl	H	Н	Isopropyl
86.	Η	Isopropyl	Н	Isopropyl	Methyl	Н
87.	H	Isopropyl	H	Isopropyl	Isopropyl	H
88. 89.	Н	Isopropyl	Н	Methyl Isopropyl	Isopropyl	H H
90.	H H	Isopropyl Isopropyl	H H	Ethyl	Ethyl Isopropyl	H H
91.	H	Isopropyl	Isobutyl	Н	Н	H
92.	Η	Isopropyl	Н	Isobutyl	H	Н
93.	H	Isopropyl	H	H	Isobutyl	H
94. 95.	H H	Isopropyl Isopropyl	H Methyl	H Isobutyl	H H	Isobutyl H
93. 96.	Н	Isopropyl	Methyl	ізовицуі Н	н Isobutyl	Н
97.	Н	Isopropyl	Methyl	H	H	Isobutyl
98.	H	Isopropyl	Н	Isobutyl	Methyl	Н
99.	Н	Isopropyl	H	Isobutyl	Isobutyl	H
100.	H	Isopropyl	H	Methyl	Isobutyl	H
101. 102.	H H	Isopropyl Isopropyl	H H	Isobutyl Ethyl	Ethyl Isobutyl	H H
102.	Н	Isopropyl	H	Isobutyl	Isopropyl	H
104.	Н	Isopropyl	H	Isopropyl	Isobutyl	H
105.	H	Isobutyl	H	Н	Н	Н
106.	Н	Isobutyl	Methyl	H	H	H
107. 108.	H H	Isobutyl	H H	Methyl H	H Mothyl	H H
108. 109.	н Н	Isobutyl Isobutyl	Н	H H	Methyl H	н Methyl
110.	Н	Isobutyl	Methyl	Methyl	Н	H
111.	Н	Isobutyl	Methyl	Н	Methyl	H
112.	Η	Isobutyl	Methyl	H	Н	Methyl
113.	Н	Isobutyl	H	Methyl	Methyl	Н

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TABLE 1-continued

		17 11)	LL I COIN	imaca		
Compound#	R_1	R_2	R ₃	R ₄	R ₅	R ₆
114.	Н	Isobutyl	Н	Methyl	Н	Methyl
	H	Isobutyl	H	Н	Methyl	Methyl
116.	H	Isobutyl	Methyl	Methyl	Methyl	Н
	H	Isobutyl	Methyl	Methyl	H	Methyl
	H	Isobutyl	Methyl	Н	Methyl	Methyl
	H	Isobutyl	H	Methyl	Methyl	Methyl
	H H	Isobutyl Isobutyl	Methyl Ethyl	Methyl H	Methyl H	Methyl H
	Н	Isobutyl	Н	Ethyl	Н	Н
	H	Isobutyl	H	H	Ethyl	Н
	H	Isobutyl	Н	Н	Н	Ethyl
	H	Isobutyl	Methyl	Ethyl	H	Н
	H	Isobutyl	Methyl	H	Ethyl	Н
	H	Isobutyl	Methyl	H	H	Ethyl
	H H	Isobutyl Isobutyl	H H	Ethyl Ethyl	Methyl Ethyl	H H
	H	Isobutyl	Н	Methyl	Ethyl	H
	H	Isobutyl	Isopropyl	Н	H	H
	H	Isobutyl	Н	Isopropyl	H	H
	H	Isobutyl	H	H	Isopropyl	H
	H	Isobutyl	H	H	H	Isopropyl
	H	Isobutyl	Methyl	Isopropyl	H	H
	H H	Isobutyl Isobutyl	Methyl Methyl	H H	Isopropyl H	H Isopropyl
	H	Isobutyl	Н	Isopropyl	Methyl	Н
	H	Isobutyl	H	Isopropyl	Isopropyl	H
	H	Isobutyl	H	Methyl	Isopropyl	H
	H	Isobutyl	H	Isopropyl	Ethyl	H
	H	Isobutyl	H	Ethyl	Isopropyl	H
	H	Isobutyl	Isobutyl	H	H	H
	H H	Isobutyl Isobutyl	H H	Isobutyl H	H Isobutyl	H H
	H	Isobutyl	H	H	H	Isobutyl
	H	Isobutyl	Methyl	Isobutyl	H	Н
148.	H	Isobutyl	Methyl	Н	Isobutyl	H
	H	Isobutyl	Methyl	H	H	Isobutyl
	H	Isobutyl	H	Isobutyl	Methyl	H
	H H	Isobutyl Isobutyl	H H	Isobutyl Methyl	Isobutyl Isobutyl	H H
	Н	Isobutyl	Н	Isobutyl	Ethyl	Н
	H	Isobutyl	Н	Ethyl	Isobutyl	Н
	H	Isobutyl	H	Isobutyl	Isopropyl	H
	H	Isobutyl	H	Isopropyl	Isobutyl	H
	Methyl	Methyl	H	H	H	H
	Methyl Methyl	Methyl Methyl	Methyl H	H Methyl	H H	H H
	Methyl	Methyl	Н	Н	Methyl	Н
	Methyl	Methyl	Н	Н	Н	Methyl
	Methyl	Methyl	Methyl	Methyl	H	Н
	Methyl	Methyl	Methyl	H	Methyl	H
	Methyl	Methyl	Methyl	H	H	Methyl
	Methyl	Methyl	H H	Methyl	Methyl	H Mathril
	Methyl Methyl	Methyl Methyl	Н	Methyl H	H Methyl	Methyl Methyl
	Methyl	Methyl	Methyl	Methyl	Methyl	H
	Methyl	Methyl	Methyl	Methyl	Н	Methyl
	Methyl	Methyl	Methyl	H	Methyl	Methyl
	Methyl	Methyl	H	Methyl	Methyl	Methyl
	Methyl	Methyl	Methyl Ethyl	Methyl H	Methyl H	Methyl H
	Methyl Methyl	Methyl Methyl	Н	Ethyl	Н	Н
	Methyl	Methyl	H	H	Ethyl	H
	Methyl	Methyl	H	H	Н	Ethyl
	Methyl	Methyl	Methyl	Ethyl	H	H
	Methyl	Methyl	Methyl	H	Ethyl	H
	Methyl	Methyl	Methyl	H	H Mathad	Ethyl
	Methyl Methyl	Methyl Methyl	H H	Ethyl Ethyl	Methyl Ethyl	H H
	Methyl	Methyl	Н	Methyl	Ethyl	Н
	Methyl	Methyl	Isopropyl	Н	Н	H
184.	Methyl	Methyl	Н	Isopropyl	H	H
	Methyl	Methyl	H	Н	Isopropyl	Н
	Methyl	Methyl	Н	H	H	Isopropyl
	Methyl	Methyl	Methyl	Isopropyl	H	Н
	Methyl Methyl	Methyl Methyl	Methyl Methyl	H H	Isopropyl H	H Isopropyl
	Methyl	Methyl	Н	Isopropyl	Methyl	Н
	Methyl	Methyl	Н	Isopropyl	Isopropyl	H

21 TABLE 1-continued

Compound#	R ₁	R_2	R ₃	R_4	R ₅	R_6
192.	Methyl	Methyl	Н	Methyl	Isopropyl	Н
193.	Methyl	Methyl	H	Isopropyl	Ethyl	H
194.	Methyl	Methyl	H	Ethyl	Isopropyl	H
195. 196.	Methyl Methyl	Methyl Methyl	Isobutyl H	H Isobutyl	H H	H H
197.	Methyl	Methyl	Н	Н	Isobutyl	H
198.	Methyl	Methyl	H	H	Н	Isobutyl
199.	Methyl	Methyl	Methyl	Isobutyl	H	Н
200.	Methyl	Methyl	Methyl	H	Isobutyl	H
201.	Methyl	Methyl	Methyl	Н	Н	Isobutyl
202.	Methyl	Methyl	H	Isobutyl	Methyl	H
203. 204.	Methyl Methyl	Methyl Methyl	H H	Isobutyl Methyl	Isobutyl	H H
205.	Methyl	Methyl	H	Isobutyl	Isobutyl Ethyl	H
206.	Methyl	Methyl	H	Ethyl	Isobutyl	H
207.	Methyl	Methyl	H	Isobutyl	Isopropyl	H
208.	Methyl	Methyl	H	Isopropyl	Isobutyl	H
209.	Methyl	Ethyl	H	H	H	H
210.	Methyl	Ethyl	Methyl	H	H	H
211.	Methyl	Ethyl	H	Methyl	H	H
212. 213.	Methyl	Ethyl	H H	H H	Methyl H	H Mathril
213. 214.	Methyl Methyl	Ethyl Ethyl	п Methyl	п Methyl	Н	Methyl H
215.	Methyl	Ethyl	Methyl	H	Methyl	H
216.	Methyl	Ethyl	Methyl	H	Н	Methyl
217.	Methyl	Ethyl	Н	Methyl	Methyl	Н
218.	Methyl	Ethyl	H	Methyl	Н	Methyl
219.	Methyl	Ethyl	H	H	Methyl	Methyl
220.	Methyl	Ethyl	Methyl	Methyl	Methyl	Н
221.	Methyl	Ethyl	Methyl	Methyl	H	Methyl
222.	Methyl	Ethyl	Methyl	H Mathad	Methyl	Methyl
223. 224.	Methyl Methyl	Ethyl Ethyl	H Methyl	Methyl Methyl	Methyl Methyl	Methyl Methyl
225.	Methyl	Ethyl	Ethyl	Н	Н	Н
226.	Methyl	Ethyl	H	Ethyl	H	H
227.	Methyl	Ethyl	H	Н	Ethyl	H
228.	Methyl	Ethyl	H	H	Н	Ethyl
229.	Methyl	Ethyl	Methyl	Ethyl	H	H
230.	Methyl	Ethyl	Methyl	H	Ethyl	Η
231.	Methyl	Ethyl	Methyl	H	H	Ethyl
232.	Methyl	Ethyl	H	Ethyl	Methyl	H
233. 234.	Methyl	Ethyl	H H	Ethyl Mothyl	Ethyl	H H
234.	Methyl Methyl	Ethyl Ethyl	Isopropyl	Methyl H	Ethyl H	Н
236.	Methyl	Ethyl	Н	Isopropyl	H	H
237.	Methyl	Ethyl	Н	Н	Isopropyl	H
238.	Methyl	Ethyl	H	H	Н	Isopropyl
239.	Methyl	Ethyl	Methyl	Isopropyl	H	H
240.	Methyl	Ethyl	Methyl	H	Isopropyl	Н
241.	Methyl	Ethyl	Methyl	Н	H	Isopropyl
242.	Methyl	Ethyl	H	Isopropyl	Methyl	H
243.	Methyl	Ethyl	Н	Isopropyl Mothyl	Isopropyl	Н
244. 245.	Methyl Methyl	Ethyl Ethyl	H H	Methyl Isopropyl	Ethyl	H H
246.	Methyl	Ethyl	H	Ethyl	Isopropyl	H
247.	Methyl	Ethyl	Isobutyl	Н	Н	H
248.	Methyl	Ethyl	Н	Isobutyl	H	H
249.	Methyl	Ethyl	H	H	Isobutyl	H
250.	Methyl	Ethyl	Н	H	H	Isobutyl
251.	Methyl	Ethyl	Methyl	Isobutyl	Н	H
252.	Methyl	Ethyl	Methyl Methyl	H	Isobutyl H	H
253. 254.	Methyl Methyl	Ethyl Ethyl	Н	H Isobutyl	п Methyl	Isobutyl H
255.	Methyl	Ethyl	H	Isobutyl	Isobutyl	H
256.	Methyl	Ethyl	Н	Methyl	Isobutyl	H
257.	Methyl	Ethyl	H	Isobutyl	Ethyl	H
258.	Methyl	Ethyl	H	Ethyl	Isobutyl	H
259.	Methyl	Ethyl	H	Isobutyl	Isopropyl	H
260.	Methyl	Ethyl	Н	Isopropyl	Isobutyl	H
261.	Methyl	Isopropyl	Н	H	H	H
262.	Methyl	Isopropyl	Methyl	H	H	H
263.	Methyl	Isopropyl	H	Methyl	H Mother!	H
264.	Methyl	Isopropyl	H H	H H	Methyl 11	H Methyl
	Methyl	Isopropyl			H	Methyl
265.	Methyl	Isopropul	Methyl			
265. 266.	Methyl Methyl	Isopropyl Isopropyl	Methyl Methyl	Methyl H	H Methyl	H H
265.	Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl	Methyl Methyl Methyl	H H	n Methyl H	H H Methyl

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TABLE 1-continued

Methyl	Isopropyl	H H H Methyl Methyl H Methyl H H H H H H H H H H H H H H H H H H H	Methyl H Methyl Methyl H H Methyl H H Ethyl H H Ethyl H H Ethyl H H Ethyl H H Isopropyl H H Isopropyl H H Isopropyl H H Isopropyl Methyl Isopropyl Methyl Isopropyl H H Isopropyl Methyl Isopropyl H H Isobutyl H Isobutyl H	H Methyl Methyl H Methyl H H H Ethyl H H Ethyl H H Isopropyl Isopr	Methyl Methyl H Methyl Methyl Methyl H H H H Ethyl H H H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	Methyl Methyl H Methyl Ethyl H H H H H H H H H H H H H H H H H H H	Methyl Methyl H Methyl H Ethyl H Ethyl H H Ethyl H H Ethyl Ethyl Methyl H H Ethyl Ethyl Methyl H Isopropyl H H Isopropyl Isopropyl Ethyl Isopropyl Ethyl H Isobutyl H H	Methyl H Methyl Methyl H H H Ethyl H H Ethyl H H Ethyl H H Sehyl Ethyl Ethyl H H Isopropyl H H Isopropyl H H Isopropyl H H Methyl Isopropyl Ethyl Isopropyl Ethyl Isopropyl H H Isopropyl H H H Isopropyl H H Methyl Isopropyl H H Methyl Isopropyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	H Methyl Methyl Methyl Methyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	Methyl Methyl H H H H H H H H H H H H H H H H H H H	Methyl H Methyl H Ethyl H Ethyl H H Ethyl H H Ethyl H H Isopropyl H Isopropyl H Isopropyl H Isopropyl H H Isopropyl H Isopropyl H H Isopropyl H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl H	H Methyl Methyl H H Ethyl H H Ethyl H H Ethyl H H Sopropyl H H Isopropyl H Methyl Isopropyl Ethyl Isopropyl H H Isobutyl H H H Isobutyl H H H H Isobutyl H H Methyl Isobutyl H H Methyl Isobutyl H Methyl	Methyl Methyl Methyl H H H Ethyl H H Ethyl H H H Isopropyl H H Isopropyl H H H Isopropyl H H H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	Methyl H Methyl H H H H H H H H H H H H H H H H H H H	H Methyl Methyl H Ethyl H H Ethyl H H Ethyl Ethyl H H Isopropyl H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Ethyl H Isobutyl H H Isobutyl H H Isobutyl H H Isobutyl H Isobutyl H H Isobutyl H H Isobutyl H Isobutyl H H Isobutyl H H Isobutyl H H Isobutyl	Methyl Methyl H H Ethyl H H Ethyl Ethyl Ethyl Ethyl Ethyl H H Isopropyl H Methyl Isopropyl Isopropyl Isopropyl Isopropyl H H H Isobutyl H H Isobutyl H H Isobutyl H H Isobutyl H Methyl Isopropyl Ethyl Isopropyl Ethyl Isopropyl H H H Isobutyl H H Isobutyl H H H Isobutyl H H H H Methyl Isobutyl H Methyl	Methyl Methyl H H H Ethyl H H Ethyl H H H Isopropyl H H Isopropyl H H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	H Methyl Ethyl H H H Methyl Methyl H H H H H Methyl Methyl H H H H H H H H H H H H H H H H H H H	Methyl Methyl H H Ethyl H H Ethyl Ethyl Ethyl H H Isopropyl H H Isopropyl H H Isopropyl Methyl Isopropyl Isopropyl Isopropyl Ethyl H Isobutyl H H Isobutyl	Methyl Methyl H H H Ethyl H H H Ethyl Ethyl Ethyl Ethyl Ethyl H H Isopropyl H H Methyl Isopropyl Isopropyl Isopropyl Isopropyl Ethyl Isopropyl H H H Isobutyl H H H Isobutyl H H Methyl Isopropyl Ethyl Isopropyl Ethyl Isopropyl H H Methyl Isopropyl H H H Isobutyl H H H Isobutyl H H H H H H H H H H Methyl	Methyl Methyl H H H Ethyl H H Ethyl H H H H Isopropyl H H Isopropyl H H Isobutyl H H Isobutyl H Isobutyl H Isobutyl H
Methyl	Isopropyl	Methyl Ethyl H H H H Methyl Methyl H H H Isopropyl H H H H Isopropyl H H H H H H H H H H H H H H H H H H H	Methyl H Ethyl H H Ethyl H H Ethyl H H Ethyl Ethyl Methyl H Isopropyl H H Isopropyl H H Isopropyl Isopropyl Ethyl Isopropyl Ethyl H H Isopropyl Ethyl H Isobutyl H H Isobutyl H H Isobutyl H H Isobutyl H Isobutyl H	Methyl H H Ethyl H H Ethyl H Methyl Ethyl Ethyl H H Isopropyl H H Isopropyl H Methyl Isopropyl Isopropyl Ethyl Isopropyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	Methyl H H H Ethyl H H Ethyl H H H H H H Isopropyl H H Isopropyl H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	Ethyl H H H H H Methyl Methyl H H Isopropyl H H H H H H H H H H H H H H H H H H H	H Ethyl H H Ethyl H H Ethyl H H Ethyl Ethyl Ethyl Methyl H Isopropyl H H Isobutyl H H Isobutyl H H Isobutyl	H H H H H Ethyl H Methyl Ethyl Ethyl H H Isopropyl H H Isopropyl H Methyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H H H H H H H H H H H H H H H H H H H	H H H Ethyl H H Ethyl H H H Isopropyl H H Isopropyl H H Isopropyl H H Isopropyl H H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	H H H H Methyl Methyl Methyl H H Isopropyl H H H Methyl Methyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	Ethyl H H Ethyl H Ethyl H Sopropyl H Isopropyl H Isopropyl H Isopropyl H Isopropyl H Isopropyl I	H Ethyl H H Ethyl H Methyl Ethyl Ethyl H H Isopropyl H Isopropyl H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H H Isobutyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	H H Ethyl H H Ethyl H H H H H H H Isopropyl H H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	H H H Methyl Methyl H H H Isopropyl H H H H H H H H Isobutyl H H H H H H H H H H H H H H H H H H H	H H Ethyl H H Ethyl Ethyl Methyl H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H Isobutyl H Isobutyl	Ethyl H H H Ethyl H Methyl Ethyl H H Isopropyl H H Isopropyl H H Isobutyl H H H H H H H H H H H H H H H H H H H	H Ethyl H H Ethyl H H H H H Isopropyl H H Isopropyl H H H Isopropyl H H H H H H H H H H H H H H H H H H H
Methyl	Isopropyl	H Methyl Methyl H H H H H H H H H H H H H H H H H H H	H Ethyl H H Ethyl Ethyl Ethyl Methyl H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl H H Isopropyl Isopropyl Isopropyl H H Isopropyl Isopropyl H H Isobutyl H H Isobutyl H Isobutyl H Isobutyl	H H H Ethyl H Methyl Ethyl Ethyl H H Isopropyl H Isopropyl H Methyl Isopropyl Ethyl Isopropyl H H Isobutyl H H Isobutyl H H H H H H H H H H H H H H H H H H H	Ethyl H H H H H H H Isopropyl H Isopropyl H H Isobutyl H Isobutyl H Isobutyl H
Methyl	Isopropyl	Methyl Methyl H H H Isopropyl H H H H Methyl Methyl H H H H H H H H H H H H H H H H H H H	H H Ethyl Ethyl Ethyl Methyl H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H H Isobutyl H Isobutyl H Isobutyl	Ethyl H Methyl Ethyl H H Isopropyl H H Isopropyl H Methyl Isopropyl Isopropyl Isopropyl Ithyl Isopropyl H H H Isobutyl H H Isobutyl H H Isobutyl H Methyl Isopropyl H H Isobutyl H Methyl Isopropyl H H Isobutyl H H H Isobutyl H Methyl Isobutyl H	H Ethyl H H H H H Isopropyl H Isopropyl H H H Isobutyl H Isobutyl H Isobutyl H
Methyl	Isopropyl	Methyl H H H Isopropyl H H H H H H H H H H H H H H H H H H H	H Ethyl Ethyl Ethyl Methyl H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H Isobutyl H Isobutyl H Isobutyl	H Methyl Ethyl Ethyl Ethyl Ethyl H H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H H Isobutyl H H Isobutyl H H Methyl Isobutyl H H Methyl Isobutyl H H Methyl Isobutyl H Methyl	Ethyl H H H H H Isopropyl H H Isopropyl H H H Isobutyl H Isobutyl H
Methyl	Isopropyl	H H H Isopropyl H H H H Methyl Methyl H H H Isobutyl H H H H H Isobutyl H H H H H H H H H H H H H H H H H H H	Ethyl Ethyl Methyl H Isopropyl H H Isopropyl H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H Isopopyl Isopropyl Isopropyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl	Methyl Ethyl Ethyl H H Isopropyl H Isopropyl H Methyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H H H H H H H H H H H H H H H H H H H	H H H H Isopropyl H Isopropyl H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	H H H Isopropyl H H H H Methyl Methyl H H H Isobutyl H H Isobutyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	Ethyl Methyl H H Isopropyl H H Isopropyl H H Isopropyl Isopropyl Isopropyl Ethyl Isopropyl H H Isobutyl H H Isobutyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl H	Ethyl Ethyl H H Isopropyl H H Isopropyl H Methyl Isopropyl Ethyl Isopropyl Ethyl Isopropyl H H H Isobutyl H H H H H H H H H H H H H H H Methyl	H H H H Isopropyl H Isopropyl H H H H H H H H H H H Isobutyl H Isobutyl H H Isobutyl
Methyl	Isopropyl	H Isopropyl H H H H Methyl Methyl H H H H H H H H H H H H H H H H H H H	Methyl H Isopropyl H H Isopropyl H H Isopropyl Isopropyl Methyl Isopropyl Ethyl H Isobutyl H H Isobutyl H H Isobutyl H H Isobutyl H Isobutyl H H Isobutyl H	Ethyl H H Isopropyl H Isopropyl H Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl H H Isobutyl H H Isobutyl H H H H H H H H H H H H H H H H H H H	H H H H Isopropyl H Isopropyl H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	Isopropyl H H H H Methyl Methyl Methyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	H Isopropyl H H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Ethyl H Isobutyl H H Isobutyl H H Isobutyl H Isobutyl H H Isobutyl	H H Isopropyl H H Isopropyl H Methyl Isopropyl Ethyl Isopropyl H H Isobutyl H Isobutyl H H H H H H H H H H H H H H H H H H H	H H H Isopropyl H Isopropyl H H H H H H H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	H H H Methyl Methyl Methyl H H H H H H H H Methyl H H H H H H H H H H H H H H H H H H H	Isopropyl H H Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Ethyl Isobutyl H Isobutyl H Isobutyl H Isobutyl	H Isopropyl H H Isopropyl H Methyl Isopropyl Ethyl Isopropyl H H H Isobutyl H H Isobutyl H H H Methyl H H H H H H H Methyl	H H Isopropyl H H Isopropyl H H H H H H H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	H H H Methyl Methyl H H H H Isobutyl H H H Methyl H H H H H H H H H H H H H H H H H H H	H H H Isopropyl H H Isopropyl Isopropyl Isopropyl Ethyl Isobutyl H Isobutyl H Isobutyl H Isobutyl	Isopropyl H H Isopropyl H Methyl Isopropyl Ethyl Isopropyl Ethyl Isopropyl H H Isobutyl H Isobutyl H H H H H H Methyl	H Isopropyl H H Isopropyl H H H H H H H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	H Methyl Methyl H H H H Isobutyl H H H Isobutyl H H H H H H H H H H H H H H H H H H H	H Isopropyl H H Isopropyl Isopropyl Methyl Isopropyl Ethyl H Isobutyl H H Isobutyl H H Isobutyl	H H Isopropyl H Methyl Isopropyl Isopropyl Ethyl Isopropyl H H Isobutyl H H Isobutyl H H Methyl	Isopropyl H H Isopropyl H H H H H H H H H H H Isobutyl H Isobutyl H
Methyl	Isopropyl	Methyl Methyl H H H H H H H Methyl H H H H H H H H H H H H H H H H H H H	Isopropyl H H Isopropyl Isopropyl Isopropyl Isopropyl Ethyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl	H Isopropyl H Methyl Isopropyl Isopropyl Ethyl Isopropyl H H Isobutyl H H Isobutyl H H H Methyl	H H Isopropyl H H H H H H H H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	Methyl Methyl H H H H Isobutyl H H H Methyl H H H H H H H H H H H H H H H H H H H	H H Isopropyl Isopropyl Methyl Isopropyl Ethyl H Isobutyl H H Isobutyl H Isobutyl	H Methyl Isopropyl Isopropyl Ethyl Isopropyl H H Isobutyl H Isobutyl H H M H Methyl	Isopropyl H H H H H H H ISObutyl H Isobutyl H Isobutyl H
Methyl	Isopropyl	H H H H Isobutyl H H H Methyl Methyl H H H H	Isopropyl Isopropyl Methyl Isopropyl Ethyl H Isobutyl H H Isobutyl H H Isobutyl	Methyl Isopropyl Isopropyl Ethyl Isopropyl H H Isobutyl H H Isobutyl H Methyl	H H H H H H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	H H H H Isobutyl H H H Methyl Methyl Methyl H H H H	Isopropyl Methyl Isopropyl Ethyl H Isobutyl H Isobutyl H H Isobutyl H H Isobutyl	Isopropyl Isopropyl Ethyl Isopropyl H H Isobutyl H Isobutyl H Methyl	H H H H H H H H Isobutyl H Isobutyl H Isobutyl
Methyl	Isopropyl	H H H Isobutyl H H H Methyl Methyl Methyl H H	Methyl Isopropyl Ethyl H Isobutyl H Isobutyl H Isobutyl H Isobutyl	Isopropyl Ethyl Isopropyl H H Isobutyl H H Isobutyl H Isobutyl H Methyl	H H H H H Isobutyl H H Isobutyl H H Isobutyl
Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	H H Isobutyl H H H H H H Methyl Methyl Methyl H H H	Isopropyl Ethyl H Isobutyl H Isobutyl H H Isobutyl H Isobutyl	Ethyl Isopropyl H H Isobutyl H Isobutyl H M Isobutyl H Isobutyl H Methyl	H H H H Isobutyl H Isobutyl
Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	H Isobutyl H H H H Methyl Methyl Methyl H H H	Ethyl H Isobutyl H H Isobutyl H Isobutyl H H Isobutyl	Isopropyl H H Isobutyl H H Isobutyl H Methyl	H H H Isobutyl H H Isobutyl
Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	Isobutyl H H H Methyl Methyl Methyl H H H	H Isobutyl H H Isobutyl H H H Isobutyl H H Isobutyl	H H Isobutyl H Isobutyl H Isobutyl H Methyl	H H Isobutyl H H Isobutyl
Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	H H H Methyl Methyl Methyl H H	Isobutyl H H Isobutyl H H Isobutyl	H Isobutyl H H Isobutyl H Methyl	H H Isobutyl H H Isobutyl H
Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	H H Methyl Methyl Methyl H H	H H Isobutyl H H Isobutyl	Isobutyl H H Isobutyl H Methyl	H Isobutyl H H Isobutyl H
Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	H Methyl Methyl Methyl H H	H Isobutyl H H Isobutyl	H H Isobutyl H Methyl	Isobutyl H H Isobutyl H
Methyl Methyl Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	Methyl Methyl H H	H H Isobutyl	Isobutyl H Methyl	H H Isobutyl H
Methyl Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl Isopropyl Isopropyl	Methyl H H	H Isobutyl	H Methyl	Isobutyl H
Methyl Methyl Methyl	Isopropyl Isopropyl Isopropyl	H H	Isobutyl	Methyl	Н
Methyl Methyl	Isopropyl Isopropyl	H			
Methyl	Isopropyl		Isobutyl	Isobutyl	H
			3.6 (1.1	T 1 (1	**
Memyr	Taamaanul	H	Methyl	Isobutyl	H H
Methyl	Isopropyl Isopropyl	H H	Isobutyl Ethyl	Ethyl Isobutyl	Н
Methyl	Isopropyl	H	Isobutyl	Isopropyl	H
Methyl	Isopropyl	Н	Isopropyl	Isobutyl	H
Methyl	Isobutyl	H	Н	Н	H
Methyl	Isobutyl	Methyl	H	H	H
Methyl	Isobutyl	H	Methyl	H	H
Methyl	Isobutyl	H	H	Methyl	Н
Methyl	Isobutyl	H	H	H	Methyl
Methyl	Isobutyl	Methyl	Methyl H	H Methyl	H H
Methyl Methyl	Isobutyl Isobutyl	Methyl Methyl	Н	Н	н Methyl
Methyl	Isobutyl	Н	Methyl	Methyl	H
Methyl	Isobutyl	H	Methyl	Н	Methyl
Methyl	Isobutyl	Н	Н	Methyl	Methyl
Methyl	Isobutyl	Methyl	Methyl	Methyl	Н
Methyl	Isobutyl	Methyl	Methyl	H	Methyl
			Н		Methyl
					Methyl
					Methyl
		•			H
					H H
					Ethyl
					Н
Methyl		Methyl	Н	Ethyl	Н
Methyl	Isobutyl	Methyl	H	Н	Ethyl
Methyl	Isobutyl	Н	Ethyl	Methyl	Н
Methyl	Isobutyl	H	Ethyl	Ethyl	H
	Isobutyl				H
			H		H
metnyl					H H
					H Isopropyl
Methyl					H H
Methyl Methyl	Isobutul				H
Methyl Methyl Methyl		Methyl			Isopropyl
Methyl Methyl Methyl Methyl	Isobutyl	•	H		1 17
Methyl Methyl Methyl		Methyl Methyl H	H Isopropyl	Methyl	H
	Methyl	Methyl Isobutyl	Methyl Isobutyl Methyl Methyl Isobutyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Methyl Isobutyl H Methyl Isobutyl Ethyl Methyl Isobutyl H Methyl Isobutyl H Methyl Isobutyl H Methyl Isobutyl H Methyl Isobutyl Methyl Methyl Isobutyl Methyl Methyl Isobutyl Methyl Methyl Isobutyl Methyl Isobutyl H Methyl Isobutyl Methyl Isobutyl Methyl Isobutyl Methyl	Methyl Isobutyl Methyl Methyl Methyl Isobutyl Methyl Hethyl Isobutyl Methyl Hethyl Methyl Methyl Isobutyl Hethyl Methyl Methyl Isobutyl Hethyl Methyl Isobutyl Hethyl Isobutyl Methyl Ethyl Methyl Isobutyl Methyl Ethyl Methyl Isobutyl Methyl Hethyl Isobutyl Methyl Hethyl Isobutyl Methyl Hethyl Isobutyl Hethyl Methyl Isobutyl Hethyl Isobutyl Methyl Isopropyl Methyl Isobutyl Methyl Isopropyl	Methyl Isobutyl Methyl Methyl Methyl Methyl Isobutyl Methyl Methyl H Methyl Isobutyl Methyl Methyl Methyl Methyl Isobutyl H Methyl Methyl Methyl Isobutyl Methyl Methyl Methyl Methyl Isobutyl H H H Methyl Isobutyl H H H Methyl Isobutyl Methyl Ethyl H Methyl Isobutyl Methyl H Ethyl Methyl Isobutyl Methyl H H Methyl Isobutyl Methyl H H Methyl Isobutyl H H H Methyl Isobutyl

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TABLE 1-continued

Compound#	R ₁	R_2	R_3	R_4	R_5	R_6
348.	Methyl	Isobutyl	Н	Methyl	Isopropyl	Н
349.	Methyl	Isobutyl	H	Isopropyl	Ethyl	H
350.	Methyl	Isobutyl	H	Ethyl	Isopropyl	H
351.	Methyl	Isobutyl	Isobutyl	Н	H	H
352.	Methyl	Isobutyl	H	Isobutyl	H	H
353.	Methyl	Isobutyl	H	H	Isobutyl	H
354.	Methyl	Isobutyl	H Mothyd	H Igobutul	Н	Isobutyl H
355. 356.	Methyl Methyl	Isobutyl Isobutyl	Methyl Methyl	Isobutyl H	H Isobutyl	Н
357.	Methyl	Isobutyl	Methyl	H	Н	Isobutyl
358.	Methyl	Isobutyl	Н	Isobutyl	Methyl	Н
359.	Methyl	Isobutyl	H	Isobutyl	Isobutyl	H
360.	Methyl	Isobutyl	Н	Methyl	Isobutyl	Н
361.	Methyl	Isobutyl	H	Isobutyl	Ethyl	Н
362.	Methyl	Isobutyl	H	Ethyl	Isobutyl	H
363.	Methyl	Isobutyl	H	Isobutyl	Isopropyl	H
364.	Methyl	Isobutyl	H	Isopropyl	Isobutyl	H
365.	Ethyl	H	H	H	H	H
366.	Ethyl	H	Methyl	Н	H	H
367.	Ethyl	H	H	Methyl	Н	H
368.	Ethyl	H	H	H	Methyl	H
369.	Ethyl	H	H	H	H	Methyl
370.	Ethyl	H	Methyl	Methyl	H Mathad	H
371. 372.	Ethyl	H H	Methyl	H H	Methyl 11	H Mathyl
372. 373.	Ethyl Ethyl	п Н	Methyl H	п Methyl	H Methyl	Methyl H
374.	Ethyl	H	H	Methyl	H	Methyl
375.	Ethyl	H	H	H	Methyl	Methyl
376.	Ethyl	H	Methyl	Methyl	Methyl	Н
377.	Ethyl	H	Methyl	Methyl	Н	Methyl
378.	Ethyl	H	Methyl	Н	Methyl	Methyl
379.	Ethyl	Н	Н	Methyl	Methyl	Methyl
380.	Ethyl	H	Methyl	Methyl	Methyl	Methyl
381.	Ethyl	H	Ethyl	Н	Н	Н
382.	Ethyl	H	Н	Ethyl	H	H
383.	Ethyl	H	H	H	Ethyl	H
384.	Ethyl	H	H	H	H	Ethyl
385.	Ethyl	H	Methyl	Ethyl	H	H
386.	Ethyl	H	Methyl	Н	Ethyl	H
387.	Ethyl	H	Methyl	H	H	Ethyl
388.	Ethyl	H	H	Ethyl	Methyl	H
389. 390.	Ethyl	H H	H H	Ethyl Mothyl	Ethyl	H H
390. 391.	Ethyl Ethyl	Н		Methyl H	Ethyl H	Н
392.	Ethyl	H	Isopropyl H	Isopropyl	H	Н
393.	Ethyl	Н	H	Н	Isopropyl	H
394.	Ethyl	Н	Н	Н	Н	Isopropyl
395.	Ethyl	Н	Methyl	Isopropyl	Н	Н
396.	Ethyl	H	Methyl	Н	Isopropyl	H
397.	Ethyl	Н	Methyl	H	Н	Isopropyl
398.	Ethyl	Н	н .	Isopropyl	Methyl	Н
399.	Ethyl	H	H	Isopropyl	Isopropyl	H
400.	Ethyl	H	H	Methyl	Isopropyl	H
401.	Ethyl	H	Н	Isopropyl	Ethyl	H
402.	Ethyl	H	H	Ethyl	Isopropyl	H
403.	Ethyl	H	Isobutyl	H	H	H
404.	Ethyl	H	H	Isobutyl	Н	H
405.	Ethyl	H	H	H	Isobutyl	H
406.	Ethyl	H	H	H	H	Isobutyl
407. 408.	Ethyl Ethyl	H	Methyl	Isobutyl	H	H
408. 409.	Ethyl	H H	Methyl Methyl	H H	Isobutyl H	H Isobutyl
410.	Ethyl	H	Н	Isobutyl	Methyl	H
411.	Ethyl	H	H	Isobutyl	Isobutyl	H
412.	Ethyl	H	H	Methyl	Isobutyl	H
413.	Ethyl	H	H	Isobutyl	Ethyl	H
414.	Ethyl	H	H	Ethyl	Isobutyl	H
415.	Ethyl	H	H	Isobutyl	Isopropyl	H
416.	Ethyl	H	H	Isopropyl	Isobutyl	H
417.	Ethyl	Methyl	H	Н	Н	H
418.	Ethyl	Methyl	Methyl	Н	H	H
419.	Ethyl	Methyl	Н	Methyl	H	H
420.	Ethyl	Methyl	H	Н	Methyl	H
	Ethyl	Methyl	H	Н	Н	Methyl
421.			Mathed	Methyl	H	Н
421. 422.	Ethyl	Methyl	Methyl	meany		11
422. 423.	Ethyl Ethyl	Methyl Methyl	Methyl	Н	Methyl	Н
422.						

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			BLE 1-con				
Compound #	≠ R ₁	R_2	R ₃	R ₄	R ₅	R ₆	
426.	Ethyl	Methyl	Н	Methyl	Н	Methyl	_
427.	Ethyl	Methyl	Н	Н	Methyl	Methyl	
428.	Ethyl	Methyl	Methyl	Methyl	Methyl	H	
429.	Ethyl	Methyl	Methyl	Methyl	H	Methyl	
430. 431.	Ethyl Ethyl	Methyl	Methyl H	H Mothyd	Methyl	Methyl	
431.	Ethyl	Methyl Methyl	n Methyl	Methyl Methyl	Methyl Methyl	Methyl Methyl	
433.	Ethyl	Methyl	Ethyl	H	Н	Н	
434.	Ethyl	Methyl	H	Ethyl	Н	Н	
435.	Ethyl	Methyl	Н	Н	Ethyl	Н	
436.	Ethyl	Methyl	H	H	Н	Ethyl	
437.	Ethyl	Methyl	Methyl	Ethyl	Η	H	
438.	Ethyl	Methyl	Methyl	H	Ethyl	H	
439.	Ethyl	Methyl	Methyl	H	H	Ethyl	
440. 441.	Ethyl	Methyl	H H	Ethyl	Methyl	H H	
442.	Ethyl Ethyl	Methyl Methyl	H	Ethyl Methyl	Ethyl Ethyl	H	
443.	Ethyl	Methyl	Isopropyl	Н	H	H	
444.	Ethyl	Methyl	Н	Isopropyl	H	Н	
445.	Ethyl	Methyl	Н	Н	Isopropyl	Н	
446.	Ethyl	Methyl	H	H	Н	Isopropyl	
447.	Ethyl	Methyl	Methyl	Isopropyl	H	H	
448.	Ethyl	Methyl	Methyl	H	Isopropyl	H	
449.	Ethyl	Methyl	Methyl	H	H	Isopropyl	
450.	Ethyl	Methyl	H	Isopropyl	Methyl	H	
451. 452.	Ethyl Ethyl	Methyl Methyl	H H	Isopropyl Methyl	Isopropyl	H H	
453.	Ethyl	Methyl	H	Isopropyl	Isopropyl Ethyl	H	
454.	Ethyl	Methyl	H	Ethyl	Isopropyl	H	
455.	Ethyl	Methyl	Isobutyl	Н	Н	H	
456.	Ethyl	Methyl	Н	Isobutyl	H	Н	
457.	Ethyl	Methyl	Н	H	Isobutyl	H	
458.	Ethyl	Methyl	Н	Н	H	Isobutyl	
459.	Ethyl	Methyl	Methyl	Isobutyl	H	H	
460. 461.	Ethyl Ethyl	Methyl Methyl	Methyl Methyl	H H	Isobutyl H	H Isobutyl	
462.	Ethyl	Methyl	Н	Isobutyl	Methyl	H	
463.	Ethyl	Methyl	H	Isobutyl	Isobutyl	Н	
464.	Ethyl	Methyl	Н	Methyl	Isobutyl	Н	
465.	Ethyl	Methyl	H	Isobutyl	Ethyl	Н	
466.	Ethyl	Methyl	Н	Ethyl	Isobutyl	Н	
467.	Ethyl	Methyl	H	Isobutyl	Isopropyl	H	
468. 469.	Ethyl	Methyl	H H	Isopropyl	Isobutyl	H H	
409. 470.	Ethyl Ethyl	Ethyl Ethyl	п Methyl	H H	H H	Н	
471.	Ethyl	Ethyl	Н	Methyl	Н	Н	
472.	Ethyl	Ethyl	Н	Н	Methyl	Н	
473.	Ethyl	Ethyl	Н	H	Н	Methyl	
474.	Ethyl	Ethyl	Methyl	Methyl	H	H	
475.	Ethyl	Ethyl	Methyl	Η	Methyl	Н	
476.	Ethyl	Ethyl	Methyl	Н	Н	Methyl	
477. 478.	Ethyl	Ethyl	H	Methyl	Methyl	H Methyl	
478. 479.	Ethyl Ethyl	Ethyl Ethyl	H H	Methyl H	H Methyl	Methyl	
480.	Ethyl	Ethyl	Methyl	Methyl	Methyl	H	
481.	Ethyl	Ethyl	Methyl	Methyl	Н	Methyl	
482.	Ethyl	Ethyl	Methyl	Н	Methyl	Methyl	
483.	Ethyl	Ethyl	Н	Methyl	Methyl	Methyl	
484.	Ethyl	Ethyl	Methyl	Methyl	Methyl	Methyl	
485.	Ethyl	Ethyl	Ethyl	Н	H	H	
486.	Ethyl	Ethyl	H H	Ethyl	H	H H	
487. 488.	Ethyl Ethyl	Ethyl Ethyl	п Н	H H	Ethyl H	п Ethyl	
489.	Ethyl	Ethyl	Methyl	Ethyl	H	H	
490.	Ethyl	Ethyl	Methyl	Н	Ethyl	Н	
491.	Ethyl	Ethyl	Methyl	H	H	Ethyl	
492.	Ethyl	Ethyl	Н	Ethyl	Methyl	Н	
493.	Ethyl	Ethyl	H	Ethyl	Ethyl	H	
	Ethyl	Ethyl	H	Methyl	Ethyl	H	
494.	Ethyl	Ethyl	Isopropyl	Η	H	H	
495.	TO 1 1	Ethyl	Н	Isopropyl H	H Isopropyl	H H	
495. 496.	Ethyl		LI	F1			
495. 496. 497.	Ethyl	Ethyl	Н				
495. 496. 497. 498.	Ethyl Ethyl	Ethyl Ethyl	H	H	Н	Isopropyl	
495. 496. 497. 498. 499.	Ethyl Ethyl Ethyl	Ethyl Ethyl Ethyl	H Methyl	H Isopropyl	H H	Isopropyl H	
495. 496. 497. 498.	Ethyl Ethyl	Ethyl Ethyl	H	H	Н	Isopropyl	
495. 496. 497. 498. 499. 500.	Ethyl Ethyl Ethyl Ethyl	Ethyl Ethyl Ethyl Ethyl	H Methyl Methyl	H Isopropyl H	H H Isopropyl	Isopropyl H H	

TABLE 1-continued

Compound	# R ₁	R_2	R ₃	R ₄	R ₅	R ₆
504.	Ethyl	Ethyl	Н	Methyl	Isopropyl	Н
505.	Ethyl	Ethyl	H	Isopropyl	Ethyl	Н
506. 507.	Ethyl Ethyl	Ethyl Ethyl	H Isobutyl	Ethyl H	Isopropyl H	H H
508.	Ethyl	Ethyl	H	n Isobutyl	Н	Н
509.	Ethyl	Ethyl	H	Н	Isobutyl	Н
510.	Ethyl	Ethyl	H	H	Н	Isobutyl
511. 512.	Ethyl Ethyl	Ethyl Ethyl	Methyl Methyl	Isobutyl H	H Isobutyl	H H
513.	Ethyl	Ethyl	Methyl	H	Н	Isobutyl
514.	Ethyl	Ethyl	Н	Isobutyl	Methyl	Н
515. 516.	Ethyl Ethyl	Ethyl Ethyl	H H	Isobutyl Methyl	Isobutyl Isobutyl	H H
517.	Ethyl	Ethyl	H	Isobutyl	Ethyl	H
518.	Ethyl	Ethyl	H	Ethyl	Isobutyl	Н
519. 520.	Ethyl	Ethyl	H H	Isobutyl	Isopropyl	H H
520. 521.	Ethyl Ethyl	Ethyl Isopropyl	Н	Isopropyl H	Isobutyl H	H H
522.	Ethyl	Isopropyl	Methyl	H	H	Н
523.	Ethyl	Isopropyl	H	Methyl	H	H
524. 525.	Ethyl Ethyl	Isopropyl Isopropyl	H H	H H	Methyl H	H Methyl
526.	Ethyl	Isopropyl	Methyl	Methyl	H	Н
527.	Ethyl	Isopropyl	Methyl	H	Methyl	Н
528. 529.	Ethyl Ethyl	Isopropyl	Methyl H	H Methyl	H Methyl	Methyl H
530.	Ethyl	Isopropyl Isopropyl	H	Methyl	Н	Methyl
531.	Ethyl	Isopropyl	H	Н	Methyl	Methyl
532.	Ethyl	Isopropyl	Methyl	Methyl	Methyl	H
533. 534.	Ethyl Ethyl	Isopropyl Isopropyl	Methyl Methyl	Methyl H	H Methyl	Methyl Methyl
535.	Ethyl	Isopropyl	Н	Methyl	Methyl	Methyl
536.	Ethyl	Isopropyl	Methyl	Methyl	Methyl	Methyl
537. 538.	Ethyl Ethyl	Isopropyl Isopropyl	Ethyl H	H Ethyl	H H	H H
539.	Ethyl	Isopropyl	H	Н	Ethyl	H
540.	Ethyl	Isopropyl	H	H	Н	Ethyl
541. 542.	Ethyl	Isopropyl	Methyl	Ethyl H	H Ethyd	H H
542. 543.	Ethyl Ethyl	Isopropyl Isopropyl	Methyl Methyl	Н	Ethyl H	п Ethyl
544.	Ethyl	Isopropyl	Н	Ethyl	Methyl	Н
545.	Ethyl	Isopropyl	H	Ethyl	Ethyl	H
546. 547.	Ethyl Ethyl	Isopropyl Isopropyl	H Isopropyl	Methyl H	Ethyl H	H H
548.	Ethyl	Isopropyl	Н	Isopropyl	Н	H
549.	Ethyl	Isopropyl	H	H	Isopropyl	H
550. 551.	Ethyl Ethyl	Isopropyl Isopropyl	H Methyl	H Isopropyl	H H	Isopropyl H
552.	Ethyl	Isopropyl	Methyl	Н	Isopropyl	Н
553.	Ethyl	Isopropyl	Methyl	Н	Н	Isopropyl
554. 555.	Ethyl Ethyl	Isopropyl	H H	Isopropyl	Methyl	H H
556.	Ethyl	Isopropyl Isopropyl	Н	Isopropyl Methyl	Isopropyl Isopropyl	H H
557.	Ethyl	Isopropyl	H	Isopropyl	Ethyl	Н
558.	Ethyl	Isopropyl	H	Ethyl	Isopropyl	H H
559. 560.	Ethyl Ethyl	Isopropyl Isopropyl	Isobutyl H	H Isobutyl	H H	Н
561.	Ethyl	Isopropyl	Н	Н	Isobutyl	H
562.	Ethyl	Isopropyl	Н	H	H	Isobutyl
563. 564.	Ethyl Ethyl	Isopropyl Isopropyl	Methyl Methyl	Isobutyl H	H Isobutyl	H H
565.	Ethyl	Isopropyl	Methyl	H	Н	Isobutyl
566.	Ethyl	Isopropyl	Н	Isobutyl	Methyl	Н
567. 568.	Ethyl Ethyl	Isopropyl Isopropyl	H H	Isobutyl Methyl	Isobutyl Isobutyl	H H
569.	Ethyl	Isopropyl	Н	Isobutyl	Ethyl	Н
570.	Ethyl	Isopropyl	H	Ethyl	Isobutyl	H
571.	Ethyl	Isopropyl	H	Isobutyl	Isopropyl	H
572. 573.	Ethyl Ethyl	Isopropyl Isobutyl	H H	Isopropyl H	Isobutyl H	H H
574.	Ethyl	Isobutyl	Methyl	Н	Н	Н
575.	Ethyl	Isobutyl	H	Methyl	H	H
576. 577.	Ethyl Ethyl	Isobutyl Isobutyl	H H	H H	Methyl H	H Methyl
578.	Ethyl	Isobutyl	п Methyl	п Methyl	п Н	Н
579.	Ethyl	Isobutyl	Methyl	Н	Methyl	Н
580.	Ethyl	Isobutyl	Methyl	H	H Mathaul	Methyl
581.	Ethyl	Isobutyl	H	Methyl	Methyl	Н

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TABLE 1-continued

		TAB	LE 1-con	tinued		
Compound#	R_1	R_2	R ₃	R_4	R_5	R ₆
582.	Ethyl	Isobutyl	Н	Methyl	Н	Methyl
583.	Ethyl	Isobutyl	H	H	Methyl	Methyl
584.	Ethyl	Isobutyl	Methyl	Methyl	Methyl	H
585. 586.	Ethyl Ethyl	Isobutyl Isobutyl	Methyl Methyl	Methyl H	H Methyl	Methyl Methyl
580. 587.	Ethyl	Isobutyl	Н	п Methyl	Methyl	Methyl
588.	Ethyl	Isobutyl	Methyl	Methyl	Methyl	Methyl
589.	Ethyl	Isobutyl	Ethyl	Н	Н	H
590.	Ethyl	Isobutyl	Н	Ethyl	H	Н
591.	Ethyl	Isobutyl	Н	Н	Ethyl	Н
592.	Ethyl	Isobutyl	H	H	Н	Ethyl
593.	Ethyl	Isobutyl	Methyl	Ethyl	Н	Н
594.	Ethyl	Isobutyl	Methyl	Н	Ethyl	H
595.	Ethyl	Isobutyl	Methyl	H	H	Ethyl
596.	Ethyl	Isobutyl	H	Ethyl	Methyl	H
597.	Ethyl	Isobutyl	H	Ethyl	Ethyl	H
598.	Ethyl	Isobutyl	H	Methyl	Ethyl	H
599.	Ethyl	Isobutyl	Isopropyl	H	H	H
600.	Ethyl	Isobutyl	H	Isopropyl	H	H
601.	Ethyl	Isobutyl	H	H	Isopropyl	H
602. 603.	Ethyl Ethyl	Isobutyl Isobutyl	H Methyl	H Isopropyl	H H	Isopropyl H
604.	Ethyl	Isobutyl	Methyl	Н	Isopropyl	H
605.	Ethyl	Isobutyl	Methyl	H	Н	Isopropyl
606.	Ethyl	Isobutyl	H	Isopropyl	Methyl	Н
607.	Ethyl	Isobutyl	H	Isopropyl	Isopropyl	H
608.	Ethyl	Isobutyl	H	Methyl	Isopropyl	H
609.	Ethyl	Isobutyl	H	Isopropyl	Ethyl	H
610.	Ethyl	Isobutyl	H	Ethyl	Isopropyl	Н
611.	Ethyl	Isobutyl	Isobutyl	н	Н	Н
612.	Ethyl	Isobutyl	Н	Isobutyl	H	H
613.	Ethyl	Isobutyl	H	H	Isobutyl	H
614.	Ethyl	Isobutyl	H	H	H	Isobutyl
615.	Ethyl	Isobutyl	Methyl	Isobutyl	H	H
616.	Ethyl	Isobutyl	Methyl	H	Isobutyl	H
617.	Ethyl	Isobutyl	Methyl	Н	H	Isobutyl
618.	Ethyl	Isobutyl	H	Isobutyl	Methyl	H
619.	Ethyl	Isobutyl	H	Isobutyl	Isobutyl	H
620.	Ethyl	Isobutyl	H	Methyl	Isobutyl	H
621.	Ethyl	Isobutyl	H H	Isobutyl	Ethyl	H H
622. 623.	Ethyl Ethyl	Isobutyl Isobutyl	Н	Ethyl Isobutyl	Isobutyl	Н
624.	Ethyl	Isobutyl	Н	Isopropyl	Isopropyl Isobutyl	Н
625.	Isopropyl	Н	H	Н	Н	H
626.	Isopropyl	H	Methyl	Н	H	Н
627.	Isopropyl	Н	Н	Methyl	H	H
628.	Isopropyl	Н	Н	Н	Methyl	Н
629.	Isopropyl	Н	H	H	Н	Methyl
630.	Isopropyl	H	Methyl	Methyl	H	Н
631.	Isopropyl	Н	Methyl	Н	Methyl	H
632.	Isopropyl	H	Methyl	H	Н	Methyl
633.	Isopropyl	H	H	Methyl	Methyl	H
634.	Isopropyl	H	H	Methyl	H	Methyl
635.	Isopropyl	H	H	H	Methyl	Methyl
636.	Isopropyl	H	Methyl	Methyl	Methyl	Н
637.	Isopropyl	H	Methyl	Methyl	H	Methyl
638.	Isopropyl	H	Methyl	H	Methyl	Methyl
639.	Isopropyl	H	H	Methyl	Methyl	Methyl
640.	Isopropyl	H	Methyl	Methyl	Methyl	Methyl
641. 642.	Isopropyl Isopropyl	H	Ethyl	H	H H	H H
643.	Isopropyl	H H	H H	Ethyl H	Ethyl	H
644.	Isopropyl	H	H	H	Н	Ethyl
645.	Isopropyl	H	Methyl	Ethyl	H	Н
646.	Isopropyl	H	Methyl	H	Ethyl	H
647.	Isopropyl	H	Methyl	H	H	Ethyl
648.	Isopropyl	H	Н	Ethyl	Methyl	Н
649.	Isopropyl	H	H	Ethyl	Ethyl	H
650.	Isopropyl	H	H	Methyl	Ethyl	Н
651.	Isopropyl	H	Isopropyl	Н	Н	H
652.	Isopropyl	H	Н	Isopropyl	H	H
032.	Isopropyl	H	H	Н	Isopropyl	Н
653.			H	H	Н	Isopropyl
	Isopropyl	H				
653.	Isopropyl Isopropyl	H H	Methyl	Isopropyl	H	H
653. 654.			Methyl Methyl	Isopropyl H	H Isopropyl	H H
653. 654. 655.	Isopropyl	H	Methyl			
653. 654. 655. 656.	Isopropyl Isopropyl	H H	Methyl Methyl	Н	Isopropyl	Н

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TABLE 1-continued

Compound#	R ₁	R_2	R ₃	R_4	R_5	R_6
660.	Isopropyl	Н	Н	Methyl	Isopropyl	Н
661.	Isopropyl	H	H	Isopropyl	Ethyl	Н
662.	Isopropyl	H	Н	Ethyl	Isopropyl	H
663.	Isopropyl	H	Isobutyl	H	H	H
664. 665.	Isopropyl Isopropyl	H H	H H	Isobutyl H	H Isobutyl	H H
666.	Isopropyl	Н	H	H	H	Isobutyl
667.	Isopropyl	H	Methyl	Isobutyl	H	Н
668.	Isopropyl	H	Methyl	Н	Isobutyl	Н
669.	Isopropyl	H	Methyl	H	Н	Isobutyl
670.	Isopropyl	H	H	Isobutyl	Methyl	H
671.	Isopropyl	Η	H	Isobutyl	Isobutyl	H
672.	Isopropyl	H	H	Methyl	Isobutyl	H
673.	Isopropyl	H	H	Isobutyl	Ethyl	H
674. 675.	Isopropyl	H H	H H	Ethyl	Isobutyl	H H
676.	Isopropyl Isopropyl	Н	Н	Isobutyl Isopropyl	Isopropyl Isobutyl	Н
677.	Isopropyl	Methyl	H	Н	Н	H
678.	Isopropyl	Methyl	Methyl	Н	Н	H
679.	Isopropyl	Methyl	Н	Methyl	H	H
680.	Isopropyl	Methyl	H	Н	Methyl	H
681.	Isopropyl	Methyl	H	Н	Н	Methyl
682.	Isopropyl	Methyl	Methyl	Methyl	Н	Н
683.	Isopropyl	Methyl	Methyl	H	Methyl	H
684.	Isopropyl	Methyl	Methyl	H Mathad	H	Methyl
685. 686	Isopropyl	Methyl	Н	Methyl	Methyl 11	H Mathyl
686. 687.	Isopropyl Isopropyl	Methyl Methyl	H H	Methyl H	H Methyl	Methyl Methyl
688.	Isopropyl	Methyl	Methyl	Methyl	Methyl	Н
689.	Isopropyl	Methyl	Methyl	Methyl	Н	Methyl
690.	Isopropyl	Methyl	Methyl	Н	Methyl	Methyl
691.	Isopropyl	Methyl	Н	Methyl	Methyl	Methyl
692.	Isopropyl	Methyl	Methyl	Methyl	Methyl	Methyl
693.	Isopropyl	Methyl	Ethyl	H	H	H
694.	Isopropyl	Methyl	H	Ethyl	H	H
695.	Isopropyl	Methyl	H	Н	Ethyl	H
696.	Isopropyl	Methyl	H	H	H	Ethyl
697. 698.	Isopropyl	Methyl Methyl	Methyl Methyl	Ethyl H	H Ethyl	H H
699.	Isopropyl Isopropyl	Methyl	Methyl	Н	Н	п Ethyl
700.	Isopropyl	Methyl	Н	Ethyl	Methyl	H
701.	Isopropyl	Methyl	Н	Ethyl	Ethyl	Н
702.	Isopropyl	Methyl	Н	Methyl	Ethyl	Н
703.	Isopropyl	Methyl	Isopropyl	Н	Н	H
704.	Isopropyl	Methyl	Н	Isopropyl	H	Н
705.	Isopropyl	Methyl	H	Н	Isopropyl	Н
706.	Isopropyl	Methyl	Н	Н	H	Isopropyl
707.	Isopropyl	Methyl	Methyl	Isopropyl	Н	H
708.	Isopropyl	Methyl	Methyl	H	Isopropyl	H
709.	Isopropyl	Methyl	Methyl	H	H Mathaul	Isopropyl
710. 711.	Isopropyl	Methyl Methyl	H H	Isopropyl	Methyl	H H
711.	Isopropyl Isopropyl	Methyl	п Н	Isopropyl Methyl	Isopropyl Isopropyl	п Н
713.	Isopropyl	Methyl	H	Isopropyl	Ethyl	H
714.	Isopropyl	Methyl	H	Ethyl	Isopropyl	Н
715.	Isopropyl	Methyl	Isobutyl	Н	Н	Н
716.	Isopropyl	Methyl	Н	Isobutyl	Н	Н
717.	Isopropyl	Methyl	H	H	Isobutyl	Н
718.	Isopropyl	Methyl	H	H	H	Isobutyl
719.	Isopropyl	Methyl	Methyl	Isobutyl	H	H
720. 721.	Isopropyl	Methyl Methyl	Methyl Methyl	H H	Isobutyl H	H Isobutul
721. 722.	Isopropyl Isopropyl	Methyl Methyl	Metnyi H	н Isobutyl	н Methyl	Isobutyl H
723.	Isopropyl	Methyl	Н	Isobutyl	Isobutyl	Н
724.	Isopropyl	Methyl	H	Methyl	Isobutyl	H
725.	Isopropyl	Methyl	H	Isobutyl	Ethyl	H
726.	Isopropyl	Methyl	H	Ethyl	Isobutyl	H
727.	Isopropyl	Methyl	H	Isobutyl	Isopropyl	H
	Isopropyl	Methyl	H	Isopropyl	Isobutyl	H
728.	Isopropyl	Ethyl	H	H	H	H
729.		Ethyl	Methyl	H	H	H
729. 730.	Isopropyl			Methyl	H	H
729. 730. 731.	Isopropyl	Ethyl	H		Master 1	TT
729. 730. 731. 732.	Isopropyl Isopropyl	Ethyl Ethyl	H	Н	Methyl	H Mothyd
729. 730. 731. 732. 733.	Isopropyl Isopropyl Isopropyl	Ethyl Ethyl Ethyl	H H	H H	Н	Methyl
729. 730. 731. 732. 733. 734.	Isopropyl Isopropyl Isopropyl Isopropyl	Ethyl Ethyl Ethyl Ethyl	H H Methyl	H H Methyl	H H	Methyl H
729. 730. 731. 732. 733.	Isopropyl Isopropyl Isopropyl	Ethyl Ethyl Ethyl	H H	H H	Н	Methyl

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TABLE 1-continued

Compound#	R ₁	R_2	R ₃	R ₄	R ₅	R ₆	
738.	Isopropyl	Ethyl	Н	Methyl	Н	Methyl	
739.	Isopropyl	Ethyl	Н	H	Methyl	Methyl	
740.	Isopropyl	Ethyl	Methyl	Methyl	Methyl	H Mathril	
741. 742.	Isopropyl	Ethyl Ethyl	Methyl Methyl	Methyl H	H Methyl	Methyl Methyl	
742. 743.	Isopropyl	Ethyl	Methyl H	п Methyl	Methyl Methyl	Methyl	
743. 744.	Isopropyl Isopropyl	Ethyl	п Methyl	Methyl	Methyl	Methyl	
745.	Isopropyl	Ethyl	Ethyl	H	H	H	
746.	Isopropyl	Ethyl	H	Ethyl	Н	H	
747.	Isopropyl	Ethyl	Н	Н	Ethyl	Н	
748.	Isopropyl	Ethyl	H	H	Н	Ethyl	
749.	Isopropyl	Ethyl	Methyl	Ethyl	H	Н	
750.	Isopropyl	Ethyl	Methyl	Н	Ethyl	H	
751.	Isopropyl	Ethyl	Methyl	H	H	Ethyl	
752.	Isopropyl	Ethyl	H	Ethyl	Methyl	H	
753.	Isopropyl	Ethyl	H	Ethyl	Ethyl	H	
754.	Isopropyl	Ethyl	H	Methyl	Ethyl	H	
755.	Isopropyl	Ethyl	Isopropyl	Н	H	H	
756.	Isopropyl	Ethyl	H	Isopropyl	H	H	
757.	Isopropyl	Ethyl	H	H	Isopropyl	H I	
758.	Isopropyl	Ethyl	H Mothyd	H	H	Isopropyl	
759. 760.	Isopropyl	Ethyl Ethyl	Methyl Methyl	Isopropyl H	H Isopropyl	H H	
760. 761.	Isopropyl Isopropyl	Ethyl Ethyl	Methyl	H H	Isopropyl H	н Isopropyl	
761. 762.	Isopropyl	Ethyl	Н	н Isopropyl	н Methyl	Isopropyi H	
763.	Isopropyl	Ethyl	H	Isopropyl	Isopropyl	H	
764.	Isopropyl	Ethyl	H	Methyl	Isopropyl	H	
765.	Isopropyl	Ethyl	H	Isopropyl	Ethyl	H	
766.	Isopropyl	Ethyl	H	Ethyl	Isopropyl	H	
767.	Isopropyl	Ethyl	Isobutyl	Н	н	H	
768.	Isopropyl	Ethyl	Н	Isobutyl	H	Н	
769.	Isopropyl	Ethyl	H	Н	Isobutyl	H	
770.	Isopropyl	Ethyl	H	H	H	Isobutyl	
771.	Isopropyl	Ethyl	Methyl	Isobutyl	H	H	
772.	Isopropyl	Ethyl	Methyl	H	Isobutyl	H	
773.	Isopropyl	Ethyl	Methyl	H	H	Isobutyl	
774.	Isopropyl	Ethyl	H	Isobutyl	Methyl	H	
775.	Isopropyl	Ethyl	Н	Isobutyl	Isobutyl	H	
776.	Isopropyl	Ethyl	H	Methyl	Isobutyl	H	
777.	Isopropyl	Ethyl	H	Isobutyl	Ethyl	H	
778. 779.	Isopropyl	Ethyl	H H	Ethyl	Isobutyl	H H	
779. 780.	Isopropyl	Ethyl Ethyl	Н	Isobutyl	Isopropyl Isobutyl	Н	
780.	Isopropyl Isopropyl	Isopropyl	Н	Isopropyl H	H	Н	
782.	Isopropyl	Isopropyl	Methyl	Н	H	H	
783.	Isopropyl	Isopropyl	Н	Methyl	Н	Н	
784.	Isopropyl	Isopropyl	Н	Н	Methyl	Н	
785.	Isopropyl	Isopropyl	Н	Н	Н	Methyl	
786.	Isopropyl	Isopropyl	Methyl	Methyl	H	Н	
787.	Isopropyl	Isopropyl	Methyl	Н	Methyl	H	
788.	Isopropyl	Isopropyl	Methyl	Н	Н	Methyl	
789.	Isopropyl	Isopropyl	Н	Methyl	Methyl	Н	
790.	Isopropyl	Isopropyl	H	Methyl	Н	Methyl	
791.	Isopropyl	Isopropyl	Н	Н	Methyl	Methyl	
792.	Isopropyl	Isopropyl	Methyl	Methyl	Methyl	Н	
793.	Isopropyl	Isopropyl	Methyl	Methyl	H	Methyl	
794.	Isopropyl	Isopropyl	Methyl	H Mathad	Methyl	Methyl	
795.	Isopropyl	Isopropyl	H Mathyl	Methyl	Methyl	Methyl	
796.	Isopropyl	Isopropyl	Methyl	Methyl ⊔	Methyl ⊔	Methyl	
797. 798.	Isopropyl	Isopropyl Isopropyl	Ethyl H	H Ethyl	Н	H H	
798. 799.	Isopropyl Isopropyl	Isopropyl	H H	Etnyi H	H Ethyl	H H	
800.	Isopropyl	Isopropyl	Н	Н	Н	n Ethyl	
801.	Isopropyl	Isopropyl	Methyl	Ethyl	H	Н	
802.	Isopropyl	Isopropyl	Methyl	H	Ethyl	H	
803.	Isopropyl	Isopropyl	Methyl	H	H	Ethyl	
804.	Isopropyl	Isopropyl	Н	Ethyl	Methyl	Н	
805.	Isopropyl	Isopropyl	Н	Ethyl	Ethyl	H	
806.	Isopropyl	Isopropyl	Н	Methyl	Ethyl	H	
807.	Isopropyl	Isopropyl	Isopropyl	Н	Н	H	
808.	Isopropyl	Isopropyl	Н	Isopropyl	Н	H	
809.	Isopropyl	Isopropyl	Н	Н	Isopropyl	H	
	Isopropyl	Isopropyl	H	H	H	Isopropyl	
810.			Methyl	Isopropyl	H	Н	
810. 811.	Isopropyl	Isopropyl					
810. 811. 812.	Isopropyl	Isopropyl	Methyl	Н	Isopropyl	H	
810. 811. 812. 813.	Isopropyl Isopropyl	Isopropyl Isopropyl	Methyl Methyl	H H	Isopropyl H	H Isopropyl	
810. 811. 812.	Isopropyl	Isopropyl	Methyl	Н	Isopropyl	H	

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TABLE 1-continued

			BLE 1-con			
Compound#	R ₁	R ₂	R ₃	R ₄	R ₅	R ₆
816. 817.	Isopropyl Isopropyl	Isopropyl Isopropyl	H H	Methyl Isopropyl	Isopropyl Ethyl	H H
818.	Isopropyl	Isopropyl	Н	Ethyl	Isopropyl	H
819.	Isopropyl	Isopropyl	Isobutyl	Н	Н	H
820.	Isopropyl	Isopropyl	Н	Isobutyl	Н	H
821.	Isopropyl	Isopropyl	H	H	Isobutyl	Н
822.	Isopropyl	Isopropyl	H	H	H	Isobutyl
823. 824.	Isopropyl Isopropyl	Isopropyl Isopropyl	Methyl Methyl	Isobutyl H	H Isobutyl	H H
825.	Isopropyl	Isopropyl	Methyl	Н	Н	Isobutyl
826.	Isopropyl	Isopropyl	Н	Isobutyl	Methyl	Н
827.	Isopropyl	Isopropyl	Н	Isobutyl	Isobutyl	H
828.	Isopropyl	Isopropyl	H	Methyl	Isobutyl	H
829. 830.	Isopropyl Isopropyl	Isopropyl Isopropyl	H H	Isobutyl Ethyl	Ethyl Isobutyl	H H
831.	Isopropyl	Isopropyl	H	Isobutyl	Isopropyl	H
832.	Isopropyl	Isopropyl	H	Isopropyl	Isobutyl	H
833.	Isopropyl	Isobutyl	H	Н	Н	H
834.	Isopropyl	Isobutyl	Methyl	H	H	H
835. 836.	Isopropyl Isopropyl	Isobutyl	H H	Methyl H	H Methyl	H H
830. 837.	Isopropyl	Isobutyl Isobutyl	Н	Н	Н	п Methyl
838.	Isopropyl	Isobutyl	Methyl	Methyl	H	Н
839.	Isopropyl	Isobutyl	Methyl	Н	Methyl	H
840.	Isopropyl	Isobutyl	Methyl	Н	Н	Methyl
841.	Isopropyl	Isobutyl	H	Methyl	Methyl	H Mathad
842. 843.	Isopropyl Isopropyl	Isobutyl Isobutyl	H H	Methyl H	H Methyl	Methyl Methyl
844.	Isopropyl	Isobutyl	Methyl	Methyl	Methyl	H
845.	Isopropyl	Isobutyl	Methyl	Methyl	Н	Methyl
846.	Isopropyl	Isobutyl	Methyl	Н	Methyl	Methyl
847.	Isopropyl	Isobutyl	H	Methyl	Methyl	Methyl
848. 849.	Isopropyl Isopropyl	Isobutyl Isobutyl	Methyl Ethyl	Methyl H	Methyl H	Methyl H
850.	Isopropyl	Isobutyl	H	Ethyl	H	H
851.	Isopropyl	Isobutyl	Н	Н	Ethyl	H
852.	Isopropyl	Isobutyl	H	Н	Н	Ethyl
853.	Isopropyl	Isobutyl	Methyl	Ethyl	H	H
854. 855.	Isopropyl Isopropyl	Isobutyl Isobutyl	Methyl Methyl	H H	Ethyl H	H Ethyl
856.	Isopropyl	Isobutyl	H	Ethyl	Methyl	H
857.	Isopropyl	Isobutyl	Н	Ethyl	Ethyl	Н
858.	Isopropyl	Isobutyl	Н	Methyl	Ethyl	H
859.	Isopropyl	Isobutyl	Isopropyl	H	H	H
860. 861.	Isopropyl Isopropyl	Isobutyl Isobutyl	H H	Isopropyl H	H Isopropyl	H H
862.	Isopropyl	Isobutyl	Н	Н	Н	Isopropyl
863.	Isopropyl	Isobutyl	Methyl	Isopropyl	H	Н
864.	Isopropyl	Isobutyl	Methyl	Н	Isopropyl	H
865.	Isopropyl	Isobutyl	Methyl	Н	Н	Isopropyl
866. 867.	Isopropyl Isopropyl	Isobutyl Isobutyl	H H	Isopropyl	Methyl Isopropyl	H H
868.	Isopropyl	Isobutyl	Н	Isopropyl Methyl	Isopropyl	л Н
869.	Isopropyl	Isobutyl	H	Isopropyl	Ethyl	Н
870.	Isopropyl	Isobutyl	H	Ethyl	Isopropyl	H
871.	Isopropyl	Isobutyl	Isobutyl	Н	H	H
872. 873.	Isopropyl Isopropyl	Isobutyl Isobutyl	H H	Isobutyl H	H Isobutyl	H H
874.	Isopropyl	Isobutyl	H	H	H	Isobutyl
875.	Isopropyl	Isobutyl	Methyl	Isobutyl	H	Н
876.	Isopropyl	Isobutyl	Methyl	Н	Isobutyl	H
877.	Isopropyl	Isobutyl	Methyl	Н	Н	Isobutyl
878. 879.	Isopropyl	Isobutyl Isobutyl	H H	Isobutyl Isobutyl	Methyl Isobutyl	H H
880.	Isopropyl Isopropyl	Isobutyl	H	Methyl	Isobutyl	H
881.	Isopropyl	Isobutyl	H	Isobutyl	Ethyl	H
882.	Isopropyl	Isobutyl	H	Ethyl	Isobutyl	H
883.	Isopropyl	Isobutyl	H	Isobutyl	Isopropyl	H
884.	Isopropyl	Isobutyl 11	H	Isopropyl ப	Isobutyl ப	H
885. 886.	Isobutyl Isobutyl	H H	H Methyl	H H	H H	H H
887.	Isobutyl	Н	Н	п Methyl	Н	Н
888.	Isobutyl	Н	Н	Н	Methyl	H
889.	Isobutyl	H	H	Н	Н	Methyl
890.	Isobutyl	H	Methyl	Methyl	H	H
891.	Isobutyl	Н	Methyl	Н	Methyl	H Mothyl
892. 893.	Isobutyl Isobutyl	H H	Methyl H	H Methyl	H Methyl	Methyl H
023.	1500uty1	11	11	wientyi	wientyi	11

TABLE 1-continued

TABLE I Continued							
Compound#	R_1	R_2	R ₃	R ₄	R ₅	R ₆	
894.	Isobutyl	Н	Н	Methyl	Н	Methyl	
895.	Isobutyl	H	H	Н	Methyl	Methyl	
896.	Isobutyl	H	Methyl	Methyl	Methyl	Н	
897.	Isobutyl	H	Methyl	Methyl	H	Methyl	
898.	Isobutyl	H	Methyl	H	Methyl	Methyl	
899.	Isobutyl	H	H	Methyl	Methyl	Methyl	
900. 901.	Isobutyl Isobutyl	H H	Methyl Ethyl	Methyl H	Methyl H	Methyl H	
901.	Isobutyl	Н	Н	п Ethyl	Н	Н	
903.	Isobutyl	Н	H	Н	Ethyl	Н	
904.	Isobutyl	H	H	H	Н	Ethyl	
905.	Isobutyl	H	Methyl	Ethyl	H	Н	
906.	Isobutyl	H	Methyl	H	Ethyl	H	
907.	Isobutyl	H	Methyl	H	H	Ethyl	
908. 909.	Isobutyl Isobutyl	H H	H H	Ethyl Ethyl	Methyl Ethyl	H H	
909. 910.	Isobutyl	Н	Н	Methyl	Ethyl	Н	
911.	Isobutyl	H	Isopropyl	Н	H	H	
912.	Isobutyl	H	Н	Isopropyl	H	H	
913.	Isobutyl	H	H	Н	Isopropyl	H	
914.	Isobutyl	H	H	H	H	Isopropyl	
915.	Isobutyl	H	Methyl	Isopropyl	H	H	
916.	Isobutyl	H	Methyl	H	Isopropyl	H	
917. 918.	Isobutyl Isobutyl	H H	Methyl H	H Isopropyl	H Methyl	Isopropyl H	
919.	Isobutyl	H	H	Isopropyl	Isopropyl	H	
920.	Isobutyl	H	Н	Methyl	Isopropyl	H	
921.	Isobutyl	H	H	Isopropyl	Ethyl	H	
922.	Isobutyl	H	H	Ethyl	Isopropyl	H	
923.	Isobutyl	H	Isobutyl	H	H	H	
924.	Isobutyl	H	H	Isobutyl	H	H	
925. 926.	Isobutyl Isobutyl	H H	H H	H H	Isobutyl H	H Isobutyl	
920. 927.	Isobutyl	Н	Methyl	Isobutyl	Н	H	
928.	Isobutyl	H	Methyl	Н	Isobutyl	H	
929.	Isobutyl	H	Methyl	H	Н	Isobutyl	
930.	Isobutyl	H	H	Isobutyl	Methyl	H	
931.	Isobutyl	H	H	Isobutyl	Isobutyl	H	
932.	Isobutyl	H	H	Methyl	Isobutyl	H	
933. 934.	Isobutyl Isobutyl	H H	H H	Isobutyl Ethyl	Ethyl Isobutyl	H H	
935.	Isobutyl	H	H	Isobutyl	Isopropyl	Н	
936.	Isobutyl	Н	Н	Isopropyl	Isobutyl	H	
937.	Isobutyl	Methyl	H	Н	Н	H	
938.	Isobutyl	Methyl	Methyl	H	H	H	
939.	Isobutyl	Methyl	H	Methyl	H	H	
940. 941.	Isobutyl	Methyl	H H	H H	Methyl H	H Mothvil	
941. 942.	Isobutyl Isobutyl	Methyl Methyl	н Methyl	n Methyl	Н	Methyl H	
943.	Isobutyl	Methyl	Methyl	Н	Methyl	Н	
944.	Isobutyl	Methyl	Methyl	H	Н	Methyl	
945.	Isobutyl	Methyl	Н	Methyl	Methyl	Н	
946.	Isobutyl	Methyl	H	Methyl	H	Methyl	
947.	Isobutyl	Methyl	H	H	Methyl	Methyl	
948. 949.	Isobutyl Isobutyl	Methyl Methyl	Methyl Methyl	Methyl Methyl	Methyl H	H Methyl	
949. 950.	Isobutyl	Methyl	Methyl	Н	n Methyl	Methyl	
951.	Isobutyl	Methyl	Н	Methyl	Methyl	Methyl	
952.	Isobutyl	Methyl	Methyl	Methyl	Methyl	Methyl	
953.	Isobutyl	Methyl	Ethyl	Н	Н	H	
954.	Isobutyl	Methyl	H	Ethyl	H	H	
955.	Isobutyl	Methyl	H	H	Ethyl	H	
956. 957.	Isobutyl	Methyl	H Mathrel	H Ethyl	H H	Ethyl	
957. 958.	Isobutyl Isobutyl	Methyl Methyl	Methyl Methyl	H	Ethyl	H H	
959.	Isobutyl	Methyl	Methyl	H	H	Ethyl	
960.	Isobutyl	Methyl	H	Ethyl	Methyl	H	
961.	Isobutyl	Methyl	H	Ethyl	Ethyl	H	
962.	Isobutyl	Methyl	H	Methyl	Ethyl	H	
963.	Isobutyl	Methyl	Isopropyl	Н	H	H	
964.	Isobutyl	Methyl	H	Isopropyl	H	H	
965.	Isobutyl	Methyl	H	H	Isopropyl	H	
966. 967.	Isobutyl Isobutyl	Methyl Methyl	H Methyl	H Isopropyl	H H	Isopropyl H	
967. 968.	Isobutyl	Methyl	Methyl	Н	п Isopropyl	Н	
969.	Isobutyl	Methyl	Methyl	Н	Н	Isopropyl	
970.	Isobutyl	Methyl	Н	Isopropyl	Methyl	Н	
971.	Isobutyl	Methyl	H	Isopropyl	Isopropyl	H	

41 TABLE 1-continued

Compound#	R_1	R_2	R ₃	R_4	R_5	R_6
972.	Isobutyl	Methyl	Н	Methyl	Isopropyl	Н
973.	Isobutyl	Methyl	H	Isopropyl	Ethyl	H
974.	Isobutyl	Methyl	Н	Ethyl	Isopropyl	H
975.	Isobutyl	Methyl	Isobutyl	H	H	H
976. 977.	Isobutyl	Methyl	H H	Isobutyl H	H Iaobutul	H H
977. 978.	Isobutyl Isobutyl	Methyl Methyl	Н	Н	Isobutyl H	п Isobutyl
979.	Isobutyl	Methyl	Methyl	Isobutyl	H	Н
980.	Isobutyl	Methyl	Methyl	Н	Isobutyl	Н
981.	Isobutyl	Methyl	Methyl	Н	Н	Isobutyl
982.	Isobutyl	Methyl	Н	Isobutyl	Methyl	Н
983.	Isobutyl	Methyl	Н	Isobutyl	Isobutyl	H
984.	Isobutyl	Methyl	H	Methyl	Isobutyl	H
985.	Isobutyl	Methyl	H	Isobutyl	Ethyl	H
986.	Isobutyl	Methyl	H	Ethyl	Isobutyl	H
987.	Isobutyl	Methyl	H	Isobutyl	Isopropyl	H
988.	Isobutyl	Methyl	H	Isopropyl	Isobutyl	H
989.	Isobutyl	Ethyl	H	H	H	H
990.	Isobutyl	Ethyl	Methyl	H	H	H
991. 992.	Isobutyl	Ethyl	H H	Methyl H	H Mathril	H H
992. 993.	Isobutyl Isobutyl	Ethyl Ethyl	Н	Н	Methyl H	н Methyl
993. 994.	Isobutyl	Ethyl	Methyl	Methyl	H	Н
995.	Isobutyl	Ethyl	Methyl	Н	Methyl	H
996.	Isobutyl	Ethyl	Methyl	H	H	Methyl
997.	Isobutyl	Ethyl	Н	Methyl	Methyl	Н
998.	Isobutyl	Ethyl	H	Methyl	Н	Methyl
999.	Isobutyl	Ethyl	H	Н	Methyl	Methyl
1000.	Isobutyl	Ethyl	Methyl	Methyl	Methyl	Н
1001.	Isobutyl	Ethyl	Methyl	Methyl	Н	Methyl
1002.	Isobutyl	Ethyl	Methyl	H	Methyl	Methyl
1003.	Isobutyl	Ethyl	H	Methyl	Methyl	Methyl
1004.	Isobutyl	Ethyl	Methyl	Methyl	Methyl	Methyl
1005.	Isobutyl	Ethyl	Ethyl	Н	H	H
1006.	Isobutyl	Ethyl	H	Ethyl	H	H
1007.	Isobutyl	Ethyl	H	H	Ethyl	H
1008.	Isobutyl	Ethyl	H Mathril	H	H	Ethyl
1009. 1010.	Isobutyl Isobutyl	Ethyl Ethyl	Methyl Methyl	Ethyl H	H Ethyl	H H
1010.	Isobutyl	Ethyl	Methyl	Н	Н	Ethyl
1012.	Isobutyl	Ethyl	Н	Ethyl	Methyl	Н
1013.	Isobutyl	Ethyl	Н	Ethyl	Ethyl	Н
1014.	Isobutyl	Ethyl	H	Methyl	Ethyl	H
1015.	Isobutyl	Ethyl	Isopropyl	Н	Н	H
1016.	Isobutyl	Ethyl	н	Isopropyl	H	H
1017.	Isobutyl	Ethyl	H	Н	Isopropyl	H
1018.	Isobutyl	Ethyl	H	H	H	Isopropyl
1019.	Isobutyl	Ethyl	Methyl	Isopropyl	H	H
1020.	Isobutyl	Ethyl	Methyl	H	Isopropyl	H
1021.	Isobutyl	Ethyl	Methyl	Н	Н	Isopropyl
1022.	Isobutyl	Ethyl	H	Isopropyl	Methyl	H
1023.	Isobutyl	Ethyl	H	Isopropyl	Isopropyl	H
1024.	Isobutyl	Ethyl	H	Methyl	Isopropyl	Н
1025. 1026.	Isobutyl Isobutyl	Ethyl Ethyl	H H	Isopropyl Ethyl	Ethyl Isopropyl	H H
1020.	Isobutyl	Ethyl	Isobutyl	H	Н	Н
1027.	Isobutyl	Ethyl	H	Isobutyl	H	H
1029.	Isobutyl	Ethyl	H	Н	Isobutyl	H
1030.	Isobutyl	Ethyl	H	H	Н	Isobutyl
1031.	Isobutyl	Ethyl	Methyl	Isobutyl	Н	Н
1032.	Isobutyl	Ethyl	Methyl	Н	Isobutyl	H
1033.	Isobutyl	Ethyl	Methyl	Н	Н	Isobutyl
1034.	Isobutyl	Ethyl	H	Isobutyl	Methyl	H
1035.	Isobutyl	Ethyl	H	Isobutyl	Isobutyl	H
1036.	Isobutyl	Ethyl	H	Methyl	Isobutyl	H
1037.	Isobutyl	Ethyl	H	Isobutyl	Ethyl	H
1038. 1039.	Isobutyl	Ethyl	H H	Ethyl Icobutyl	Isobutyl	H H
	Isobutyl Isobutyl	Ethyl Ethyl	Н	Isobutyl Isopropyl	Isopropyl Isobutyl	H H
1040. 1041.	Isobutyl	Isopropyl	Н	H H	H	Н
1041.	Isobutyl	Isopropyl	н Methyl	Н	Н	Н
1042.	Isobutyl	Isopropyl	Н	Methyl	Н	Н
1043.	Isobutyl	Isopropyl	Н	Н	Methyl	Н
1045.	Isobutyl	Isopropyl	H	H	H	Methyl
		Isopropyl	Methyl	Methyl	H	Н
1046.	Isobutyl					
	Isobutyl		Methyl	Н	Methyl	H
1046.		Isopropyl Isopropyl		H H	Methyl H	H Methyl

TABLE 1-continued

	_		LE 1-cont		_	_
Compound #	R ₁	R ₂	R ₃	R ₄	R ₅	R ₆
	Isobutyl Isobutyl	Isopropyl	H H	Methyl H	H Methyl	Methyl Methyl
	Isobutyl	Isopropyl Isopropyl	Methyl	Methyl	Methyl	Н
	Isobutyl	Isopropyl	Methyl	Methyl	Н	Methyl
	Isobutyl	Isopropyl	Methyl	Н	Methyl	Methyl
	Isobutyl	Isopropyl	H	Methyl	Methyl	Methyl
	Isobutyl	Isopropyl	Methyl	Methyl	Methyl	Methyl
	Isobutyl	Isopropyl	Ethyl	H	H H	H H
	Isobutyl Isobutyl	Isopropyl Isopropyl	H H	Ethyl H	н Ethyl	Н
	Isobutyl	Isopropyl	Н	H	Н	Ethyl
	Isobutyl	Isopropyl	Methyl	Ethyl	H	Н
	Isobutyl	Isopropyl	Methyl	H	Ethyl	H
	Isobutyl	Isopropyl	Methyl	H	H	Ethyl
	Isobutyl Isobutyl	Isopropyl Isopropyl	H H	Ethyl Ethyl	Methyl Ethyl	H H
	Isobutyl	Isopropyl	Н	Methyl	Ethyl	H
	Isobutyl	Isopropyl	Isopropyl	Н	Н	H
	Isobutyl	Isopropyl	Н	Isopropyl	H	H
	Isobutyl	Isopropyl	H	H	Isopropyl	H
	Isobutyl	Isopropyl	H	H	H	Isopropyl
	Isobutyl Isobutyl	Isopropyl Isopropyl	Methyl Methyl	Isopropyl H	H Isopropyl	H H
	Isobutyl	Isopropyl	Methyl	H	Н	Isopropyl
	Isobutyl	Isopropyl	Н	Isopropyl	Methyl	Н
1075.	Isobutyl	Isopropyl	H	Isopropyl	Isopropyl	H
	Isobutyl	Isopropyl	H	Methyl	Isopropyl	H
	Isobutyl	Isopropyl	H	Isopropyl	Ethyl	H
	Isobutyl Isobutyl	Isopropyl Isopropyl	H Isobutyl	Ethyl H	Isopropyl H	H H
	Isobutyl	Isopropyl	H	Isobutyl	H	H
	Isobutyl	Isopropyl	H	Н	Isobutyl	H
1082.	Isobutyl	Isopropyl	H	H	Н	Isobutyl
	Isobutyl	Isopropyl	Methyl	Isobutyl	H	H
	Isobutyl	Isopropyl	Methyl	H H	Isobutyl H	H Lan hustral
	Isobutyl Isobutyl	Isopropyl Isopropyl	Methyl H	Isobutyl	Methyl	Isobutyl H
	Isobutyl	Isopropyl	Н	Isobutyl	Isobutyl	H
	Isobutyl	Isopropyl	H	Methyl	Isobutyl	H
	Isobutyl	Isopropyl	H	Isobutyl	Ethyl	H
	Isobutyl	Isopropyl	H	Ethyl	Isobutyl	H H
	Isobutyl Isobutyl	Isopropyl Isopropyl	H H	Isobutyl Isopropyl	Isopropyl Isobutyl	Н
	Isobutyl	Isobutyl	Н	Н	Н	Н
	Isobutyl	Isobutyl	Methyl	H	H	H
	Isobutyl	Isobutyl	H	Methyl	H	H
	Isobutyl	Isobutyl	H	H	Methyl	H
	Isobutyl Isobutyl	Isobutyl Isobutyl	H Methyl	H Methyl	H H	Methyl H
	Isobutyl	Isobutyl	Methyl	Н	Methyl	H
	Isobutyl	Isobutyl	Methyl	Н	Н	Methyl
1101.	Isobutyl	Isobutyl	Н	Methyl	Methyl	Н
1102.	Isobutyl	Isobutyl	H	Methyl	H	Methyl
	Isobutyl	Isobutyl	H Mathad	H M-th-d	Methyl Methyl	Methyl
	Isobutyl Isobutyl	Isobutyl Isobutyl	Methyl Methyl	Methyl Methyl	H	H Methyl
	Isobutyl	Isobutyl	Methyl	Н	Methyl	Methyl
	Isobutyl	Isobutyl	Н	Methyl	Methyl	Methyl
	Isobutyl	Isobutyl	Methyl	Methyl	Methyl	Methyl
	Isobutyl	Isobutyl	Ethyl	H	H	H
	Isobutyl Isobutyl	Isobutyl Isobutyl	H H	Ethyl H	H Ethyl	H H
	Isobutyl	Isobutyl	Н	H	H	Ethyl
	Isobutyl	Isobutyl	Methyl	Ethyl	H	H
1114.	Isobutyl	Isobutyl	Methyl	Н	Ethyl	H
	Isobutyl	Isobutyl	Methyl	H	H	Ethyl
	Isobutyl	Isobutyl	Н	Ethyl	Methyl	Н
	Isobutyl Isobutyl	Isobutyl Isobutyl	H H	Ethyl Methyl	Ethyl Ethyl	H H
	Isobutyl	Isobutyl	Isopropyl	Н	Н	H
				Isopropyl	H	H
1119.	Isobutyl	Isobutyl	H			
1119. 1120. 1121.	Isobutyl Isobutyl	Isobutyl	H	Н	Isopropyl	H
1119. 1120. 1121. 1122.	Isobutyl Isobutyl Isobutyl	Isobutyl Isobutyl	H H	H H	Isopropyl H	H Isopropyl
1119. 1120. 1121. 1122. 1123.	Isobutyl Isobutyl Isobutyl Isobutyl	Isobutyl Isobutyl Isobutyl	H H Methyl	H H Isopropyl	Isopropyl H H	H Isopropyl H
1119. 1120. 1121. 1122. 1123. 1124.	Isobutyl Isobutyl Isobutyl Isobutyl Isobutyl	Isobutyl Isobutyl Isobutyl Isobutyl	H H Methyl Methyl	H H Isopropyl H	Isopropyl H H Isopropyl	H Isopropyl H H
1119. 1120. 1121. 1122. 1123. 1124. 1125.	Isobutyl Isobutyl Isobutyl Isobutyl	Isobutyl Isobutyl Isobutyl	H H Methyl	H H Isopropyl	Isopropyl H H	H Isopropyl H

TABLE 1-continued

Compound #	# R ₁	R_2	R_3	R_4	R_5	R_6
1128.	Isobutyl	Isobutyl	Н	Methyl	Isopropyl	Н
1129.	Isobutyl	Isobutyl	H	Isopropyl	Ethyl	H
1130.	Isobutyl	Isobutyl	H	Ethyl	Isopropyl	H
1131.	Isobutyl	Isobutyl	Isobutyl	Н	Н	Н
1132.	Isobutyl	Isobutyl	Н	Isobutyl	H	Н
1133.	Isobutyl	Isobutyl	H	Н	Isobutyl	H
1134.	Isobutyl	Isobutyl	H	H	Н	Isobutyl
1135.	Isobutyl	Isobutyl	Methyl	Isobutyl	H	Н
1136.	Isobutyl	Isobutyl	Methyl	Н	Isobutyl	H
1137.	Isobutyl	Isobutyl	Methyl	H	Н	Isobutyl
1138.	Isobutyl	Isobutyl	Н	Isobutyl	Methyl	Н
1139.	Isobutyl	Isobutyl	H	Isobutyl	Isobutyl	H
1140.	Isobutyl	Isobutyl	H	Methyl	Isobutyl	H
1141.	Isobutyl	Isobutyl	H	Isobutyl	Ethyl	Н
1142.	Isobutyl	Isobutyl	H	Ethyl	Isobutyl	H
1143.	Isobutyl	Isobutyl	H	Isobutyl	Isopropyl	H
1144.	Isobutyl	Isobutyl	H	Isopropyl	Isobutyl	H
1145.	CD ₃ CH ₂	Н	H	Н	Н	H
1146.	$(CD_3)_2CH$	Н	Н	H	Н	H

In one embodiment, a first device is provided. The first device comprises a first organic light emitting device, further comprising an anode, a cathode, and an organic layer, disposed between the anode and the cathode, comprising a compound having the formula:

Formula I

35

40

Formula I. R_1 and R_2 are optionally linked and the sum of the number of carbon atoms in R1 and R2 is at least 2. R_3 , R_4 , R_5 , R_6 are optionally linked, and R_a and R_b represent mono-, di, tri- or tetra-substitution. X is selected from the group consisting of BR, NR, PR, O, S, Se, C=O, S=O, SO₂, CRR', SiRR', and GeRR', and R_a , R_b , R_1 , R_2 , R_3 , R_4 , R_5 , and R_6 are independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, 55 carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof; and wherein n is 1 or 2.

In one embodiment, the first device is a consumer product.

In another embodiment, the first device is an organic lightemitting device. In another embodiment, the first device comprises a lighting panel. In one embodiment, the organic layer is an emissive layer and the compound is an emissive dopant.

In another embodiment, the organic layer is an emissive layer and the compound is a non-emissive dopant.

In one embodiment, the organic layer further comprises a host. In another embodiment, the host comprises a triphenylene containing benzo-fused thiophene or benzo-fused furan, wherein any substituent in the host is an unfused substituent independently selected from the group consisting of C_nH_{2n+1} , OC_nH_{2n+1} , OAr_1 , $N(C_nH_{2n+1})_2$, $N(Ar_1)(Ar_2)$, $CH=CH-C_nH_{2n+1}$, $C=CC_nH_{2n+1}$, Ar_1 , Ar_1-Ar_2 , $C_nH_{2n}-Ar_1$, or no substitution, wherein Ar_1 and Ar_2 are independently selected from the group consisting of benzene, biphenyl, naphthalene, triphenylene, carbazole, and heteroaromatic analogs thereof, and wherein n is from 1 to 10.

In one embodiment, the host has the formula

In another embodiment, the host is selected from the group consisting of:

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-continued

and combinations thereof.

In one embodiment, the host is a metal complex.

Device Examples

All example devices were fabricated by high vacuum ($<10^{-7}$ Torr) thermal evaporation (VTE). The anode electrode is 1200 Å of indium tin oxide (ITO). The cathode consisted of 10 Å of LiF followed by 1,000 Å of Al. All devices are encapsulated with a glass lid sealed with an epoxy resin in a nitrogen glove box (<1 ppm of $\rm H_2O$ and $\rm O_2$) immediately after fabrication, and a moisture getter was incorporated inside the package.

The organic stack of the device examples consisted of sequentially, from the ITO surface, 100 Å of Compound C as the hole injection layer (HIL), 300 Å of 4,4'-bis[N-(1-naph-thyl)-N-phenylamino]biphenyl (alpha-NPD) as the hole transporting layer (HTL), 300 Å of the invention compound doped in Compound D as host with 5-15 weight percent of a compound of Formula I as the emissive layer (EML), 50 Å of Compound D as blocking layer (BL), and 400 Å of Alq (tris-8-hydroxyquinoline aluminum) as the ETL. Comparative Examples with Compound A and Compound B were fabricated similarly to the Device Examples except that Compound A and Compound B were used as the emitter in the EML.

The device results and data are summarized in Tables 1 from those devices. As used herein, NPD, Alq, Compound A, Compound B, Compound C, and Compound D have the following structures:

Compound A

Compound D

15

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TABLE 2

		V	TE Phosphoresce	nt OLEDs		
Example	HIL	HTL	EML (30	0 Å, doping %)	BL	ETL 1
Comparative Example 1	Compound C	NPD 300 Å	Compound D	Compound A 10%	Compound D 50 Å	Alq 400 Å
Comparative Example 2	Compound C 100 Å	NPD 300 Å	Compound D	Compound B 10%	Compound D 50 Å	Alq 400 Å
Example 1	Compound C	NPD 300 Å	Compound D	Compound 53	Compound D 50 Å	Alq 400 Å
Example 2	Compound C 100 Å	NPD 300 Å	Compound D	Compound 157 10%	Compound D 50 Å	Alq 400 Å
Example 3	Compound C 100 Å	NPD 300 Å	Compound D	Compound 158 12%	Compound D 50 Å	Alq 400 Å
Example 4	Compound C 100 Å	NPD 300 Å	Compound D	Compound 159 10%	Compound D 50 Å	Alq 400 Å
Example 5	Compound C 100 Å	NPD 300 Å	Compound D	Compound 165 12%	Compound D 50 Å	Alq 400 Å
Example 6	Compound C 100 Å	NPD 300 Å	Compound D	Compound 174 8%	Compound D 50 Å	Alq 400 Å
Example 7	Compound C 100 Å	NPD 300 Å	Compound D	Compound 175 8%	Compound D 50 Å	Alq 400 Å
Example 8	Compound C 100 Å	NPD 300 Å	Compound D	Compound 184 7%	Compound D 50 Å	Alq 400 Å
Example 9	Compound C 100 Å	NPD 300 Å	Compound D	Compound 185 10%	Compound D 50 Å	Alq 400 Å
Example 10	Compound C 100 Å	NPD 300 Å	Compound D	Compound 314 12%	Compound D 50 Å	Alq 400 Å
Example 11	Compound C 100 Å	NPD 300 Å	Compound D	Compound 321 12%	Compound D 50 Å	Alq 400 Å
Example 12	Compound C 100 Å	NPD 300 Å	Compound D	Compound 625 12%	Compound D 50 Å	Alq 400 Å
Example 13	Compound C 100 Å	NPD 300 Å	Compound D	Compound 626 10%	Compound D 50 Å	Alq 400 Å
Example 14	Compound C 100 Å	NPD 300 Å	Compound D	Compound 627 8%	Compound D 50 Å	Alq 400 Å
Example 15	Compound C 100 Å	NPD 300 Å	Compound D	Compound 628 8%	Compound D 50 Å	Alq 400 Å
Example 16	Compound C 100 Å	NPD 300 Å	Compound D	Compound 633 10%	Compound D 50 Å	Alq 400 Å
Example 17	Compound C 100 Å	NPD 300 Å	Compound D	Compound 643 8%	Compound D 50 Å	Alq 400 Å
Example 18	Compound C 100 Å	NPD 300 Å	Compound D	Compound 652 8%	Compound D 50 Å	Alq 400 Å
Example 19	Compound C 100 Å	NPD 300 Å	Compound D	Compound 653 8%	Compound D 50 Å	Alq 400 Å
Example 20	Compound C 100 Å	NPD 300 Å	Compound D	Compound 1145 10%	Compound D 50 Å	Alq 400 Å

TABLE 2-continued

VTE Phosphorescent OLEDs								
Example	HIL	HTL	EML (300	Å, doping %)	BL	ETL 1		
Example 21	Compound C 100 Å	NPD 300 Å	Compound D	Compound 1146 10%	Compound D 50 Å	Alq 400 Å		

TABLE 3

				IADL.	<i>5</i>				
			7	TE Devic	e Data				
	x	у	λ _{max} (nm)	FWHM (nm)	Voltage (V)	LE (Cd/A)	EQE (%)	PE (lm/W)	LT80% (h)
Comparative Example 1	0.367	0.607	532	66	6.5	43.2	11.5	21	250
Compound A Comparative	0.336	0.623	524	66	5.2	58.2	15.7	35	170
Example 2 Compound B	0.550	0.023	327	00	3.2	36.2	13.7	33	170
Example 1 Compound 53	0.345	0.619	526	64	5.1	69.2	18.7	42.7	20
Example 2 Compound 157	0.336	0.618	518	70	5.8	62.2	17.3	33.6	166
Example 3 Compound 158	0.318	0.632	518	60	4.7	73.4	20.2	49.1	55
Example 4 Compound 159	0.339	0.616	520	66	5.4	58.3	16.2	33.9	82
Example 5 Compound 165	0.333	0.626	522	62	4.6	56.1	15.2	38.3	54
Example 6 Compound 174	0.327	0.627	520	64	4.9	61.5	16.9	39.3	62
Example 7 Compound 175	0.314	0.635	518	60	5.3	71.2	19.5	42.2	77
Example 8 Compound 184	0.331	0.623	518	64	5.7	52.8	14.6	28.8	66
Example 9 Compound 185	0.331	0.623	518	64	5.4	56.7	15.7	32.9	53
Example 10 Compound 314	0.308	0.636	516	60	5.0	61.4	16.9	38.9	44
Example 11 Compound 321	0.326	0.630	520	60	5.1	61.4	16.6	37.7	73
Example 12 Compound 625	0.338	0.622	524	66	5.1	60.1	16.3	37.2	124
Example 13 Compound 626	0.336	0.624	522	64	5.5	67.4	18.2	38.2	71
Example 14 Compound 627	0.345	0.619	526	64	5.2	65.2	17.7	39.2	121
Example 15 Compound 628	0.351	0.615	526	64	5.6	68.6	18.6	38.7	124
Example 16 Compound 633	0.366	0.608	528	66	5.0	66.3	17.8	41.8	56
Example 17 Compound 643	0.339	0.625	526	60	5.2	71.5	19.1	43.3	108
Example 18 Compound 652	0.349	0.616	526	66	5.7	53.4	14.5	29.3	104
Example 19 Compound 653	0.337	0.626	524	62	5.1	65.6	17.6	40.8	84
Example 20 Compound 1145	0.343	0.618	524	68	5.6	61.3	16.7	34.4	59
Example 21 Compound 1146	0.343	0.618	524	68	5.6	63	17.2	35.5	157

Table 3 is a summary of the device data. The luminous efficiency (LE), external quantum efficiency (EQE) and power efficiency (PE) were measured at 1000 nits, while the lifetime (LT $_{80\%}$) was defined as the time required for the device to decay to 80% of its initial luminance under a constant current density of 40 mA/cm 2 .

The advantage of alkyl substitution on the 4- and 5-positions of the DBX-pyridine ring is clear from Table 3. Compared to Comparative Example 1, with no substitution at the 65 4- or 5-positions of the DBX-pyridine ring, the compounds of Formula I are more saturated (lower CIE x coordinate and

shorter λ_{max}) and the broadness as measured by the FWHM is comparable. In all the inventive compounds, the voltage is lower and the LE, PE and EQE values are all higher. In the case of Compounds 53, 158, 175, 633 and 643, the PE is at least twice as high as Comparative Example 1.

Compared to Comparative Example 2 (Compound B), with only one-carbon substitution (methyl) at the 4-position of the DBX-pyridine ring, Compounds 53, 158, 174, 175, 184, 185, and 314 have more saturated color based CIE x coordinate and Compounds 157, 158, 159, 165, 174, 175, 184, 185, 314, 321 and 626 all have shorter λ_{max} values. Most of the com-

pounds of Formula I have narrower emission profiles (as measured by FWHM) than Comparative Example 2. Compounds 53, 158, 165, 314, 321, 625, 633 and 653 all have lower driving voltages than Comparative Example 2. Most of the compounds of Formula I have greater LE, PE and EQE 5 values than Comparative Example 2.

Combination with Other Materials

The materials described herein as useful for a particular layer in an organic light emitting device may be used in combination with a wide variety of other materials present in 10 the device. For example, emissive dopants disclosed herein may be used in conjunction with a wide variety of hosts, transport layers, blocking layers, injection layers, electrodes and other layers that may be present. The materials described or referred to below are non-limiting examples of materials 15 that may be useful in combination with the compounds disclosed herein, and one of skill in the art can readily consult the literature to identify other materials that may be useful in combination.

HIL/HTL:

A hole injecting/transporting material to be used in the present invention is not particularly limited, and any compound may be used as long as the compound is typically used as a hole injecting/transporting material. Examples of the material include, but not limit to: a phthalocyanine or porphryin derivative; an aromatic amine derivative; an indolocarbazole derivative; a polymer containing fluorohydrocarbon; a polymer with conductivity dopants; a conducting polymer, such as PEDOT/PSS; a self-assembly monomer derived from compounds such as phosphonic acid and sliane derivatives; a metal oxide derivative, such as MoO_x; a p-type semiconducting organic compound, such as 1,4,5,8,9,12-Hexaazatriphenylenehexacarbonitrile; a metal complex, and a cross-linkable compounds.

Examples of aromatic amine derivatives used in HIL or 35 HTL include, but not limit to the following general structures:

Each of Ar¹ to Ar⁹ is selected from the group consisting aromatic hydrocarbon cyclic compounds such as benzene, biphenyl, triphenyl, triphenylene, naphthalene, anthracene, phenalene, phenanthrene, fluorene, pyrene, chrysene, perylene, azulene; group consisting aromatic heterocyclic 65 compounds such as dibenzothiophene, dibenzofuran, dibenzoselenophene, furan, thiophene, benzofuran, ben-

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zothiophene, benzoselenophene, carbazole, indolocarbazole, pyridylindole, pyrrolodipyridine, pyrazole, imidazole, triazole, oxazole, thiazole, oxadiazole, oxatriazole, dioxazole, thiadiazole, pyridine, pyridazine, pyrimidine, pyrazine, triazine, oxazine, oxathiazine, oxadiazine, indole, benzimidazole, indazole, indoxazine, benzoxazole, benzisoxazole, benzothiazole, quinoline, isoquinoline, cinnoline, quinazoline, quinoxaline, naphthyridine, phthalazine, pteridine, xanthene, acridine, phenazine, phenothiazine, phenoxazine, benzofuropyridine, furodipyridine, benzothienopyridine, thienodipyridine, benzoselenophenopyridine, and selenophenodipyridine; and group consisting 2 to 10 cyclic structural units which are groups of the same type or different types selected from the aromatic hydrocarbon cyclic group and the aromatic heterocyclic group and are bonded to each other directly or via at least one of oxygen atom, nitrogen atom, sulfur atom, silicon atom, phosphorus atom, boron atom, chain structural unit and the aliphatic cyclic group. Wherein each Ar is further substituted by a substituent selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof.

In one aspect, Ar^1 to Ar^9 is independently selected from the group consisting of:

k is an integer from 1 to 20; X^1 to X^8 is C (including CH) or N; Ar^1 has the same group defined above.

Examples of metal complexes used in HIL or HTL include, but not limit to the following general formula:

$$\begin{bmatrix} Y^1 \\ Y^2 \end{bmatrix}$$
 M—Ln

M is a metal, having an atomic weight greater than 40; $(Y^1 - Y^2)$ is a bidentate ligand, Y^1 and Y^2 are independently selected from C, N, O, P, and S; L is an ancillary ligand; m is an integer value from 1 to the maximum number of ligands that may be attached to the metal; and m+n is the maximum number of ligands that may be attached to the metal.

In one aspect, $(Y^1 - Y^2)$ is a 2-phenylpyridine derivative. In another aspect, $(Y^1 - Y^2)$ is a carbene ligand.

In another aspect, M is selected from Ir, Pt, Os, and Zn.

In a further aspect, the metal complex has a smallest oxidation potential in solution vs. Fc $^+$ /Fc couple less than about 0.6 V.

Host:

The light emitting layer of the organic EL device of the present invention preferably contains at least a metal complex 25 as light emitting material, and may contain a host material using the metal complex as a dopant material. Examples of the host material are not particularly limited, and any metal complexes or organic compounds may be used as long as the triplet energy of the host is larger than that of the dopant.

Examples of metal complexes used as host are preferred to have the following general formula:

$$\begin{bmatrix} Y^3 \\ Y^4 \end{bmatrix}$$
 M—Ln

M is a metal; $(Y^3 - Y^4)$ is a bidentate ligand, Y^3 and Y^4 are independently selected from C, N, O, P, and S; L is an ancillary ligand; m is an integer value from 1 to the maximum number of ligands that may be attached to the metal; and m+n is the maximum number of ligands that may be attached to the metal.

In one aspect, the metal complexes are:

$$\begin{bmatrix} O \\ N \end{bmatrix}_{m} Al - L_{3-m} \begin{bmatrix} O \\ N \end{bmatrix}_{m} Zn - L_{2-m}$$
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(O-N) is a bidentate ligand, having metal coordinated to $\,$ 55 atoms O and N.

In another aspect, M is selected from Ir and Pt.

In a further aspect, (Y³—Y⁴) is a carbene ligand.

Examples of organic compounds used as host are selected from the group consisting aromatic hydrocarbon cyclic compounds such as benzene, biphenyl, triphenyl, triphenylene, naphthalene, anthracene, phenalene, phenanthrene, fluorene, pyrene, chrysene, perylene, azulene; group consisting aromatic heterocyclic compounds such as dibenzothiophene, dibenzofuran, dibenzoselenophene, furan, thiophene, benzofuran, benzothiophene, benzoselenophene, carbazole, indolocarbazole, pyridylindole, pyrrolodipyridine, pyrazole,

imidazole, triazole, oxazole, thiazole, oxadiazole, oxatriazole, dioxazole, thiadiazole, pyridine, pyridazine, pyrimidine, pyrazine, triazine, oxazine, oxathiazine, oxadiazine, indole, benzimidazole, indazole, indoxazine, benzoxazole, benzisoxazole, benzothiazole, quinoline, isoquinoline, cinnoline, quinazoline, quinoxaline, naphthyridine, phthalazine, pteridine, xanthene, acridine, phenazine, phenothiazine, phebenzofuropyridine, furodipyridine, zothienopyridine, thienodipyridine, benzoselenophenopyridine, and selenophenodipyridine; and group consisting 2 to 10 cyclic structural units which are groups of the same type or different types selected from the aromatic hydrocarbon cyclic group and the aromatic heterocyclic group and are bonded to each other directly or via at least one of oxygen atom, nitrogen atome, sulfur atom, silicon atom, phosphorus atom, boron atom, chain structural unit and the aliphatic cyclic group. Wherein each group is further substituted by a substituent selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfanyl, sulfonyl, phosphino, and combinations thereof.

In one aspect, host compound contains at least one of the following groups in the molecule:

-continued
$$X^{1} \longrightarrow X^{8} \longrightarrow X^{8} \longrightarrow X^{7} \longrightarrow X^{8} \longrightarrow X^{8} \longrightarrow X^{8} \longrightarrow X^{7} \longrightarrow X^{8} \longrightarrow X$$

R¹ to R² is independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof, when it is aryl or heteroaryl, it has the similar definition as Ar's mentioned above.

k is an integer from 0 to 20.

 X^1 to X^8 is selected from C (including CH) or N. HBL:

A hole blocking layer (HBL) may be used to reduce the number of holes and/or excitons that leave the emissive layer. The presence of such a blocking layer in a device may result in substantially higher efficiencies as compared to a similar device lacking a blocking layer. Also, a blocking layer may be used to confine emission to a desired region of an OLED.

In one aspect, compound used in HBL contains the same molecule used as host described above.

In another aspect, compound used in HBL contains at least one of the following groups in the molecule:

-continued
$$\begin{bmatrix} O \\ N \end{bmatrix}_m$$
 Al- L_{3-m}

k is an integer from 0 to 20; L is an ancillary ligand, m is an $_{10}\,$ integer from 1 to 3.

ETL:

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Electron transport layer (ETL) may include a material capable of transporting electrons. Electron transport layer may be intrinsic (undoped), or doped. Doping may be used to enhance conductivity. Examples of the ETL material are not particularly limited, and any metal complexes or organic compounds may be used as long as they are typically used to transport electrons.

In one aspect, compound used in ETL contains at least one 20 of the following groups in the molecule:

R¹ is selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof, it has the similar definition as Ar's mentioned above.

 Ar^1 to Ar^a has the similar definition as Ar's mentioned above.

k is an integer from 0 to 20.

polymer

 X^1 to X^8 is selected from C (including CH) or N.

In another aspect, the metal complexes used in ETL contains, but not limit to the following general formula:

$$\begin{bmatrix} O \\ N \end{bmatrix}_{m} Al - L_{3-m} \begin{bmatrix} O \\ N \end{bmatrix}_{m} Be - L_{2-m} \\ \begin{bmatrix} O \\ N \end{bmatrix}_{m} Zn - L_{2-m} \begin{bmatrix} N \\ N \end{bmatrix}_{m} Zn - L_{2-m} \end{bmatrix}$$

(O-N) or (N-N) is a bidentate ligand, having metal coordinated to atoms O,N or N,N;L is an ancillary ligand; m is an integer value from 1 to the maximum number of ligands that may be attached to the metal.

In any above-mentioned compounds used in each layer of the OLED device, the hydrogen atoms can be partially or fully deuterated

In addition to and/or in combination with the materials disclosed herein, many hole injection materials, hole transporting materials, host materials, dopant materials, exiton/hole blocking layer materials, electron transporting and electron injecting materials may be used in an OLED. Nonlimiting examples of the materials that may be used in an OLED in combination with materials disclosed herein are listed in Table 3 below. Table 3 lists non-limiting classes of materials, non-limiting examples of compounds for each class, and references that disclose the materials.

TABLE 3

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
	Hole injection materials	
Phthalocyanine and porphryin compounds	N N N N N N N N N N N N N N N N N N N	Appl. Phys. Lett. 69, 2160 (1996)
Starburst triarylamines		J. Lumin. 72-74, 985 (1997)
CF _x Fluorohydrocarbon	$-$ [CH_xF_y] $_n$	Appl. Phys. Lett. 78, 673 (2001)

TABLE 3-continued

TABLE 3-continued		
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Conducting polymers (e.g., PEDOT:PSS, polyaniline, polypthiophene	$\begin{array}{c} \\ \\ \\ \\ \\ \\ \\ \\ \\ \end{array}$	Synth. Met. 87, 171 (1997) WO2007002683
Phosphonic acid and silane SAMs	N — $SICl_3$	US20030162053
Triarylamine or polythiophene polymers with conductivity dopants	N-N-N-N-C	EP1725079A1
	Br N - N	
	$F \longrightarrow F \longrightarrow$	

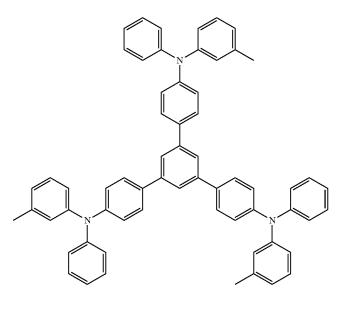
TABLE 3-continued		
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Arylamines complexed with metal oxides such as molybdenum and tungsten oxides	$+ M_{0}O_{x}$	SID Symposium Digest, 37, 923 (2006) WO2009018009
p-type semiconducting organic complexes	NC CN N N CN NC CN	US20020158242
Metal organometallic complexes	$\begin{bmatrix} \\ \\ \\ \end{bmatrix}_3$	US20060240279
Cross-linkable compounds		US20080220265
	Hole transporting materials	
Triarylamines (e.g., TPD, α-NPD)		Appl. Phys. Lett. 51, 913 (1987)

MATERIAL EXAMPLES OF MATERIAL PUBLICATIONS

EP650955

U.S. Pat. No. 5,061,569

J. Mater. Chem. 3, 319 (1993)



MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		Appl. Phys. Lett. 90, 183503 (2007)
		Appl. Phys. Lett. 90, 183503 (2007)
Triaylamine on spirofluorene core	Ph_2N NPh_2 NPh_2	Synth. Met. 91, 209 (1997)
Arylamine carbazole compounds		Adv. Mater. 6, 677 (1994), US20080124572

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Triarylamine with (di)benzothiophene/ (di)benzofuran	$\begin{array}{c c} & & & \\ & & & \\ & & & \\ \end{array}$	US20070278938, US20080106190
Indolocarbazoles		Synth. Met. 111, 421 (2000)
Isoindole compounds		Chem. Mater. 15, 3148 (2003)
Metal carbene complexes	Ir	US20080018221
	Phosphorescent OLED host materials Red hosts	

	TABLE 3-continued	
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Arylcarbazoles		Appl. Phys. Lett. 78, 1622 (2001)
Metal 8- hydroxyquinolates (e.g., Alq ₃ , BAlq)	$\begin{bmatrix} \\ \\ \\ \\ \end{bmatrix}_{O} \end{bmatrix}_{3}$ Al	Nature 395, 151 (1998)
	$\begin{bmatrix} \\ \\ \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \begin{bmatrix} \\ \end{bmatrix} \end{bmatrix} \begin{bmatrix} \end{bmatrix} \begin{bmatrix}$	US20060202194
	$\begin{bmatrix} \\ \\ \\ \\ \\ \end{bmatrix}$ $AI - O$	WO2005014551
	$\begin{bmatrix} \\ \\ \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \\ \\ \end{bmatrix} \begin{bmatrix} \\ \\ \\ \\$	WO2006072002
Metal phenoxybenzothiazole compounds	\sum_{N} \sum_{N} \sum_{n} \sum_{n}	Appl. Phys. Lett. 90, 123509 (2007)
Conjugated oligomers and polymers (e.g., polyfluorene)	C_8H_{17} C_8H_{17}	Org. Electron. 1, 15 (2000)

TABLE 3-continued

	TABLE 3-continued	
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Aromatic fused rings		WO2009066779, WO2009066778, WO2009063833, US20090045731, US20090045730, WO2009008311, US20090008605, US20090009065
Zinc complexes	H N Zn N H Green hosts	WO2009062578
Arylcarbazoles		Appl. Phys. Lett. 78, 1622 (2001)
	N N N N N N N N N N N N N N N N N N N	US20030175553
		WO2001039234
Aryltriphenylene compounds		US20060280965

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		US20060280965
		WO2009021126
Donor acceptor type molecules		WO2008056746
Aza-carbazole/DBT/ DBF		JP2008074939
Polymers (e.g., PVK)	N N	Appl. Phys. Lett. 77, 2280 (2000)

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Spirofluorene compounds		WO2004093207
Metal phenoxybenzooxazole compounds	AI—O	WO2005089025
	Al-O-N	WO2006132173
	O N Zn	JP200511610
Spirofluorene- carbazole compounds		JP2007254297

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		JP2007254297
Indolocabazoles		WO2007063796
		WO2007063754
5-member ring electron deficient heterocycles (e.g., triazole, oxadiazole)	N-N N	J. Appl. Phys. 90, 5048 (2001)
		WO2004107822

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Tetraphenylene complexes		US20050112407
Metal phenoxypyridine compounds	$\begin{bmatrix} \\ \\ \\ \\ \end{bmatrix}^{N} = Zn$	WO2005030900
Metal coordination complexes (e.g., Zn, Al with N N ligands)	N N N Zn	US20040137268, US20040137267
	Blue hosts	
Arylcarbazoles		Appl. Phys. Lett, 82, 2422 (2003)
	N. N.	US20070190359

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Dibenzothiophene/ Dibenzofuran- carbazole compounds		WO2006114966, US20090167162
	N S S S S S S S S S S S S S S S S S S S	US20090167162
		WO2009086028
	S S S S S S S S S S S S S S S S S S S	US20090030202, US20090017330
Silicon aryl compounds		US20050238919
	S _{Si} S _{Si}	WO2009003898

	TABLE 5-continued	
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Silicon/Germanium aryl compounds	S _{Si}	EP2034538A
Aryl benzoyl ester		WO2006100298
High triplet metal organometallic complex	Ir	U.S. Pat. No. 7,154,114
	Phosphorescent dopants Red dopants	
Heavy metal porphyrins (e.g., PtOEP)	Et Et Et Et N N N N Et Et Et Et Et	Nature 395, 151 (1998)
Iridium(III) organometallic complexes	Ir o	Appl. Phys. Lett. 78, 1622 (2001)

TABLE 3-continued

	IABLE 3-continued	
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
	Ir o	US2006835469
		US2006835469
		US20060202194
	Ir O	US20060202194
	Ir 3	US20070087321

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
	Ir	US20070087321
		Adv. Mater. 19, 739 (2007)
	Ir(acac)	WO2009100991
		WO2008101842
Platinum(II) organometallic complexes	N O Pt O	WO2003040257

TABLE 3-continued		
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Osminum(III) complexes	F_3C N N $Os(PPhMe_2)_2$	Chem. Mater. 17, 3532 (2005)
Ruthenium(II) complexes	$\begin{bmatrix} & & & & \\ & & & & \\ & & & & \\ & & & & $	Adv. Mater. 17, 1059 (2005)
Rhenium (I), (II) and (III) complexes	Re—(CO) ₄ Green dopants	US20050244673
Iridium(III) organometallic complexes	and its derivatives	Inorg. Chem. 40, 1704 (2001)
		U\$20020034656

US20020034656

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		U.S. Pat. No. 7,332,232
		US20090108737
	Ir	US20090039776
		U.S. Pat. No. 6,921,915

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		U.S. Pat. No. 6,687,266

TABLE 3-continued		
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
	Ir N	Angew. Chem. Int. Ed. 2006, 45, 7800
	Ir	WO2009050290
	S N Ir	US20090165846
		US20080015355
Monomer for polymeric metal organometallic compounds		U.S. Pat. No. 7,250,226, U.S. Pat. No. 7,396,598

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Pt(II) organometallic complexes, including polydentated ligands	Pt Cl	Appl. Phys. Lett. 86, 153505 (2005)
	Pt O	Appl. Phys. Lett. 86, 153505 (2005)
	Pt F_5 F_5	Chem. Lett. 34, 592 (2005)
	N O Pt	WO2002015645
	Ph Pt Ph	US20060263635

MATERIAL	TABLE 3-continued EXAMPLES OF MATERIAL	PUBLICATIONS
Cu complexes	P Cu N N	WO2009000673
Gold complexes	Au N	Chem. Commun. 2906 (2005)
Rhenium(III) complexes	F ₃ C OC Re	Inorg. Chem. 42, 1248 (2003)
Deuterated organometallic complexes	D D D Ir	US20030138657

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Organometallic complexes with two or more metal centers		US20030152802
	F F S F S S S S S S S S S S S S S S S S	U.S. Pat. No. 7,090,928
Iridium(III) organometallic complexes	Blue dopants F Ir O O	WO2002002714
		WO2006009024
	Ir	US20060251923

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
	Ir Ir	U.S. Pat. No. 7,393,599, WO2006056418, US20050260441, WO2005019373
	Ir 3	U.S. Pat. No. 7,534,505
	Ir^+	U.S. Pat. No. 7,445,855
	Ir	US20070190359, US20080297033
	Ir 3	U.S. Pat. No. 7,338,722
	N N N 3	US20020134984

TABLE 3-continued

	17 IDEE 5 continued	
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
	N N N N N N N N N N N N N N N N N N N	Angew. Chem. Int. Ed. 47, 1 (2008)
	N Ir	Chem. Mater. 18, 5119 (2006)
	F Ir	Inorg. Chem. 46, 4308 (2007)
	r N N Ir	WO2005123873
	Ir	WO2005123873
	$\begin{bmatrix} \\ \\ \\ \\ \\ \\ \\ \\ \\ \end{bmatrix}_3$ Ir	WO2007004380

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		WO2006082742
Osmium(II) complexes	Os	U.S. Pat. No. 7,279,704
	$\bigcap_{N} \bigcap_{2} \operatorname{Os}(PPh_{3})$	Organometallics 23, 3745 (2004)
Gold complexes	Ph ₂ P PPh ₂ I Au	Appl. Phys. Lett. 74, 1361 (1999)
Platinum(II) complexes	S N N N N N N N N N N N N N N N N N N N	WO2006098120, WO2006103874
	Exciton/hole blocking layer materials	

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Bathocuprine compounds (e.g., BCP, BPhen)		Appl. Phys. Lett. 75, 4 (1999)
		Appl. Phys. Lett. 79, 449 (2001)
Metal 8- hydroxyquinolates (e.g., BAlq)	$\begin{bmatrix} \\ \\ \\ \\ \\ \end{bmatrix}$ $\begin{bmatrix} \\ \\ $	Appl. Phys. Lett. 81, 162 (2002)
5-member ring electron deficient heterocycles such as triazole, oxadiazole, imidazole, benzoimidazole		Appl. Phys. Lett. 81, 162 (2002)
Triphenylene compounds		US20050025993

TABLE 3-continued

TABLE 3-continued		
MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Fluorinated aromatic compounds	F F F F F F F F F F	Appl. Phys. Lett. 79, 156 (2001)
Phenothiazine-S-oxide	O Si Si Si O Si O Electron transporting materials	WO2008132085
Anthracene- benzoimidazole compounds		WO2003060956

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		US20090179554
Aza triphenylene derivatives		US20090115316
Anthracene- benzothiazole compounds		Appl. Phys. Lett. 89, 063504 (2006)
Metal 8- hydroxyquinolates (e.g., Alq ₃ , Zrq ₄)	$\begin{bmatrix} \\ \\ \\ \\ \end{bmatrix}_{O} \end{bmatrix}_{3} A I$	Appl. Phys. Lett. 51, 913 (1987) U.S. Pat. No. 7,230,107
Metal hydroxybenoquinolates	$\begin{bmatrix} \\ \\ \\ \\ \end{bmatrix}_2$ Be	Chem. Lett. 5, 905 (1993)
Bathocuprine compounds such as BCP, BPhen, etc		Appl. Phys. Lett. 91, 263503 (2007)

TABLE 3-continued

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
		Appl. Phys. Lett. 79, 449 (2001)
5-member ring electron deficient heterocycles (e.g., triazole, oxadiazole, imidazole, benzoimidazole)		Appl. Phys. Lett. 74, 865 (1999)
	N-N N-N	Appl. Phys. Lett. 55, 1489 (1989)
		Jpn. J. Apply. Phys. 32, L917 (1993)
Silole compounds	N N N N N N N N N N N N N N N N N N N	Org. Electron. 4, 113 (2003)
Arylborane compounds	B B B	J. Am. Chem. Soc. 120, 9714 (1998)

MATERIAL	EXAMPLES OF MATERIAL	PUBLICATIONS
Fluorinated aromatic compounds	$F \longrightarrow F \longrightarrow$	J. Am. Chem. Soc. 122, 1832 (2000)
Fullerene (e.g., C60)		US20090101870
Triazine complexes	$F \longrightarrow F \qquad $	US20040036077
Zn (N N) complexes	N N N SO ₂	U.S. Pat. No. 6,528,187

EXPERIMENTAL

Chemical abbreviations used throughout this document are as follows: Cy is cyclohexyl, dba is dibenzylideneacetone, EtOAc is ethyl acetate, DME is dimethoxyethane, dppe is 1,2-bis(diphenylphosphino)ethane, THF is tetrahydrofuran, 65 DCM is dichloromethane, S-Phos is dicyclohexyl(2',6'-dimethoxy-[1,1'-biphenyl]-2-yl)phosphine.

Pd(PPh₃)₄

$$K_2CO_3$$

35

50

55

60

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-continued

Synthesis of 5-chloro-2-(dibenzo[b,d]furan-4-yl)pyridine

Dibenzo[b,d]furan-4-ylboronic acid (9.5 g, 44.8 mmol), 2,5-dichloropyridine (7.0 g, 47.0 mmol), Pd(PPh₃)₄ (2.6 g, 20 2.2 mmol) and potassium carbonate (18.6 g, 134 mmol) were added to dimethoxyethane (75 mL) and water (75 mL). The reaction mixture was degassed with nitrogen before being heated to reflux overnight. EtOAc and water were added, the organic layer separated and the aqueous layer was extracted with 3×50 mL dichloromethane and dried over sodium sulfate. After removing the solvent under reduced pressure, the crude product was chromatographed on silica gel with dichloromethane to yield 11.7 g of crude product. The product was crystallized from hexane to give 9.5 g (76%) of 5-chloro-2-(dibenzo[b,d]furan-4-yl)pyridine as white needles. The product was confirmed by GC/MS.

$$\begin{array}{c} CI \\ N \\ + \\ O \\ \end{array}$$

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-5-(prop-1-en-2-yl)pyridine

5-Chloro-2-(dibenzo[b,d]furan-4-yl)pyridine (9.5 g, 34.0 mmol), dicyclohexyl(2',6'-dimethoxy-[1,1'-biphenyl]-2-yl) 65 phosphine (1.1 g, 2.7 mmol), and potassium phosphate tribasic monohydrate (23.5 g, 102 mmol) were added to toluene

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(200 mL) and water (20 mL) and the reaction mixture was degassed with nitrogen. $Pd_2(dba)_3$ (0.622 g, 0.679 mmol) and 4,4,5,5-tetramethyl-2-(prop-1-en-2-yl)-1,3,2-dioxaborolane (7.7 mL, 40.8 mmol) were added and the reaction mixture was heated to reflux overnight. EtOAc and water were added, the organic layer separated and the aqueous layer was extracted with 3×50 mL dichloromethane and dried over sodium sulfate. After removing the solvent under reduced pressure, 12.7 g of amber oil was obtained. The crude material was chromatographed on silica with 9/1 (v/v) hexane/EtOAc to give 7.5 g (77%) of 2-(dibenzo[b,d]furan-4-yl)-5-(prop-1-en-2-yl)pyridine as a white solid. The product was confirmed by GC/MS and used without further purification.

$$\begin{array}{c} Pd/C, H_2 \\ \hline Pt/C \end{array}$$

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-5-isopropylpyridine

2-(Dibenzo[b,d]furan-4-yl)-5-(prop-1-en-2-yl)pyridine (7.5 g, 26.3 mmol) was added to a hydrogenator bottle containing EtOH (150 mL). The reaction mixture was degassed by bubbling nitrogen for 10 min Pd/C (0.28 g, 2.63 mmol) and Pt/C (0.26 g, 1.3 mmol) were added to the reaction mixture. The reaction mixture was placed on the Parr hydrogenator for 1 h. The reaction mixture was filtered on a tightly packed Celite® bed and washed with dichloromethane to yield 7.5 g (99%) of the desired product. The product was confirmed by GC/MS and NMR.

Dibenzo[b,d]furan-4-ylboronic acid (25 g, 118 mmol), 2,4-dichloropyridine (19.2 g, 130 mmol), Pd(PPh $_3$) $_4$ (4.1 g, 5 3.5 mmol) and potassium carbonate (48.9 g, 354 mmol) were added to dimethoxyethane (200 mL) and water (200 mL). The reaction mixture was degassed with nitrogen before being heated to reflux overnight. EtOAc and water were added, the organic layer separated and the aqueous layer was extracted with 3×50 mL dichloromethane and dried over sodium sulfate. After removing the solvent under reduced pressure, the crude product was chromatographed on silica gel with dichloromethane to yield 33.4 g of crude product. The product was crystallized from hexane to give 27.0 g (82%) of 4-chloro-2-15 (dibenzo[b,d]furan-4-yl)pyridine as white needles. The product was confirmed by GC/MS and NMR.

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-4-(prop-1-en-2-yl)pyridine

4-Chloro-2-(dibenzo[b,d]furan-4-yl)pyridine (24.0 g, 86.0 mmol), dicyclohexyl(2',6'-dimethoxy-[1,1'-biphenyl]-2-yl) phosphine (2.8 g, 6.9 mmol), and potassium phosphate tribasic monohydrate (59.3 g, 257 mmol) were added to toluene (400 mL) and water (40 mL) and the reaction mixture was degassed. Pd₂(dba)₃ (1.6 g, 1.7 mmol) and 4,4,5,5-tetramethyl-2-(prop-1-en-2-yl)-1,3,2-dioxaborolane (19.4 mL, 103 mmol) were added and the reaction mixture was heated to reflux overnight. EtOAc and water were added, the organic 65 layer separated and the aqueous layer was extracted with 3×50 mL dichloromethane and dried over sodium sulfate.

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After removing the solvent under reduced pressure, $33.0\,\mathrm{g}$ of amber oil was obtained. The crude material was chromatographed on silica with 9/1~(v/v) DCM/EtOAc to give $23.5\,\mathrm{g}$ (96%) of 2-(dibenzo[b,d]furan-4-yl)-4-(prop-1-en-2-yl)pyridine as a white solid. The product was confirmed by GC/MS and used without further purification.

$$\begin{array}{c|c} & & & \\ \hline \\ Pt/C & & \\ \hline \end{array}$$

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-4-isopropylpyridine

2-(Dibenzo[b,d]furan-4-yl)-5-(prop-1-en-2-yl)pyridine (8.0 g, 28 mmol) was added to a hydrogenator bottle containing EtOH (150 mL). The reaction mixture was degassed by bubbling N₂ for 10 min. Pd/C (0.60 g, 5.6 mmol) and Pt/C (0.55 g, 2.8 mmol) were added to the reaction mixture. The reaction mixture was placed on the Parr hydrogenator for 1 h. The reaction mixture was filtered on a tightly packed Celite® bed and washed with dichloromethane. The crude product was chromatographed on silica gel with 9/1 (v/v) hexane/35 EtOAc to yield 7.2 g (96%) of 2-(dibenzo[b,d]furan-4-yl)-4-isopropylpyridine. The product was confirmed by GC/MS and NMR.

Synthesis of 5-bromo-2-(dibenzo[b,d]furan-4-yl)-4-methylpyridine

2,5-Dibromo-4-methylpyridine (30 g, 118 mmol), dibenzo [b,d]furan-4-ylboronic acid (25 g, 118 mmol), $Pd(PPh_3)_4$ (1.4 g, 1.18 mmol), and K_2CO_3 (49 g, 354 mmol) were added to a

flask with dimethoxyethane (450 mL) and water (100 mL) and degassed with nitrogen. The reaction mixture was heated to reflux for 15 h before cooling to room temperature. EtOAc and water were added, the organic layer separated and the aqueous layer was extracted with 3×50 mL dichloromethane and dried over sodium sulfate. After removing the solvent under reduced pressure, the crude product was chromatographed on silica gel with dichloromethane and 29.7 g of crude product was obtained. The product was crystallized from hexane to give 28.8 g (72%) of pure product. The product was confirmed by NMR and HPLC (99.3% pure)

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-4,5-dimethylpyridine

5-Bromo-2-(dibenzo[b,d]furan-4-yl)-4-methylpyridine (28.7 g, 85 mmol), dicyclohexyl(2',6'-dimethoxy-[1,1'-bi-phenyl]-2-yl)phosphine (1.394 g, 3.39 mmol) and potassium 55 phosphate monohydrate (58.6 g, 255 mmol) were added to toluene (500 mL) and water (50 mL) and degassed for 20 min. Trimethylboroxine (14.83 mL, 106 mmol) and Pd₂(dba)₃ (0.777 g, 0.849 mmol) were added and the reaction mixture heated to reflux overnight. After cooling, the organic layer 60 was separated and the aqueous layer extracted 3×50 mL with EtOAc, dried over sodium sulfate and evaporated. The crude product was chromatographed on silica gel with 8/2 (v/v) dichloromethane/EtOAc in hexane to give 19.2 g of an offwhite solid, which was recrystallized from heaxane to give 65 16.8 g (83%) of the product as white needles. The product was confirmed by NMR and HPLC (99.97% pure).

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-5-isobutyl-4methylpyridine

 $5\text{-Bromo-}2\text{-}(dibenzo[b,d]furan-4\text{-}yl)\text{-}4\text{-}methylpyridine} \ (13.0\ g,\ 38.3\ mmol),\ isobutylboronic\ acid\ (11.7\ g,\ 115\ mmol),\ dicyclohexyl(2',6'\text{-}dimethoxy-[1,1'\text{-}biphenyl]-2\text{-}yl)\ phosphine}\ (0.63\ g,\ 1.53\ mmol)\ and\ potassium\ phosphate\ monohydrate\ (22.1\ g,\ 96\ mmol)\ were\ mixed\ in\ water\ (10\ mL)\ and\ toluene\ (210\ mL).\ The\ system\ was\ degassed\ for\ 20\ min.\ with\ nitrogen\ and\ Pd_2(dba)_3\ (0.35\ g,\ 0.38\ mmol)\ was\ then\ added\ and\ the\ system\ was\ refluxed\ overnight.\ After\ cooling\ to\ room\ temperature,\ the\ reaction\ mixture\ was\ filtered\ through\ a\ small\ plug\ of\ silica\ gel\ and\ eluted\ with\ dicloromethane.\ The\ filtrated\ was\ concentrated\ and\ then\ crystallized\ from\ hexane\ to\ give\ 2\text{-}(dibenzo[b,d]furan-4\text{-}yl)\text{-}5\text{-}isobutyl-4\text{-}methylpyridine}\ (9.0\ g,\ 74\%).$

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$$\begin{array}{c} Cl \\ \hline \\ N \end{array} + \begin{array}{c} B(OH)_2 \\ \hline \\ K_2CO_3 \end{array} \end{array}$$

Synthesis of 5-chloro-2-phenylpyridine

2,5-Dichloropyridine (30 g, 203 mmol), phenylboronic acid (24.72 g, 203 mmol) and potassium carbonate (84 g, 608 mmol) were added to dimethoxyethane (500 mL) and water 20 (100 mL). The reaction mixture was degassed with nitrogen for 20 min, and Pd(PPh₃)₄ (2.3 g, 2.0 mmol) was added and reaction mixture was allowed to reflux for 18 h. The reaction was cooled to room temperature, the aqueous layer removed and dimethoxyethane was concentrated to dryness by rotary evaporation under vacuum. The residue was dissolved in DCM and passed through a silica gel plug, eluting with DCM. The solvent was removed and the crude product was chromatographed on silica with 40/60 (v/v) DCM/hexane to 50/50 (v/v) DCM/hexane to yield 28 g (73%) of the product as a white solid (HPLC purity: 99.7%).

$$\begin{array}{c|c} Cl & & \\$$

Synthesis of 5-ethyl-2-phenylpyridine

5-Chloro-2-phenylpyridine (16 g, 84 mmol) and Ni(dppe) Cl₂ (0.891 g, 1.687 mmol) were added to 300 mL of THF and the reaction mixture was degassed with nitrogen for 20 min. before being cooled to 0° C. Ethylmagnesium bromide (169 mL, 169 mmol) was added dropwise over a period of 60 min. and the reaction mixture stirred for and additional 3 h at before warming to room temperature overnight. The reaction mixture was recooled to 0° C. and quenched with 250 mL of water, extracted with EtOAc and the organic layer dried over sodium sulfate and filtered. The crude material was chromatographed on silica with 95/5 hexane/EtOAc to give 2.9 g (19%) of 5-ethyl-2-phenylpyridine as a white solid.

Synthesis of 2-phenyl-5-(prop-1-en-2-yl)pyridine

To a 1 L round bottom flask was added 5-chloro-2-phenylpyridine (10.15 g, 53.5 mmol), dicyclohexyl(2',6'-dimethoxy-[1,1'-biphenyl]-2-yl)phosphine (1.8 g, 4.3 mmol), potassium phosphate tribasic monohydrate (37.0 g, 161 mmol) with toluene (200 mL) and water (20 mL). The reaction mixture was degassed with nitrogen for 20 mins. 4,4,5,5-tetramethyl-2-(prop-1-en-2-yl)-1,3,2-dioxaborolane (12.07 mL, 64.2 mmol) and $Pd_2(dba)_3$ (0.980 g, 1.070 mmol) were added and the reaction mixture was refluxed for 18 h. The aqueous layer was removed and the organic layer was concentrated to dryness. The crude product was chromatographed on silica gel with 0-20% EtOAc in hexane to yield 11 g of the desired product (HPLC purity: 95%). The product was confirmed by GC/MS.

Synthesis of 2-phenyl-5-isopropylpyridine

2-Phenyl-5-(prop-1-en-2-yl)pyridine (11 g, 56.3 mmol) was added to a hydrogenator bottle containing EtOH (150 mL). The reaction mixture was degassed by bubbling $\rm N_2$ for 10 min. Pd/C (0.60 g, 5.63 mmol) and Pt/C (0.55 g, 2.82 mmol) were added to the reaction mixture. The reaction mixture was placed on the Parr hydrogenator for 1.5 h. The

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reaction mixture was filtered on a tightly packed Celite® bed and washed with dichloromethane. The solvent was removed on rotoevaporator and GC/MS confirmed complete conversion. The crude product was adsorbed on Celite® for column chromatography. The crude product was chromatographed on silica gel with 10% EtOAc in hexane to yield 6 g (54%) of 2-phenyl-5-isopropylpyridine (HPLC purity: 100%). The product was confirmed by GC/MS.

$$\begin{array}{c|c} Cl & & Cl \\ \hline & & \\ &$$

Synthesis of 4-chloro-2-phenylpyridine

A 1 L round bottom flask was charged with 2,4-dichloropyridine (30 g, 203 mmol), phenylboronic acid (24.7 g, 203 25 mmol), potassium carbonate (84 g, 608 mmol), Pd(PPh₃)₄ (2.3 g, 2.0 mmol), dimethoxyethane (500 mL) and water (150 mL). The mixture was degassed and heated to reflux for 20 h. After cooling, the aqueous layer was extracted with EtOAc; the organic portion was combined and subjected to column chromatography (SiO₂, 5% EtOAc in hexane to 10% EtOAc in hexane) to give 34 g (88%) of 4-chloro-2-phenylpyridine. The product was confirmed by GC/MS and NMR.

Synthesis of 2-phenyl-4-(prop-1-en-2yl)pyridine

4-Chloro-2-phenylpyridine (14 g, 73.8 mmol) and potassium phosphate (51.0 g, 221 mmol) were dissolved in 300 mL 60 of toluene and 30 mL of water. The reaction was purged with nitrogen for 20 minutes and then 4,4,5,5-tetramethyl-2-(prop-1-en-2-yl)-1,3,2-dioxaborolane (16.65 mL, 89 mmol), Pd₂(dba)₃ (1.35 g, 1.48 mmol) and S-Phos (2.42 g, 5.91 mmol) were added. The reaction was brought to reflux for 18 65 h. After cooling, 100 mL of water was added, separated and the aqueous layer extracted twice with 100 mL of ethyl

acetate. The organic layers were passed through a plug of silica gel, eluting with DCM. After evaporation of the solvent, the crude product was subjected to column chromatography (SiO₂, 5% EtOAc in hexane to 10% EtOAc in hexane) to get 13.5 g (90%) of 2-phenyl-4-(prop-1-en-2yl)pyridine.

Synthesis of 2-phenyl-4-isopropylpyridine

2-Phenyl-4-(prop-1-en-2-yl) pyridine (13.5 g, 69.1 mmol) was added to a hydrogenator bottle containing EtOH (150 mL). The reaction mixture was degassed by bubbling with nitrogen for 10 min. Pd/C (0.736 g, 6.9 mmol) and Pt/C (0.674 g, 3.5 mmol) was added to the reaction mixture. The reaction mixture was placed on the Parr hydrogenator for 2 h. The reaction mixture was filtered on a tightly packed Celite® bed and washed with dichloromethane. The solvent was removed on a rotary evaporator and GC/MS confirmed complete conversion. The crude product was adsorbed on Celite® for column chromatography. The crude product was chromatographed on silica gel with 10% EtOAc in hexane to yield 10 g (75%) of 2-phenyl-4-isopropylpyridine (HPLC purity: 99.8%). The product was confirmed by GC/MS.

$$\begin{array}{c|c} & & & \\ & & & \\$$

Synthesis of 5-methyl-2-phenylpyridine

2-Bromo-5-methylpyridine (30 g, 174 mmol), phenylboronic acid (25.5 g, 209 mmol), dicyclohexyl(2',6'-dimethoxy-[1,1'-biphenyl]-2-yl)phosphine (2.86 g, 6.98 mmol) and

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potassium phosphate tribasic monohydrate (120 g, 523 mmol) were added to toluene (600 mL) and water (60 mL). The reaction mixture was degassed with nitrogen for 20 min. Pd₂(dba)₃ (3.19 g, 3.49 mmol) was added and the reaction mixture was refluxed for 18 h. After cooling, the organic layer was separated and the aqueous layer extracted with 3×50 mL dichloromethane, dried over sodium sulfate and evaporated. The crude product was chromatographed on silica gel with 75/25 (v/v) hexane/EtOAc and then distilled on a Kugelrohr apparatus (150° C., 100 mbar) to give 26 g (88%) of 5-methyl-2-phenylpyridine as a white solid. The product was confirmed by NMR and GC/MS. HPLC purity: 99.2%.

$$\begin{array}{c|c} & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & \\ & & & \\ & &$$

Synthesis of 4-methyl-2-phenylpyridine

A 1 L round bottom flask was charged with 2-chloro-4-methylpyridine (25 g, 196 mmol), phenylboronic acid (23.9 g, 196 mmol), potassium carbonate (81 g, 588 mmol), Pd(PPh_3)_4 (2.3 g, 1.9 mmol), dimethoxyethane (500 mL) and water (150 mL). The reaction mixture was degassed with nitrogen and heated to reflux for 22 h. After cooling, the aqueous layer was extracted with EtOAc; the organic portion was combined and subjected to column chromatography (SiO_2, 5% EtOAc in hexane to 10% EtOAc in hexane) to give 28 g (78%) of 4-methyl-2-phenylpyridine. The product was confirmed by NMR and GC/MS.

Synthesis of 4-ethyl-2-phenylpyridine

To 4-methyl-2-phenylpyridine (8 g, 47.3 mmol) in dry THF (150 mL) at -78° C. was added dropwise lithium diisopropylamide (LDA) (30.7 mL, 61.5 mmol). The dark solution was stirred for 3 h at -78° C. and then CH $_{3}$ I was added (4.1 mL, 66.2 mmol) dropwise. The reaction mixture was allowed to slowly warm to room temperature overnight. Ammonium chloride solution and EtOAc were added and the reaction transferred to a reparatory funnel. The layers were separated, washing the aqueous twice with EtOAc and combined organics once with water. After removal of the solvent, the crude product was chromatographed on silica gel with 9/1 (v/v) 65 hexane/EtOAc to give 5.5 g (63.5%) of 4-ethyl-2-phenylpyridine. HPLC purity: 99.0%.

Synthesis of 4-methyl-2-phenylpyridine chloro-bridged dimer

To a 500 mL round-bottom flask was added 4-methyl-2-phenylpyridine (7 g, 41 mmol) and iridium(III) chloride hydrate (4.86 g, 13.79 mmol) with 2-ethoxyethanol (90 mL) and water (30 mL) under a nitrogen atmosphere. The resulting reaction mixture was refluxed at 130° C. for 18 h. The resulting precipitate was filtered and washed with methanol (3-4 times) and hexane (3-4 times). The product obtained was dried to give 7.5 g (90%) of the desired product. The product was used without further purification.

Synthesis of 5-methyl-2-phenylpyridine chloro-bridged dimer

To a 500 mL round bottom flask was added 5-methyl-2-phenylpyridine (12 g, 70.9 mmol) and iridium(III) chloride hydrate (7.1 g, 20.3 mmol) with 2-ethoxyethanol (100 mL) and water (33.3 mL) under a nitrogen atmosphere. The resulting reaction mixture was refluxed at 130° C. for 18 h. The resulting precipitate was filtered and washed with methanol

(3-4 times) and hexane (3-4 times). The product obtained was dried to give 11.0 g (96%) of the desired product. The product was used without further purification.

Synthesis of 2-phenyl-5-isopropylpyridine chloro-bridged dimer

To a 500 mL round-bottom flask was added 5-isopropyl-2-phenylpyridine ($6.0\,\mathrm{g}$, $30.4\,\mathrm{mmol}$) and iridium(III) chloride hydrate ($3.6\,\mathrm{g}$, $10.1\,\mathrm{mmol}$) with 2-ethoxyethanol ($100\,\mathrm{mL}$) and water ($33.3\,\mathrm{mL}$) under a nitrogen atmosphere. The resulting reaction mixture was refluxed at 130° C. for 18 h. The resulting precipitate was filtered and washed with methanol (3-4 times) and hexane (3-4 times). The product obtained was dried to give 7 g (100%) of the desired product. The product was used without further purification.

Synthesis of 2-phenyl-4-isopropylpyridine chloro-bridged dimmer

To a 500 mL round-bottom flask was added 4-isopropyl-2-phenylpyridine ($8.0\,\mathrm{g}$, $40.6\,\mathrm{mmol}$) and iridium(III) chloride hydrate ($7.4\,\mathrm{g}$, $20.3\,\mathrm{mmol}$) with 2-ethoxyethanol ($90\,\mathrm{mL}$) and water ($30\,\mathrm{mL}$) under a nitrogen atmosphere. The resulting reaction mixture was refluxed at 130° C. for $18\,\mathrm{h}$. The resulting precipitate was filtered and washed with methanol (3-4 times) and hexane (3-4 times). The product obtained was dried to give $6.1\,\mathrm{g}$ (95%) of the desired product. The product was used without further purification.

Synthesis of 4-ethyl-2-phenylpyridine chloro-bridged dimmer

To a 500 mL round-bottom flask was added 4-isopropyl-2-phenylpyridine (5.5 g, 30.0 mmol) and iridium(III) chloride hydrate (5.8 g, 16.5 mmol) with 2-ethoxyethanol (90 mL) and water (30 mL) under a nitrogen atmosphere. The resulting reaction mixture was refluxed at 130° C. for 18 h. The resulting precipitate was filtered and washed with methanol (3-4 times) and hexane (3-4 times). The product obtained was dried to give 6.5 g (72%) of the desired product. The product was used without further purification.

Synthesis of 5-ethyl-2-phenylpyridine chloro-bridged dimer

To a 500 mL round bottom flask was added 5-ethyl-2-phenylpyridine (2.9 g, 15.7 mmol) and iridium(III) chloride hydrate (1.8 g, 5.2 mmol) with 2-ethoxyethanol (60 mL) and water (20 mL) under a nitrogen atmosphere. The reaction mixture was refluxed at 130° C. for 18 h. The resulting precipitate was filtered and washed with methanol (3-4 times) and hexane (3-4 times). The product obtained was dried to give 2.45 g (89.3%) of the desired product. The product was used without further purification.

Synthesis of 5-methyl-2-phenylpyridine iridium trifluoromethanesulfonate salt

The iridium dimer (11 g, 9.8 mmol) was suspended in 600 mL of dichloromethane. In a separate flask, silver(I) trifluoromethanesulfonate (5.3 g, 20.5 mmol) was dissolved in 60 MeOH (300 mL) and added slowly to the dichloromethane solution with continuous stirring at room temperature. The reaction mixture was stirred overnight in the dark. The reaction mixture was filtered through a tightly packed Celite® bed and the solvent was removed under vacuum to give 15 g 65 (100%) of product as a brownish green solid. The product was used without further purification.

Synthesis of 4-methyl-2-phenylpyridine iridium trifluoromethanesulfonate salt

The iridium dimer (7.5 g, 6.6 mmol) was dissolved in 600 mL of dichloromethane. In a separate flask, silver(I) trifluoromethanesulfonate (3.5 g, 13.8 mmol) was dissolved in MeOH (300 mL) and added slowly to the dichloromethane solution with continuous stirring at room temperature. The reaction mixture was stirred overnight in the dark. The reaction mixture was filtered through a tightly packed Celite® bed and the solvent was removed under vacuum to give 10 g (100%) of product as a brownish green solid. The product was used without further purification.

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The iridium dimer (5.3 g, 4.3 mmol) was dissolved in 500 mL of dichloromethane. In a separate flask, silver(I) trifluoromethanesulfonate (2.3 g, 8.9 mmol) was dissolved in MeOH (250 mL) and added slowly to the dichloromethane solution with continuous stirring at room temperature. The reaction mixture was stirred overnight in the dark. The reaction mixture was filtered through a tightly packed Celite® bed and the solvent was removed under vacuum to give 6.9 g (100%) of product as a brownish solid. The product was used without further purification.

Synthesis of 2-phenyl-4-isopropylpyridine iridium trifluoromethanesulfonate salt

The iridium dimer (6.2 g, 4.94 mmol) was dissolved in 500 mL of dichloromethane. In a separate flask, silver(I) trifluoromethanesulfonate (2.7 g, 10.4 mmol) was dissolved in 65 MeOH (250 mL) and added slowly to the dichloromethane solution with continuous stirring at room temperature. The

reaction mixture was stirred overnight in the dark. The reaction mixture was filtered through a tightly packed Celite® bed and the solvent was removed under vacuum to give 7.8 g (100%) of product as a brownish green solid. The product was used without further purification.

Synthesis of 4-ethyl-2-phenylpyridine iridium trifluoromethanesulfonate salt

The iridium dimer (6.8 g, 5.7 mmol) was dissolved in 500 mL of dichloromethane. In a separate flask, silver(I) trifluoromethanesulfonate (3.2 g, 12.5 mmol) was dissolved in MeOH (250 mL) and added slowly to the dichloromethane solution with continuous stirring at room temperature. The reaction mixture was stirred overnight in the dark. The reaction mixture was filtered through a tightly packed Celite® bed and the solvent was removed under vacuum to give 5.5 g (63%) of product as a brownish green solid. The product was used without further purification.

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Synthesis of 5-ethyl-2-phenylpyridine iridium trifluoromethanesulfonate salt

The iridium dimer (2.8 g, 2.4 mmol) was suspended in 500 mL of dichloromethane. In a separate flask, silver(I) trifluoromethanesulfonate (1.3 g, 4.91 mmol) was dissolved in MeOH (250 mL) and added slowly to the dichloromethane solution with continuous stirring at room temperature. The reaction mixture was stirred overnight in the dark. The reaction mixture was filtered through a tightly packed Celite® bed and the solvent was removed under vacuum to give 3.6 g (100%) of product as a brownish green solid. The product was used without further purification.

Synthesis of Compound 53

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (3.5 g, 4.9 mmol) and 2-(dibenzo[b,d] furan-4-yl)-5-isopropylpyridine (3.5 g, 12.18 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 1.3 g (33%) of Compound 53 as a yellow solid. The product was confirmed by HPLC (99.5% pure) and LC/MS.

Synthesis of Compound 157

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.50 mmol) and 2-(dibenzo[b,d] 20 furan-4-yl)-4,5-dimethylpyridine (2.5 g, 9.15 mmol)) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was refluxed for 24 h. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture 25 stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane to yield a mixture of fac- and mer-isomers by LC/MS. The mixture was isomerized to the fac-isomer in a Rayonet at 350 nm in DMSO. The crude product was chromatographed on silica gel with 1/1 dichloromethane/hexane to yield 1.4 g (52%) of Compound 157 as a yellow solid. The product was confirmed by HPLC (98.7% pure) and LC/MS.

Synthesis of Compound 158

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.37 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethylpyridine (2.5 g, 9.15 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane and dried to yield 2.7 g (100%) of Compound 158 as a yellow solid. The product was confirmed by HPLC (99.4% pure) and LC/MS.

Synthesis of Compound 159

Synthesis of Compound 165

A mixture of the appropriate iridium trifluoromethanesulfonate complex (3.0 g, 4.04 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethylpyridine (3.0 g, 10.98 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h 25 under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was dis-30 carded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solubility of the desired product was very poor. Large amount of solvent was used to elute the product. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane and later 35 4/1 dichloromethane/hexane to yield 0.3 g of the product as a yellow solid. The product was confirmed by HPLC (99.9% pure) and LC/MS.

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.25 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethylpyridine (2.5 g, 9.15 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane and dried. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 1.2 g (43%) of Compound 165 as a yellow solid. The product was con-40 firmed by HPLC (99.4% pure) and LC/MS.

Synthesis of Compound 174

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (3.6 g, 4.68 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethylpyridine (3.6 g, 13.17 mmol) in EtOH (50 mL) and MeOH (50 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 0.8 g of product as a yellow solid was confirmed by HPLC (98.6% pure) and LC/MS.

Synthesis of Compound 175

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.25 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethylpyridine (2.66 g, 9.74 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under nitrogen atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with 2/3 (v/v) THF/hexane to yield 0.8 g of 35 product by HPLC. The product was recrystallized by slow evaporation of DCM from a 1/3 DCM/hexane solution to yield 0.6 g (22%) as a yellow crystalline solid. The product was confirmed by HPLC (99.4% pure) and LC/MS.

Synthesis of Compound 184

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (3.0 g, 3.76 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethylpyridine (3.0 g, 10.98 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h 25 under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 2.1 g (65%) of product as a yellow solid. The product was confirmed by HPLC (99.8% pure) and LC/MS.

Synthesis of Compound 185

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (2.8 g, 3.51 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4,5-dimethyl pyridine (2.88.0 g, 10.53 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under N_2 atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with $^2\!/_3$ (v/v) dichloromethane/hexane to yield 2.1 g (69%) of product as a yellow solid. The product was confirmed by HPLC (99.9% pure) and LC/MS.

Synthesis of Compound 314

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.37 mmol) and 2-(dibenzo[b,d] furan-4-yl)-5-isobutyl-4-methylpyridine (2.5 g, 7.93 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h $_{30}$ under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 35 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane and dried to yield $3.0 \,\mathrm{g}$ (100%) of Compound 314_{-45} as a yellow solid. The product was confirmed by HPLC (99.6% pure) and LC/MS.

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Synthesis of Compound 321

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.2 g, 2.86 mmol) and 2-(dibenzo[b,d] 50 furan-4-yl)-5-isobutyl-4-methylpyridine (2.2 g, 6.98 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added $_{55}$ and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane. The crude product was chromatographed on 65 silica gel with 1/1 (v/v) dichloromethane/hexane to yield 1.6 g (50%) of Compound 321 as a yellow solid. The product was confirmed by HPLC (99.0% pure) and LC/MS.

Synthesis of Compound 625

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.2 g, 3.08 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4-isopropylpyridine (2.2 g, 7.66 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to 60 elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane and dried to yield 1.7 g (67%) of Compound 625 as a yellow solid. 65 The product was confirmed by HPLC (99.8% pure) and LC/MS.

Synthesis of Compound 626

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.37 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4-isopropylpyridine (2.5 g, 8.70 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane and dried. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 2.5 g (89%) of Compound 626 as a yellow solid. The product was confirmed by HPLC (99.4% pure) and LC/MS.

Synthesis of Compound 627

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (3.0 g, 4.0 mmol) and 2-(dibenzo[b,d] 55 furan-4-yl)-4-isopropylpyridine (3.0 g, 10.4 mmol in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 65 2.0 g (60%) of Compound 627 as a yellow solid. The product was confirmed by HPLC (99.9% pure) and LC/MS.

Synthesis of Compound 628

A mixture of the appropriate iridium trifluormethane-sulfonate complex (3.0 g, 4.0 mmol) and 2-(dibenzo[b,d] furan-4-yl)4-isopropylpyridine (3.0 g, 10.5 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 24 h under nitrogen atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with ½ (v/v) dichloromethane/hexane to yield 2.1 g (64%) of product as a yellow solid. The product was confirmed by HPLC (99.95% pure) and LC/MS.

Synthesis of Compound 633

A mixture of the appropriate iridium trifluoromethanesulfonate complex (2.5 g, 3.25 mmol) and 2-(dibenzo[b,d] 50 furan-4-yl)-4-isopropylpyridine (2.5 g, 8.70 mmol) in EtOH (25 mL) and MeOH (25 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for $10\,\mathrm{min}$. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The solvent was removed to half the volume and the product precipitated by addition of isopropanol and removing dichloromethane under reduced pressure. The filtered material was washed with isopropanol and hexane and dried. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 1.6 g (59%) of Compound 633 as a yellow solid. The product was confirmed by HPLC (99.7% pure) and LC/MS.

Synthesis of Compound 643

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (2.4 g, 3.12 mmol) and 2-(dibenzo[b,d] furan-4-yl)4-ethylpyridine (2.69 g, 9.35 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under nitrogen atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with $\frac{2}{3}(v/v)$ dichloromethane/hexane to yield 1.3 g (50%) of product as a yellow solid. The product was confirmed by HPLC (100% pure) and LC/MS.

Synthesis of Compound 652

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (3.1 g, 3.9 mmol) and and 2-(dibenzo[b, d]furan-4-yl)-4-isopropylpyridine (3.1 g, 10.9 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with 1/1 (v/v) dichloromethane/hexane to yield 2.1 g (62%) of Compound 652 as a yellow solid. The product was confirmed by HPLC (99.9% pure) and LC/MS

Synthesis of Compound 653

A mixture of iridium trifluoromethanesulfonate complex (2.4 g, 3.01 mmol) and 2-(dibenzo[b,d]furan-4-yl)4isopropylpyridine (3.0 g, 9.02 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under nitrogen atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with $\frac{2}{3}$ (v/v) dichloromethane/hexane to yield 0.96 g (45%) of product as a yellow solid. The product was confirmed by HPLC (99.8% pure) and LC/MS.

$$\begin{array}{c|c}
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0 & 1. LDA \\
\hline
2. CD_3I
\end{array}$$

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-4-ethyl-d₃-pyridine

To 2-(dibenzo[b,d]furan-4-yl)-4-methylpyridine (15.3 g, 59.0 mmol) in dry THF (250 mL) at -78° C. was added dropwise lithium diisopropylamide (35.4 mL, 70.8 mmol). The dark solution was stirred for 2 h at -78° C. and then CD₃I was added (4.41 mL, 70.8 mmol) dropwise. The reaction mixture was allowed to slowly warm to RT overnight. Ammonium chloride solution and EtOAc were added and the reaction transferred separatory funnel. The layers were separated, washing the aqueous twice with EtOAc and combined organics once with water. After removal of the solvent, the crude product was chromatographed on silica gel with 8/2 (v/v) hexane/EtOAc and then 7/3 hexane/EtOAc to give 14.5 g of product as a pale yellow solid. Recrystallization from hexane gave 12.9 g (79%) of 2-(dibenzo[b,d]furan-4-yl)-4-ethyl-d₃-pyridine. HPLC purity: 99.4%.

Synthesis of 2-(dibenzo[b,d]furan-4-yl)-4-isopropyl- d_{6} -pyridine

2-(Dibenzo[b,d]furan-4-yl)-4-ethyl-d₃-pyridine was dissolved in dry THF (100 mL) and cooled to -78° C. Lithium diisopropylamide (19.0 mL, 38.0 mmol) was added dropwise and the reaction mixture stirred for 2 h at -78° C. CD₃I was added dropwise and the reaction mixture was allowed to slowly warm to room temperature overnight. The reaction was quenched with MeOH, NH₄Cl (aq.) and EtOAc were added and the bipasic mixture transferred to a separatory funnel, The layers were separated, washing the aqueous layer twice with EtOAc and the combined organics with water. After removal of the solvent, the crude product was chromatographed on silica gel with 8/2 (v/v) hexane/EtOAc to 65 give 6.4 g (86%) of 2-(dibenzo[b,d]furan-4-yl)-4-isopropyl-d₆-pyridine. HPLC purity: 99.2%.

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Synthesis of Compound 1145

A mixture of the appropriate iridium trifluoromethane-sulfonate complex (3.5 g, 4.9 mmol) and 2-(dibenzo[b,d] furan-4-yl)-4-d³-ethylylpyridine (3.5 g, 12.7 mmol) in EtOH (30 mL) and MeOH (30 mL) was refluxed for 20 h under inert atmosphere. The reaction mixture was cooled to room temperature, diluted with ethanol, celite was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The Celite®/silica plug was then washed with dichloromethane to elute the product. The crude product was chromatographed on silica gel with dichloromethane to yield 1.8 g (47%) of Compound 1145 as a yellow solid. The product was confirmed by HPLC (98.7% pure) and LC/MS.

Synthesis of Compound 1146

 $2\text{-}(\mathrm{Dibenzo[b,d]furan-4-yl)-4-isopropyl-d_6-pyridine}$ and the appropriate iridium trifluoromethanesulsonate complex were combined in ethanol (25 mL) and methanol (25 mL) and heated to reflux for 16 h. The reaction mixture was cooled to room temperature, diluted with ethanol, Celite® was added and the mixture stirred for 10 min. The mixture was filtered on a small silica gel plug on a frit and washed with ethanol (3-4 times) and with hexane (3-4 times). The filtrate was discarded. The celite/silica plug was then washed with dichloromethane to dissolve the product. The crude product was chromatographed on silica gel with 50-70% dichloromethane in hexane to and then sublimed to yield 1.7 g (43%) of 55 Compound 1146 as a yellow solid. The product was confirmed by HPLC (99.5% pure) and LC/MS.

It is understood that the various embodiments described herein are by way of example only, and are not intended to limit the scope of the invention. For example, many of the materials and structures described herein may be substituted with other materials and structures without deviating from the spirit of the invention. The present invention as claimed may therefore include variations from the particular examples and preferred embodiments described herein, as will be apparent to one of skill in the art. It is understood that various theories as to why the invention works are not intended to be limiting.

The invention claimed is:

1. A compound having the formula:

Formula I

$$R_1$$
 R_2
 R_3
 R_4
 R_5
 R_6
 R_6
 R_6
 R_6

wherein the sum of the number of carbon atoms in R_1 is at least 2;

wherein R₃, R₄, R₅, R₆ are optionally linked;

wherein R_a and R_b represent mono-, di-, tri- or tetra-substitution;

wherein X is selected from the group consisting of BR, NR, PR, O, S, Se, C=O, S=O, SO₂, CRR, SiRR', and GeRR'.

wherein R_a, R_b, R, R', R₃, R₄, R₅, and R₆ are independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof;

wherein n is 1 or 2, and

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wherein R_1 is alkyl or cycloalkyl, and R_2 is hydrogen or deuterium.

- 2. The compound of claim 1, wherein n is 2.
- 3. The compound of claim 1, wherein X is O.
- 4. The compound of claim 1, wherein R_1 is branched alkyl, cyclic alkyl, bicyclic alkyl, and multicyclic alkyl.
 - **5**. The compound of claim **1**, wherein R_1 is iso-propyl.
- **6**. The compound of claim **1**, wherein R_1 or R_2 contains one or more deuterium atoms.
- 7. The compound of claim 1, wherein R_1 and R_2 contain one or more deuterium atoms.
- **8**. The compound of claim **1**, wherein R₃, R₄, R₅ and R₆ are independently selected from the group consisting of hydrogen, deuterium, alkyl, aryl, and combinations thereof.
- 9. The compound of claim 1, wherein at least one of R_3 , R_4 , R_5 and R_6 comprises a branched alkyl, cyclic alkyl, bicyclic alkyl, or a multicyclic alkyl.
- 10. The compound of claim 1, wherein R_3 , R_4 , R_5 or R_6 contain one or more deuterium atoms.

11. The compound of claim 1, wherein the compound is selected from the group consisting of:

-continued

Compound 633

-continued

D₃C N Ir

Compound 1146 15

Compound 1145

12. A first device comprising a first organic light emitting ³⁰ device, comprising:

an anode;

a cathode; and

an organic layer, disposed between the anode and the cathode, comprising a compound having the formula: wherein n is 1 or 2; and

wherein R₁ is alkyl or cycloalkyl, and R₂ is hydrogen or deuterium.

13. The first device of claim 12, wherein the first device is a consumer product.

14. The first device of claim 12, wherein the first device is an organic light-emitting device.

15. The first device of claim 12, wherein the first device comprises a lighting panel.

16. The first device of claim **12**, wherein the organic layer is an emissive layer and the compound is an emissive dopant.

17. The first device of claim 12, wherein the organic layer is an emissive layer and the compound is a non-emissive dopant.

18. The first device of claim 12, wherein the organic layer further comprises a host.

19. The first device of claim 18, wherein the host comprises a triphenylene containing benzo-fused thiophene or benzo-fused furan;

wherein any substituent in the host is an unfused substituent independently selected from the group consisting of C_nH_{2n+1} , OC_nH_{2n+1} , OAr_1 , $N(C_nH_{2n+1})_2$, $N(Ar_1)(Ar_2)$, $CH=CH-C_nH_{2+1}$, $C=CC_nH_{2n+1}$, Ar_1 , Ar_1 - Ar_2 , and $C_nH_{2n}-Ar_1$;

wherein n is from 1 to 10; and

wherein ${\rm Ar_1}$ and ${\rm Ar_2}$ are independently selected from the group consisting of benzene, biphenyl, naphthalene, triphenylene, carbazole, and heteroaromatic analogs thereof

20. The first device of claim 19, wherein the host has the formula:

Formula I

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$$\begin{bmatrix} R_1 & R_2 & R_3 & R_4 & A_5 \\ R_1 & R_5 & R_6 & A_5 \\ R_6 & R_6 & R_6 \end{bmatrix}_{n_i} = 50$$

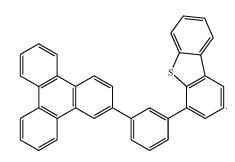
wherein the sum of the number of carbon atoms in R_1 is at least 2;

wherein R_3 , R_4 , R_5 , R_6 are optionally linked;

wherein R_a and R_b represent mono-, di-, tri- or tetra-sub-stitution:

wherein X is selected from the group consisting of BR, NR, PR, O, S, Se, C=O, S=O, SO₂, SiRR', and GeRR';

wherein R_a, R_b, R, R', R₃, R₄, R₅, and R₆ are independently selected from the group consisting of hydrogen, deuterium, halide, alkyl, cycloalkyl, heteroalkyl, arylalkyl, alkoxy, aryloxy, amino, silyl, alkenyl, cycloalkenyl, heteroalkenyl, alkynyl, aryl, heteroaryl, acyl, carbonyl, carboxylic acids, ester, nitrile, isonitrile, sulfanyl, sulfinyl, sulfonyl, phosphino, and combinations thereof;



21. The first device of claim 18, wherein the host is selected from the group consisting of:

and combinations thereof.

22. The first device of claim 18, wherein the host is a metal complex.

UNITED STATES PATENT AND TRADEMARK OFFICE

CERTIFICATE OF CORRECTION

PATENT NO. : 9,184,397 B2

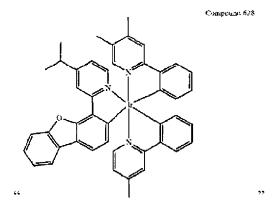
APPLICATION NO. : 14/156808

DATED : November 10, 2015 INVENTOR(S) : Gregg Kottas et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

In the Claims:

Claim 11, Column 163, Lines 49-65, delete



and insert --

Compound 628

Signed and Sealed this First Day of March, 2016

Michelle K. Lee

Michelle K. Lee

Director of the United States Patent and Trademark Office